

Academia-Industry Cooperation *“Needs First”*

Research Group for Flexible Technologies (Nakada/Furukawa/Yuki/Koden)

2022



**Professor
Hitoshi Nakada**



**Associate Professor
Tadahiro Furukawa**



**Associate Professor
Dr. Toshinao Yuki**



**Professor
Dr. Mitsuhiro Koden**

Mission and Activity

Consortium (YU-FIC, YU-FLEC)

Background technologies

- OLED & OPV device fabrication
- Evaluation of OLED & OPV
- R2R (Roll-to-roll) and printing technologies
- Evaluation of gas barrier / International standardization

Developed technologies

- Flexible OLEDs on ultra-thin glass
- Improved mechanical strength of flexible OLEDs on ultra-thin glass
- Flexible OLEDs on stainless steel foil or barrier film
- R2R fabrication of barrier film with transparent electrode
- In-mold electronics (IME) technology
- Mechanism analysis of electrode disconnection in 3D thermoforming
- Application of organic electronics to interactive advertisement
- Non-ITO transparent electrode with implanted metal-mesh structure
- TFE (Thin Film Encapsulation) technologies for OLEDs
- OnDemand patterning of OLEDs by ink-jet printed insulators
- Barrier layer by ALD (Atomic layer deposition)
- High temperature tolerant barrier films for flexible OLEDs
- Printed flexible OPV fabricated by R2R processes
- PSA encapsulating technologies for OLEDs
- Spray coating
- Optical simulation
- Analysis of defects, failures, structures, etc.

Topics/Publications

Main members

p.2~3

p.4~5

p.6

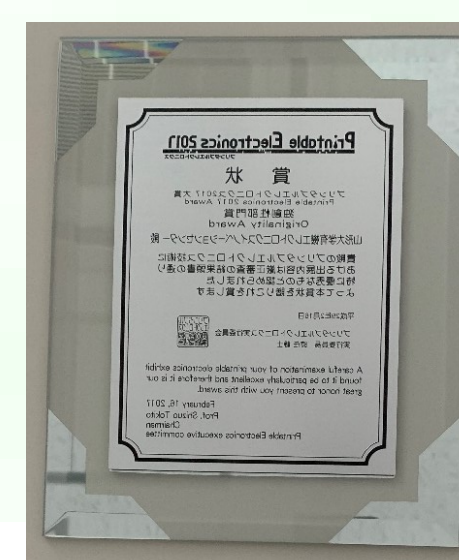
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“Award from Minister of State for Science and Technology Policy”
Cabinet Office of Japan
(2017)



Printable Electronics
2017 Award



JFlex Award
(2019, 2020)

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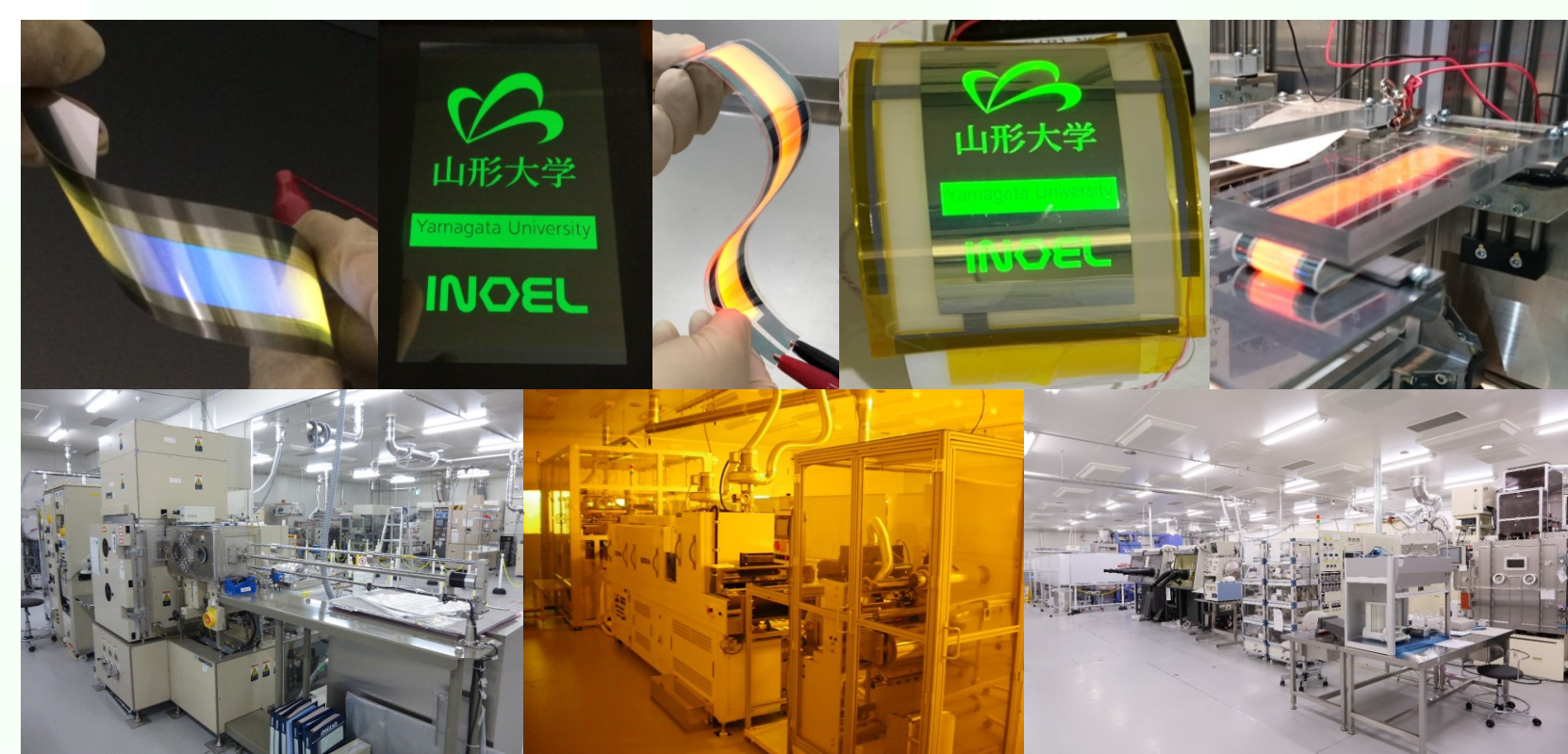
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Activity

Academia-Industry Collaboration “Needs First!”

In flexible organic electronics technologies, we offer academia-industry collaboration with **“Needs First”**, in which needs and requests from collaborating companies are first priority.

We contribute R&Ds of collaborating companies, aiming at practical technologies and actual businesses.

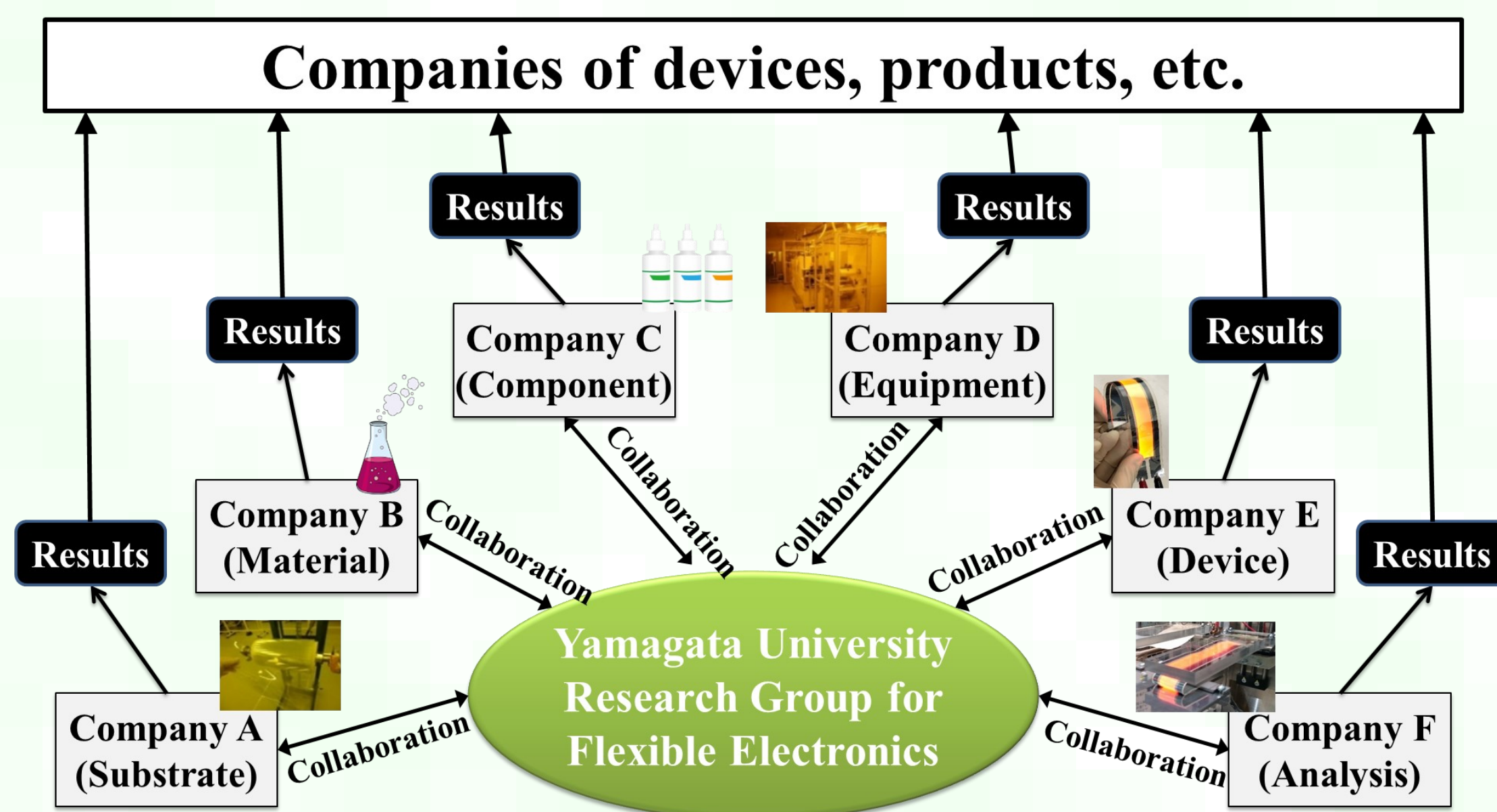
Our activity with “Needs First” was awarded from Minister of State for Science and Technology Policy, Government of Japan in 2017.

(Main technologies)

- Devices and processes of organic electronics (OLED, OPV, OTFT, etc.)
- Materials and components for flexible organic electronics
- Barrier technologies / Barrier evaluation and analysis / Flexible encapsulation
- Printing and roll-to-roll (R2R) technologies for flexible organic electronics



“Award from Minister of State for Science and Technology Policy”
Cabinet Office,
Government of Japan (2017)



Collaboration scheme



Unique points

- **“Needs First” (Business First)**
Company’s needs are first priority.
- **Merits in IPs**
- **Self-supporting accounting system**
An unique model based on collaboration with industry

Collaborations

- Device fabrication with collaborating company’s technologies and feedback of all results to the company
- Data for proofing potential of the technologies of collaborating company.
- Prototype samples
- Coordination of plural companies
- Individual collaboration / Consortium / International collaboration

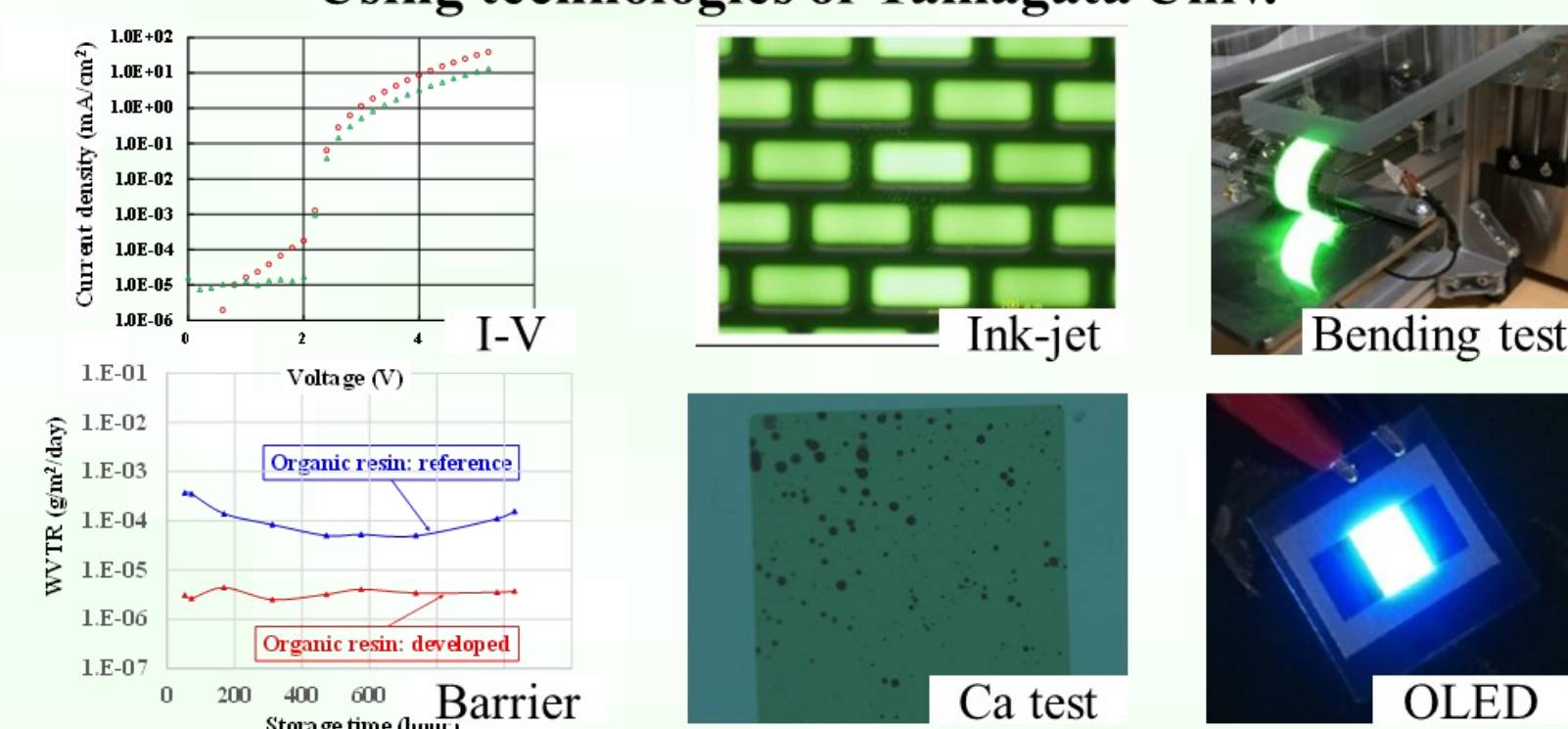
Skills of members

- Substantial experience in the practical development at previous companies.
- Rich knowledge on organic electronics (OLEDs etc.), displays, flexible, R2R, printing, etc.
- Rich information about trends of technologies and businesses.
- Rich human network in academic society and industrial fields.

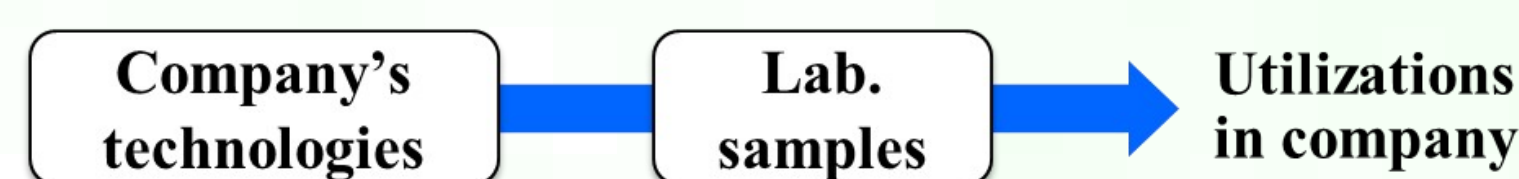
Evaluation / Developmental support



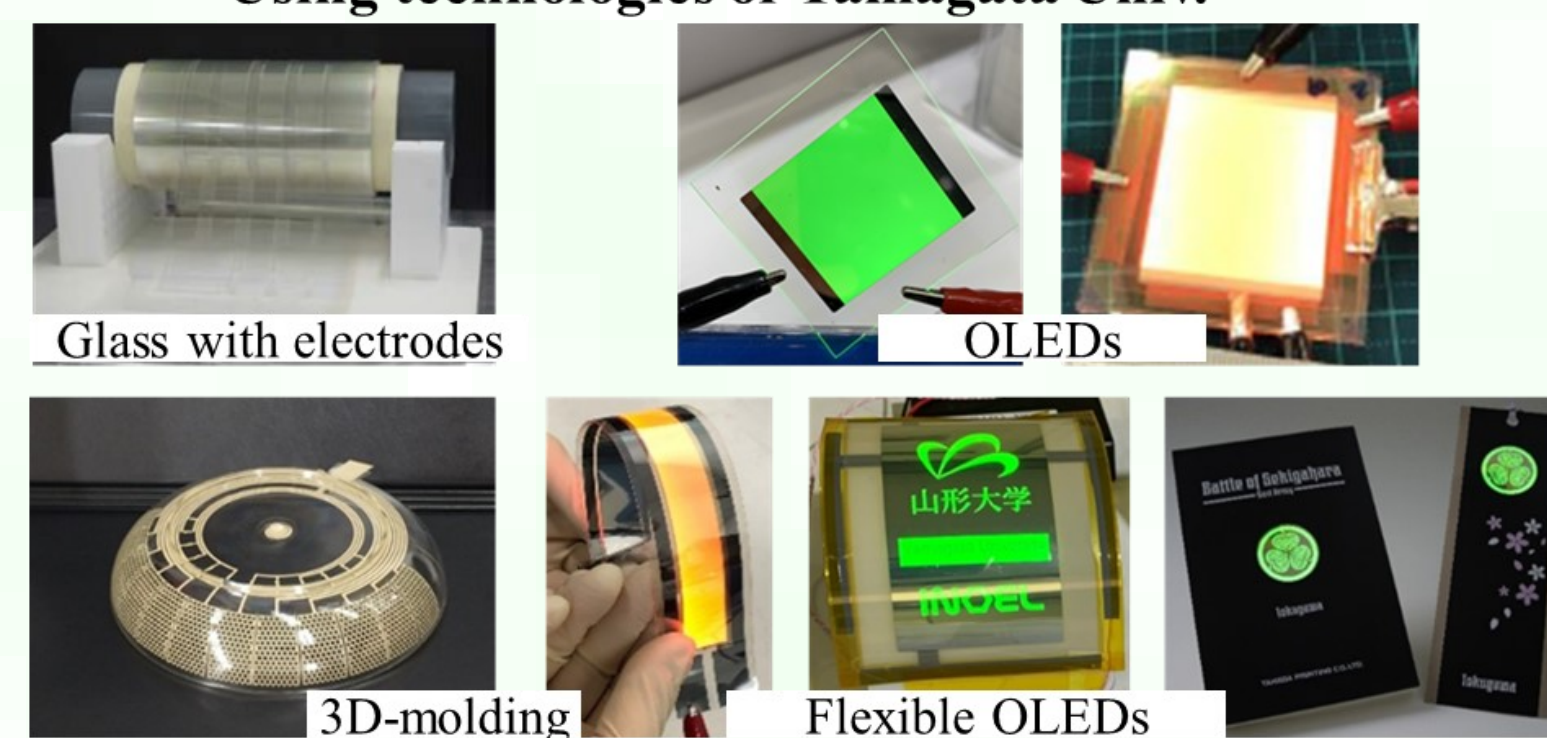
Using technologies of Yamagata Univ.



Prototype / Lab. sample



Using technologies of Yamagata Univ.



Activities

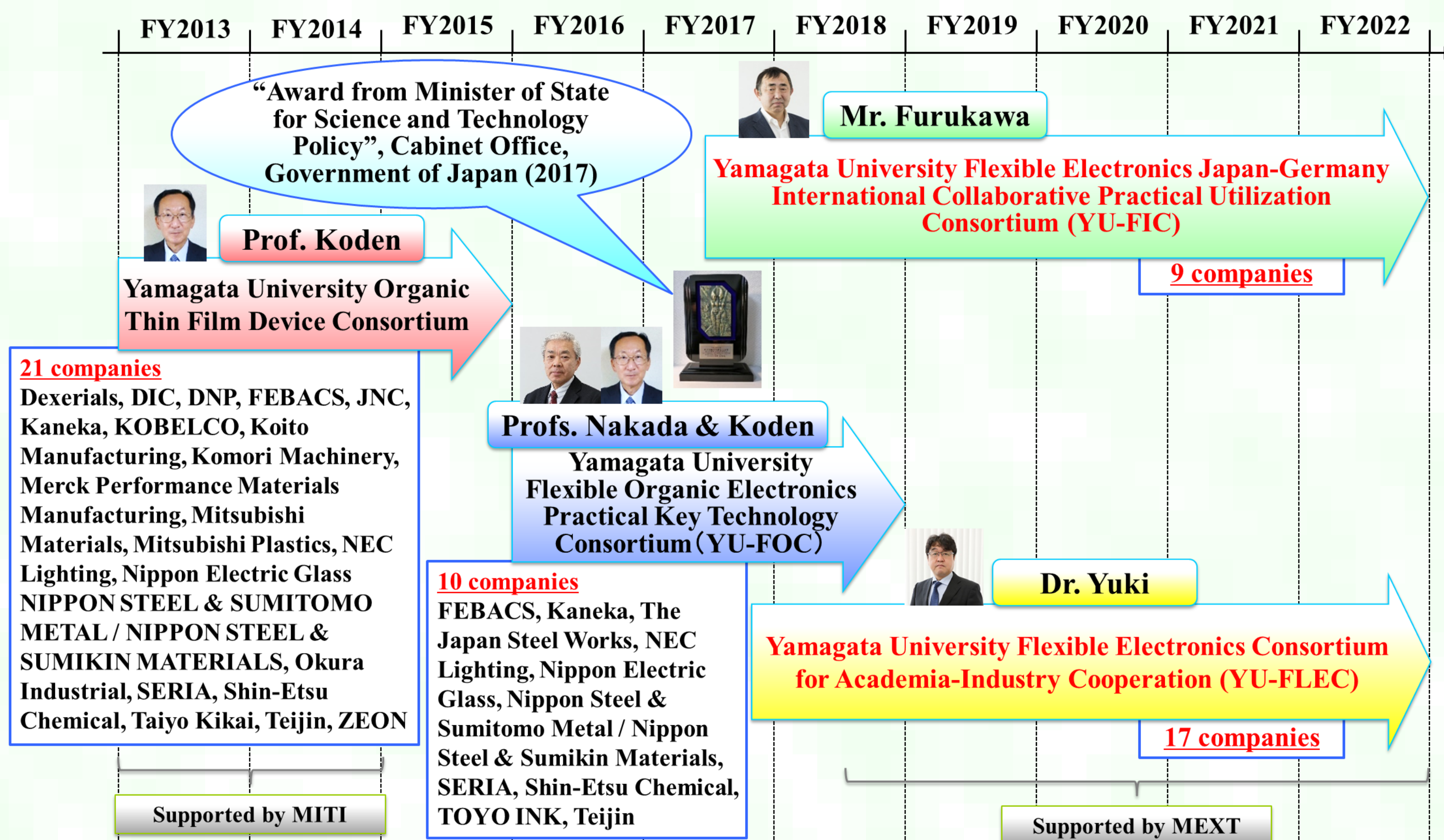
- Academia-Industry Cooperation Consortium (p.3~p.5)
- National Project (p.3)
- Individual Collaboration
- Evaluation support (p.8): WVTR (Water Vapor Transmission Rate) evaluation with MORESCO

Activity

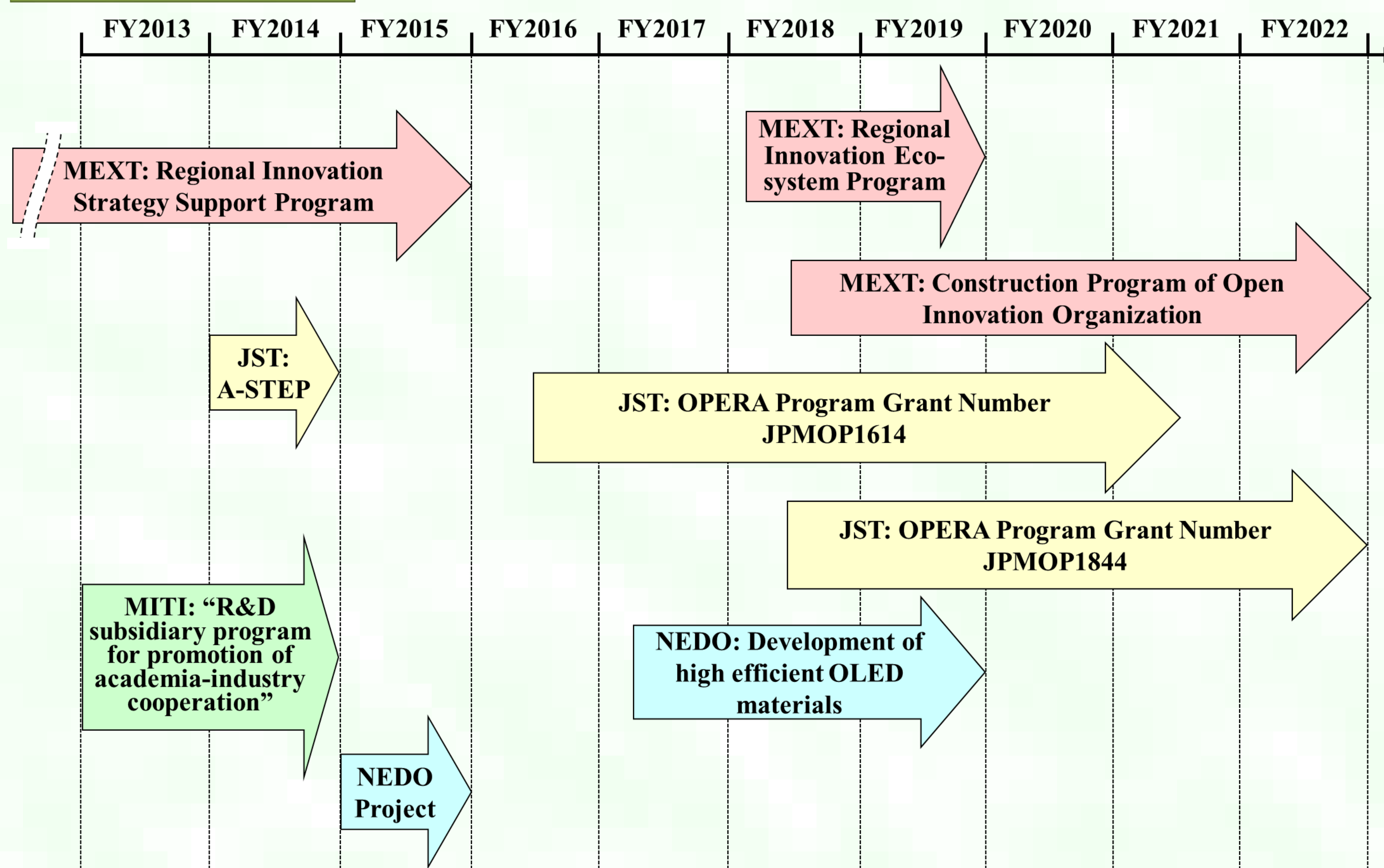
Consortium / National Projects

Based on the concept of **“Needs First”**, we promote **academia-industry collaboration consortiums** and participate various **national projects**.

Academia-Industry Collaboration Consortium



National Projects



Consortium

Yamagata University Flexible Electronics Japan-Germany International Collaborative Practical Utilization Consortium (YU-FIC)

Yamagata University Flexible Electronics Japan-Germany International Collaborative Practical Utilization Consortium (YU-FIC) collaborates with companies and institutes in Germany, aiming at novel flexible electronics products.

Project term October 2017 ~ March 2023

Participants 9 Companies (Jan. 2022)

Subjects

- Innovative roll-to-roll fabrication of OLED lighting on flexible substrates
- Application of organic electronics technologies to interactive advertisement
- Fabrication technologies for three dimensional print circuit boat (3DPCB)

Leaders

- **Project leader: Associate Prof. T. Furukawa**
- **Fellow: Prof. T. Takahashi**
- **Secretary: Prof. M. Koden**



Collaboration with German activity

YU-FIC collaborates with 24 German companies and institutes which are organized by Organic Electronics Saxony (OES), having twice visits a every year, respectively.

Activity

- ✓ Mutual visits between Germany and Japan.
- ✓ Frequent remote meeting between Germany and Japan.
- ✓ Demonstrations of collaborated results at conferences and exhibitions.



LOPEC/Germany (Mar. 2019)



Flex Japan 2019 (May 2019)



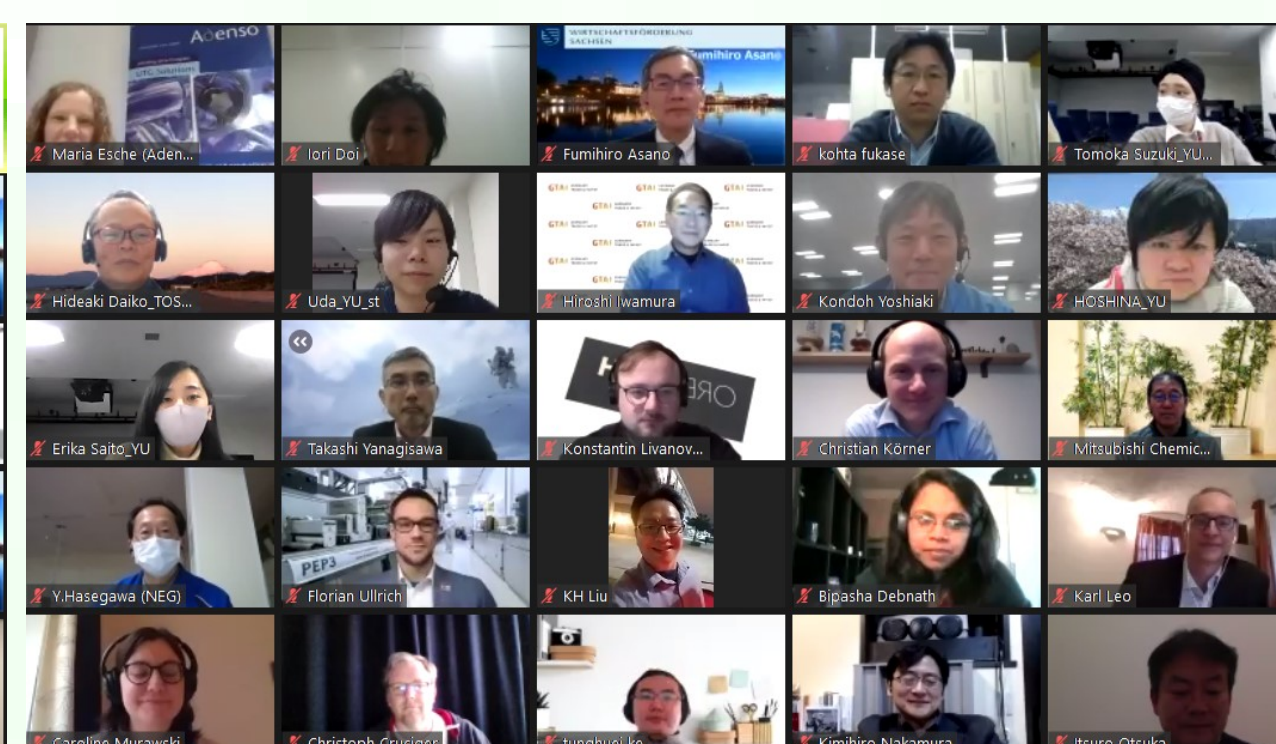
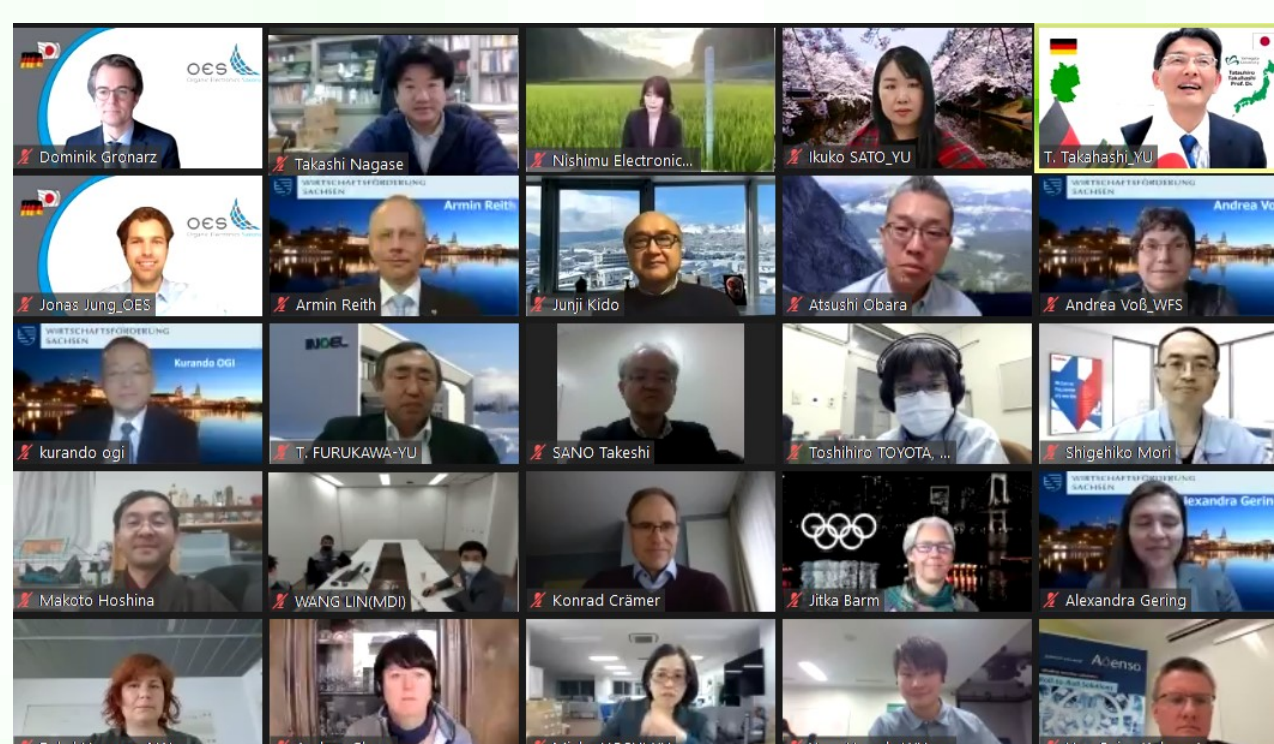
Germany (Sep. 2019)



Japan (Jan. 2020)



JFlex (Jan. 2020)



The 9th Germany-Japan Joint Workshop (Online) "Flexible, Printed Electronics and Sensors", 26 February (2021).

Related program

- MEXT: Construction Program of Open Innovation Organization [FY2018~FY2022].
- JST: OPERA Program Grant Number JPMOP1614 [FY2016~FY2021].

Web page

- Home page: <https://inoel.yz.yamagata-u.ac.jp/yu-fic-en/>
- You Tube: <https://www.youtube.com/watch?v=Zu9DZH4Nq6c>

Consortium

Yamagata University Flexible Electronics Consortium for Academia-Industry Cooperation (YU-FLEC)

Yamagata University Flexible Electronics Consortium for Academia-Industry Cooperation (YU-FLEC) is constructed by **one-by-one collaborations with individual companies**, promoting practical development based on the concept of “**Needs First**”. We would appreciate it if you are interested in YU-FLEC.

Mission and Subjects

Practical R&D in flexible electronics

- Flexible substrates
- Gas barrier and flexible encapsulation
- process technologies for flexible devices
- Novel electrodes (Non-ITO electrode)
- Next-generation materials and devices
- Equipment

Leaders



- **Project leader: Dr. T. Yuki (Associate Prof.)**
- **Fellow: Prof. H. Nakada**
- **Secretary: Prof. M. Koden**

Activities

- Application of flexible substrates to OLEDs
 - Stainless steel foil
 - Barrier film
- Gas barrier technologies
 - Evaluation of gas barrier properties
 - Fabrication technologies of gas barrier layers
- Flexible encapsulation
 - TFE (Thin Film Encapsulation)
 - PSA encapsulating technology
 - Laminating encapsulation
- Non-ITO transparent electrode
 - Metal mesh electrode
- OLED devices and processes
 - OnDemand patterning of OLED
- Novel materials for emission devices
 - Evaporation materials
 - Solution materials
- Novel emission devices
 - QLED
 - Novel TFT technologies
- Novel components for organic electronics
- Equipment for organic electronics
 - Evaporation equipment
 - Deposition of barrier layers
 - Ink-jet

Project term

January 2018 ~ March 2023

Participants (total)

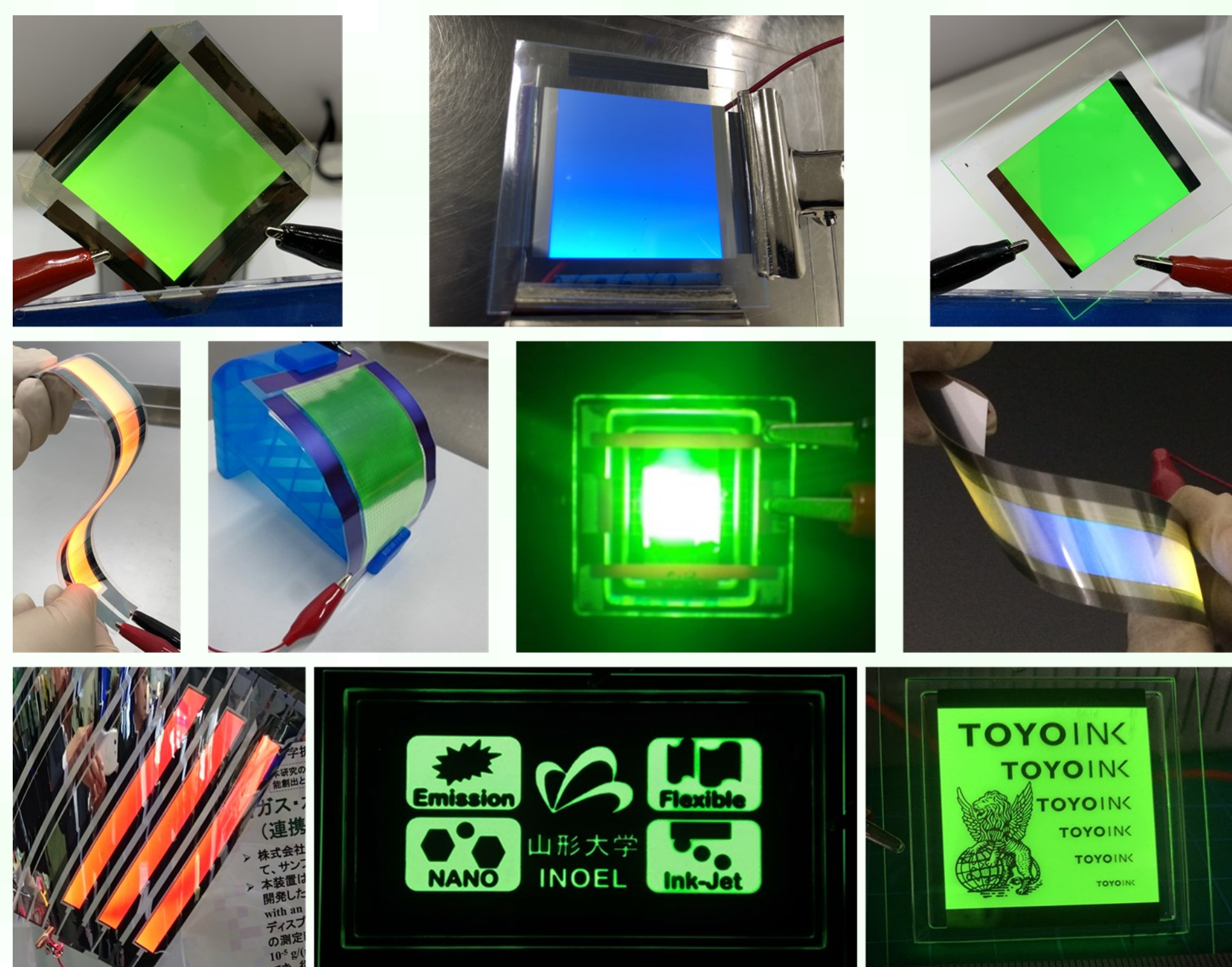
17 Companies (January 2022)

Unique points

- Academia-industry collaboration led by scientists having rich experience in actual businesses
- Large size equipment for various prototypes
- Creation of business competitiveness

Main applications

- Small flexible OLED displays (mobile, etc.)
- Large size OLED displays (TV, etc.)
- Flexible OLED lighting



Related program

- MEXT: Construction Program of Open Innovation Organization [FY2018~FY2022].

Seminar

- Monthly report for YU-FLEC members by Prof. H. Nakada “Trend of organic electronics”
- Bimonthly report for YU-FLEC members by Prof. M. Koden “Trend of organic electronics - OPV”
- 1st YU-FLEC seminar (Aug. 2019 Tokyo).

Web page

- Home page: <https://inoel.yz.yamagata-u.ac.jp/yu-flec-en/>

Background
technologies

OLED & OPV Device Fabrications

Various types of OLED & OPV devices are able to be fabricated. The fabricated OLED & OPV devices are utilized for technological evaluations, prototype samples, etc.

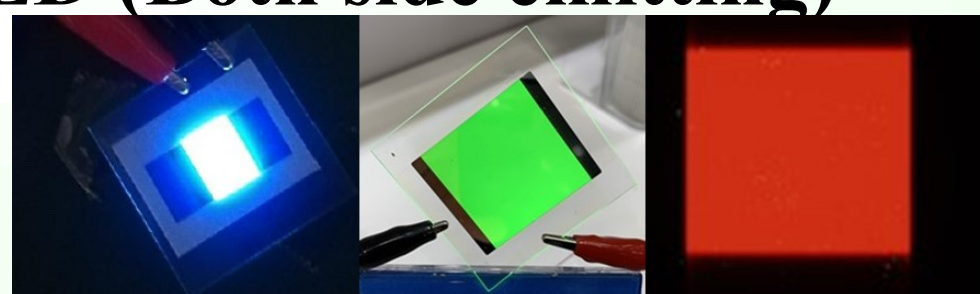
OLED (Organic Light Emitting Diode)

Materials

- Small molecular and polymer materials
- Fluorescent, phosphorescent and TADF
- Quantum dot (QD) materials

Devices

- Bottom emitting & Top-emitting
- Transparent OLED (Both side emitting)
- Multi-photon
- White emitting



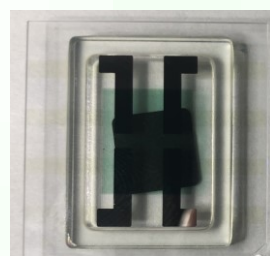
OPV (Organic Photovoltaic)

Materials

- Vacuum & Coating
- Quantum dot (QD)

Devices

- Normal structure
- Inverted structure



Processes for organic layers

- Dry process: Vacuum evaporation
- Solution process: Spin-coat, Ink-jet, Spray, etc.



Vacuum evaporation



Ink-jet



Spin-coat



Spray



Wet cleaning



Plasma cleaner

Barrier layers

- Inorganic barrier layer: CVD, Sputtering, ALD
- Inorganic/organic alternately stacked barrier layer



R2R sputtering & CVD



ALD
(Atomic Layer Deposition)



Sputtering

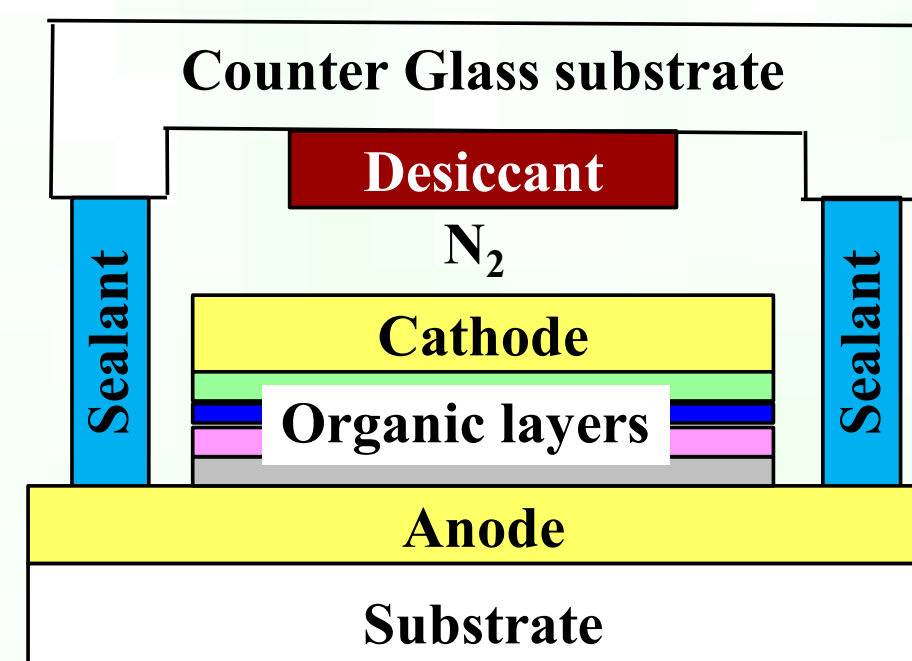


Ink-jet

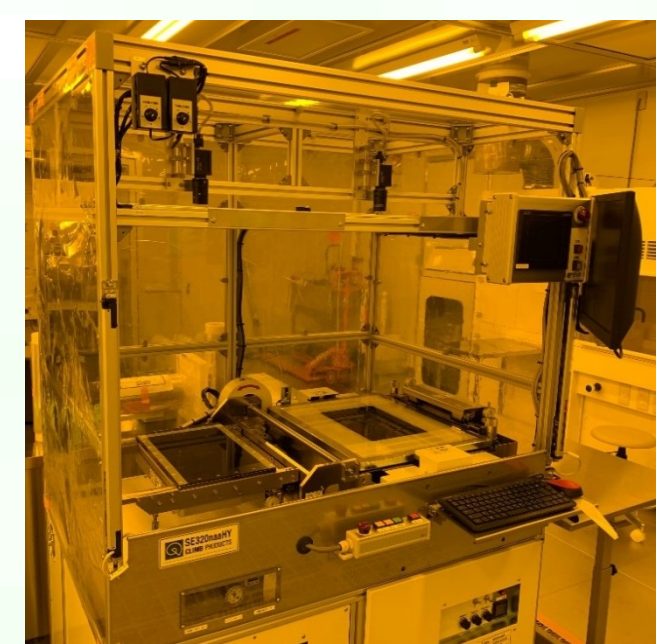
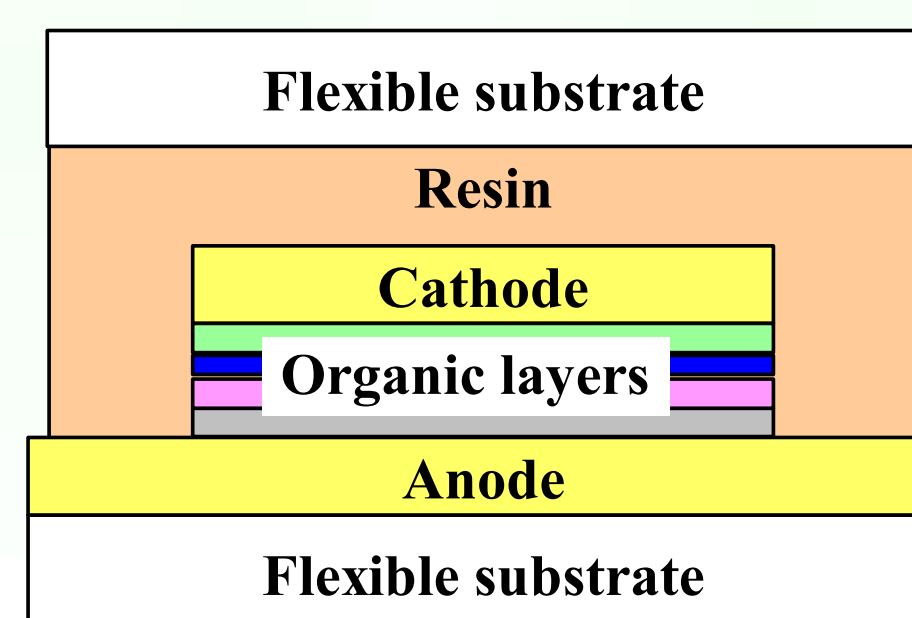
Encapsulations

Various encapsulating technologies are applied.

- Common encapsulation with desiccant
- Flexible all-solid type encapsulation



Sheet-type lamination



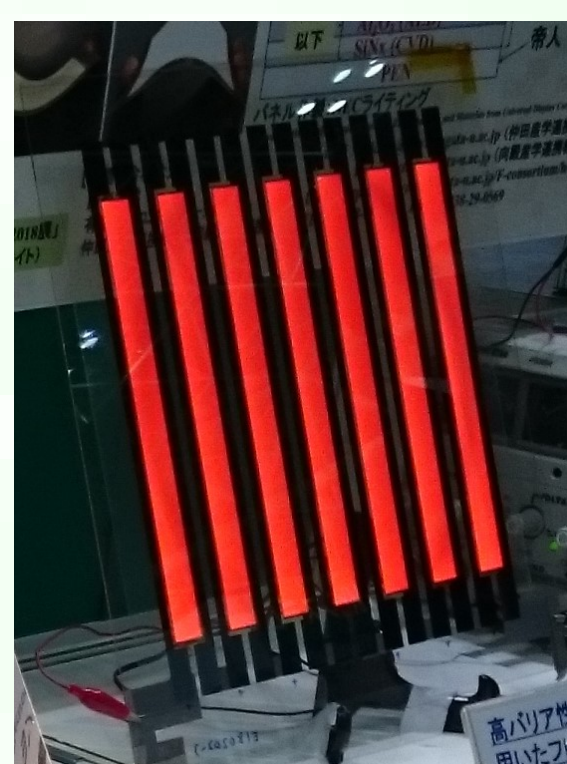
Roll-type lamination

Large size OLEDs

Large size OLED devices can be fabricated.
The maximum substrate size: 30cm × 30cm

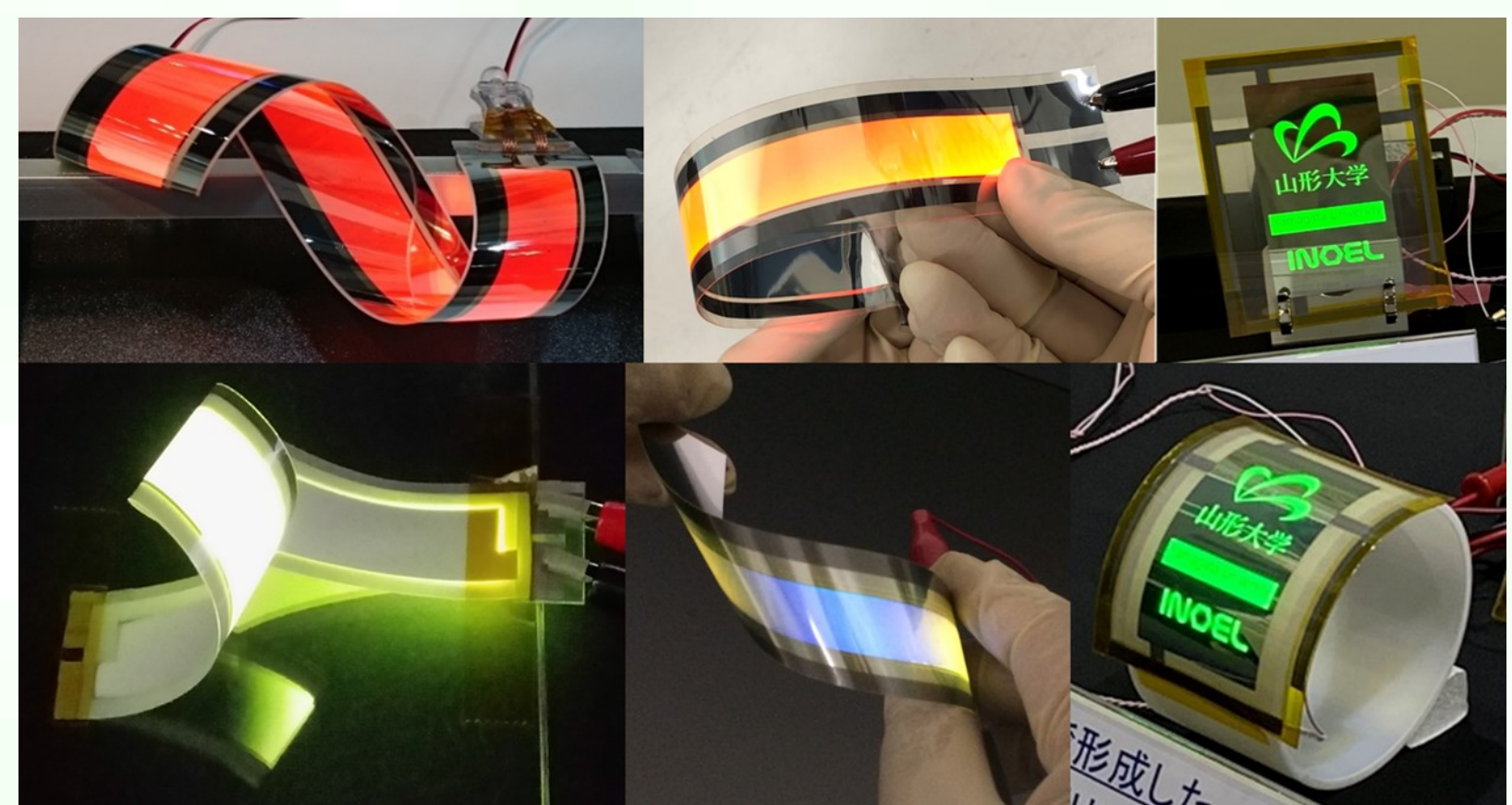


OLED vacuum evaporation
equipment "ELVESS" (Tokki)



Flexible OLEDs

Flexible OLED devices with various designs can be fabricated.



Background
technologies

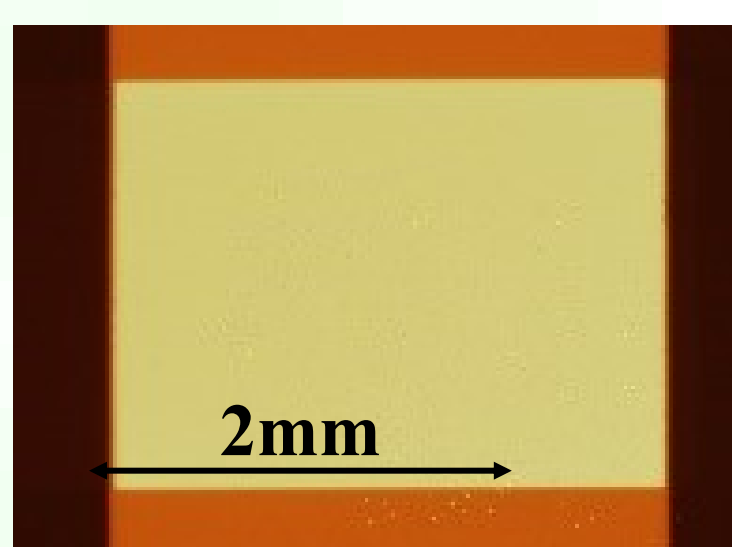
Evaluation of OLED & OPV

OLED and OPV devices with various technologies (materials, components, device architectures, processes, equipment, etc.) of collaborating companies are fabricated and evaluated from practical points of view. All evaluating results are feedbacked to the collaborating company for not only the next development but also demonstrations etc.

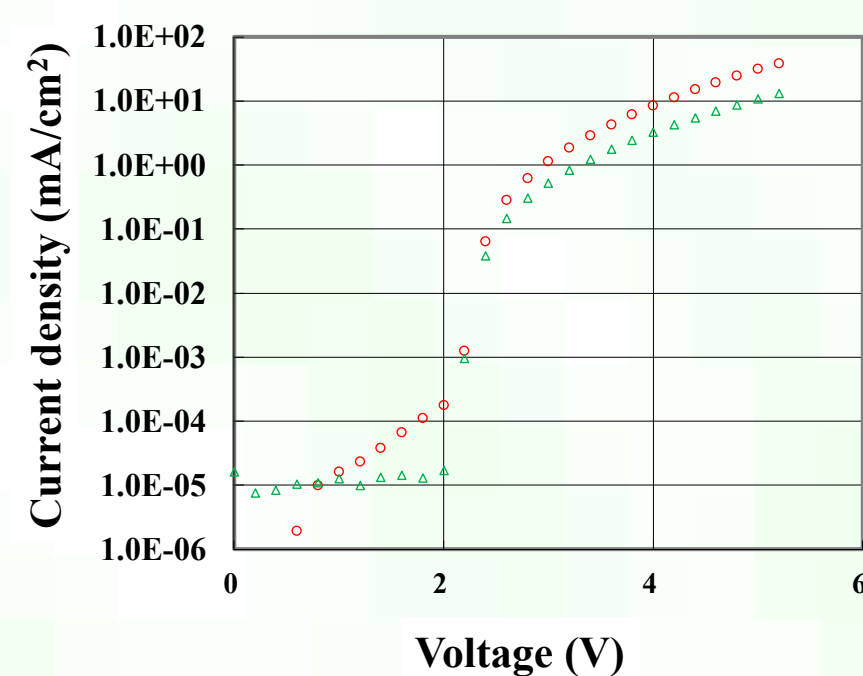
Evaluations of OLEDs

Various characteristics of OLEDs are evaluated.

- Emission quality such as uniformity, defects, etc.
- I-V, L-I characteristics
- Emission spectrum, etc.



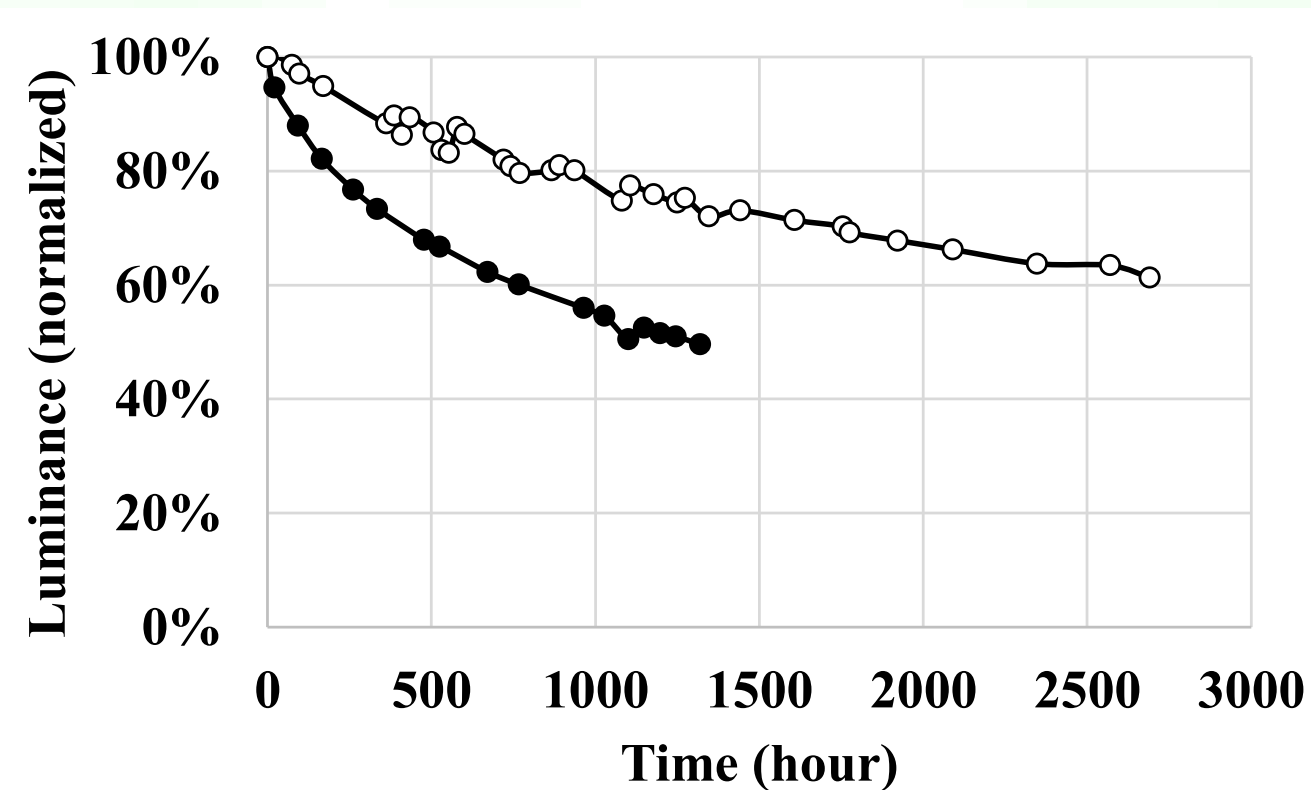
Uniform emission



I-V characteristics

Driving lifetime

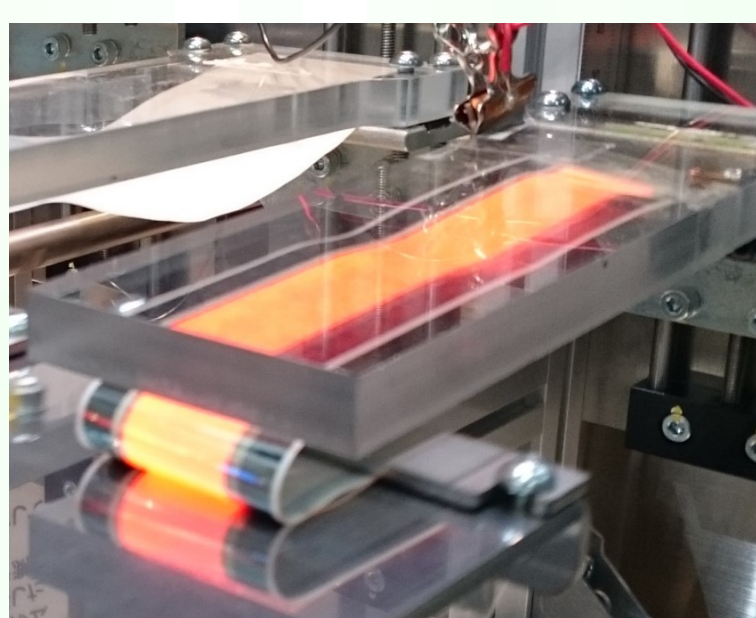
The reduction of emission intensity of OLED devices under constant current driving is evaluated.



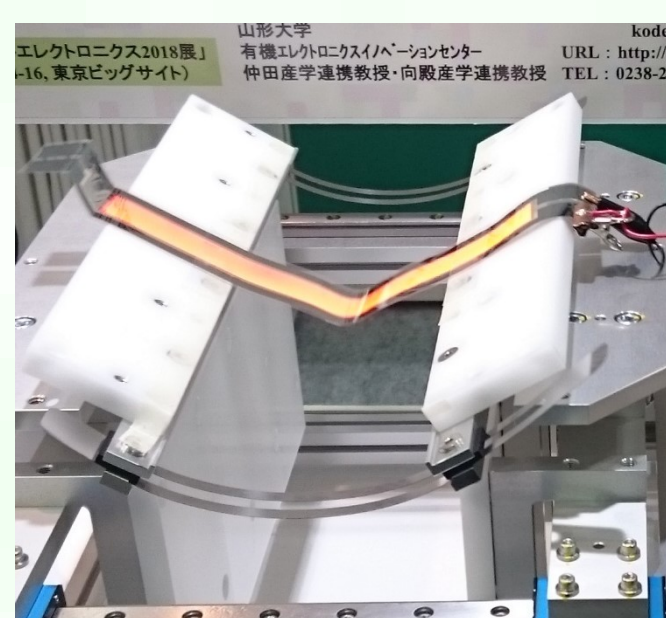
Driving lifetime

Bending tests

The influences of various bending stress on device characteristics, barrier properties, etc. are evaluated using three types of bending equipment.



U-shape sliding



Folding



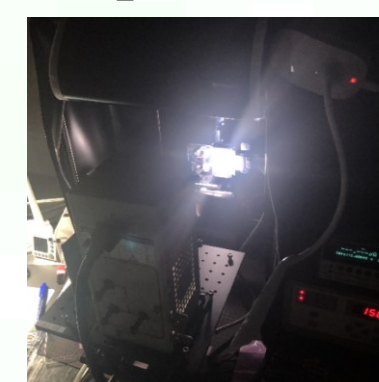
Both-side bending

Evaluations of OPVs

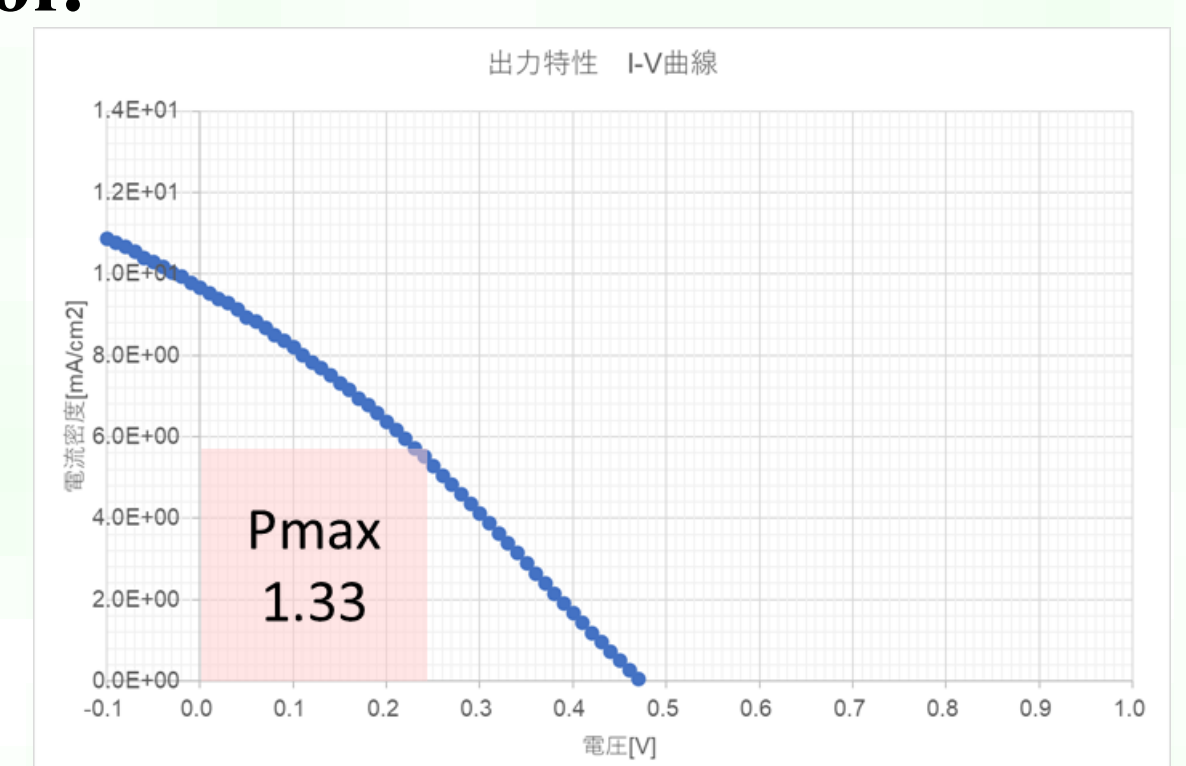
Power generations of OPV devices are evaluated, using solar simulator.



Solar simulator
Newport MODEL 66902



1SUN(1000W/m²)
AM1.5 room temperature
~100,000 LUX

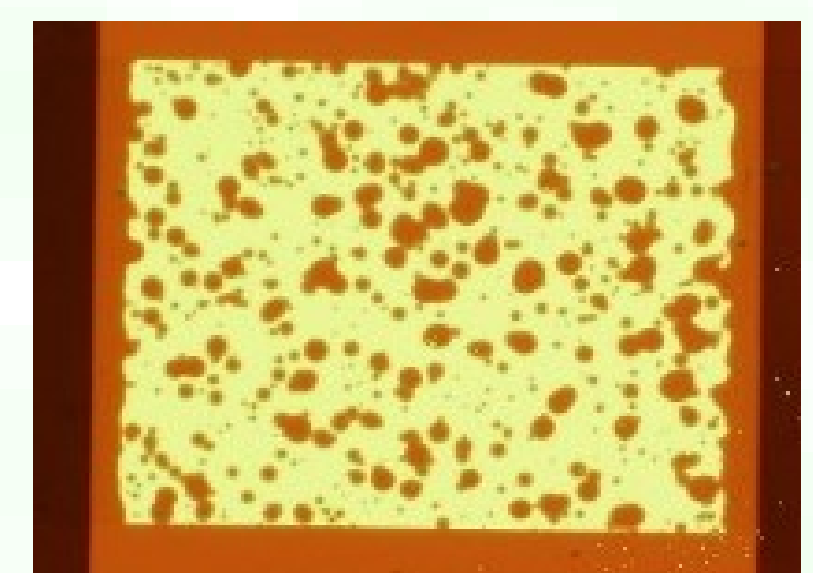


Storage lifetime

The change of emission is observed after storage test with high temperature and high humidity.



Initial emission
(No defect)



Emission after storage
test (Dark spot)

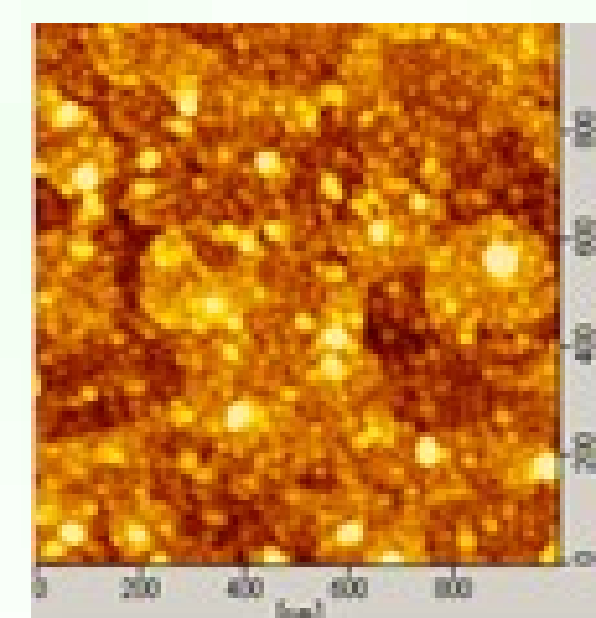
Others

Other evaluations can be used, based on the request from collaborating companies.
(Example)

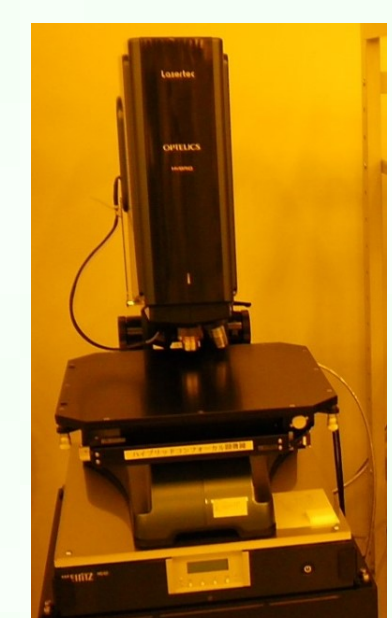
- Ionization potential
- Defect analysis
- SEM, AFM
- 3D profile



Ionization
potential



AFM



Hybrid
confocal
microscopy

Background
technologies

Roll-to-roll (R2R) and Printing Technologies

We provide roll-to-roll (R2R) and printing technologies, aiming at an innovation of productions in flexible organic electronics.

Roll-to-roll (R2R)

Three types of unique roll-to-roll (R2R) equipment are utilized for fabrications of electrodes, barrier layers, organic layers, etc.

- Substrate width : 30cm
- Substrate: ultra-thin glass, stainless steel foil, flexible film



R2R sputtering
& CVD
(KOBELCO)



R2R screen printing
and slit-coating
(SERIA)



R2R wet cleaning
(FEBACS)

Printing / Coating

Various printing and coating equipment can be utilized for printing tests and device fabrications.



Screen printing



Flexography and
gravure offset printing



Ink-jet



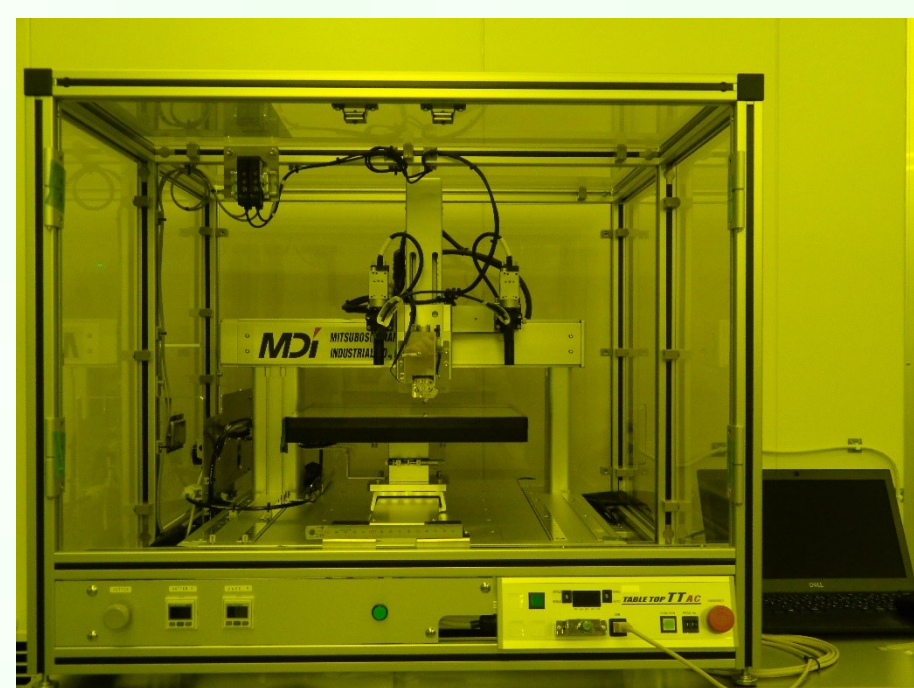
Spray



Spin-coating

Process technologies

Various equipment for process technologies can be used.



Cutting machine
for ultra-thin glass



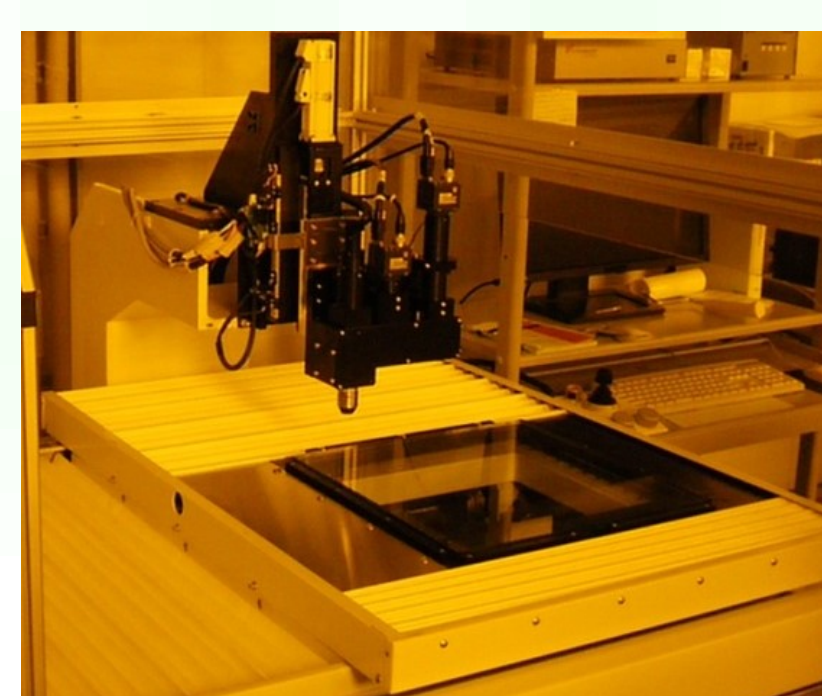
3D thermoforming

Evaluation

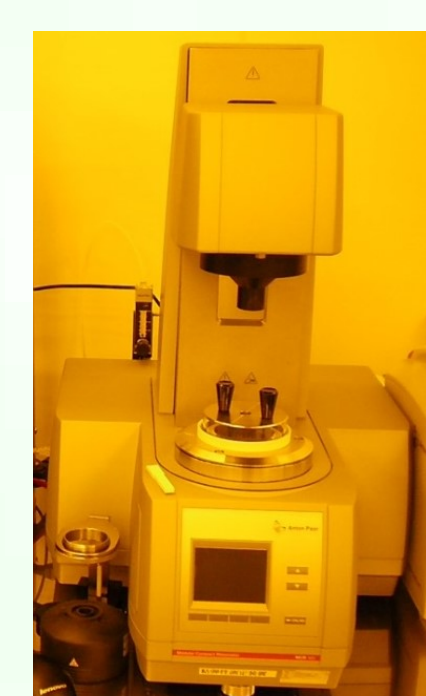
Various evaluation equipment are used for R&D of printing and roll-to-roll (R2R) technologies.



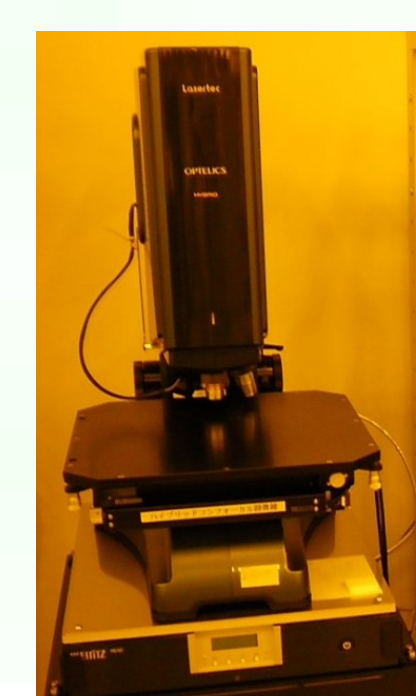
Contact angle measurement



Precise position
detector



Viscoelasticity
measurement



Hybrid
confocal
microscopy

Background
technologies

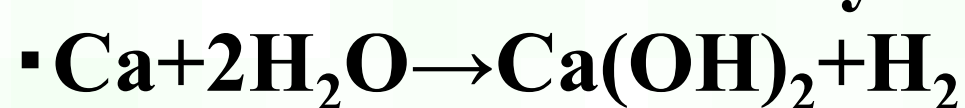
Evaluation of Gas Barrier / International Standardization

Evaluation of gas barrier properties is very important in flexible organic electronics technologies. We provide two evaluation methods which are “**Calcium corrosion method**” and “**MA method** (Modified differential pressure method with an Attached support)”. In addition, we contribute to **SEMI international standardizations** of gas barrier films.

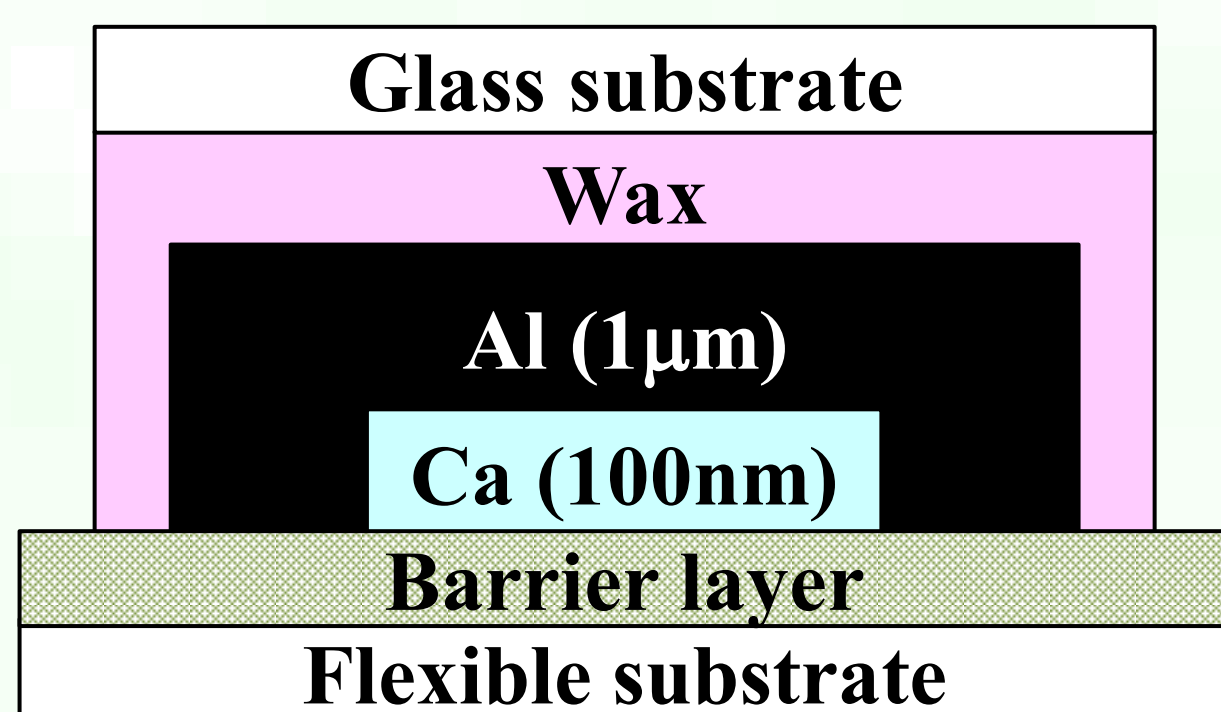
Ca corrosion method

- ✓ **Ca corrosion** method evaluates the optical change in Ca reflectivity which changes by the reaction of Ca and H₂O, giving WVTR (Water Vapor Transmission Rate) values.

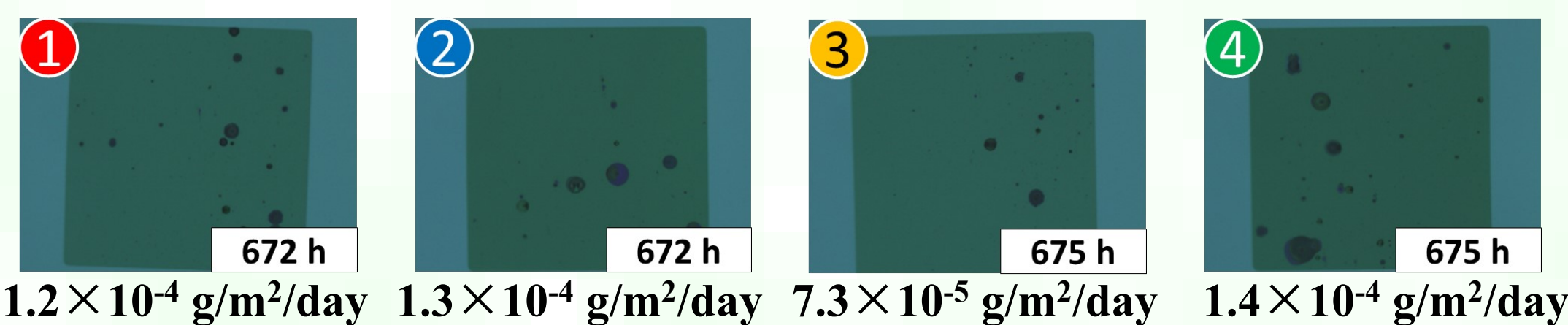
This method is useful for the evaluation of defects in barrier layer.



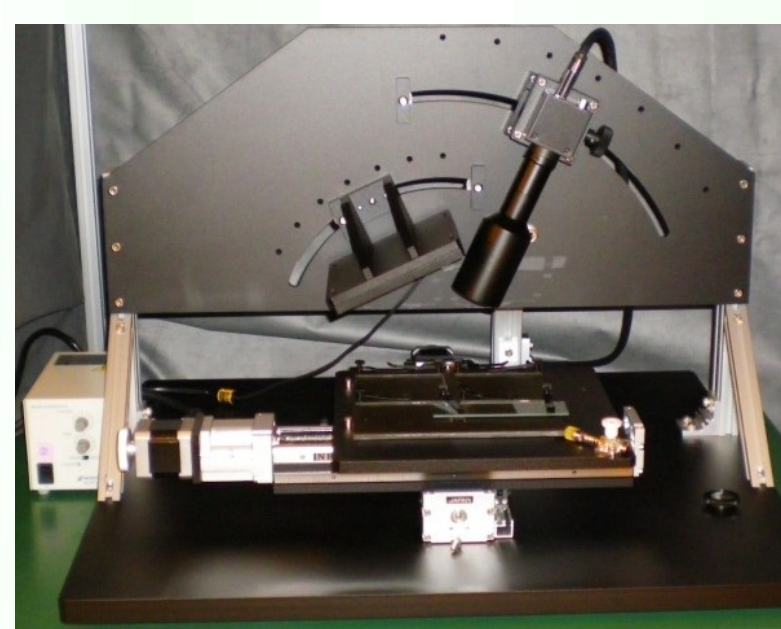
- ✓ **SEMI D78** - Test Method of Water Vapor Barrier Property for Plastic Films with High Barrier for Electronic Devices



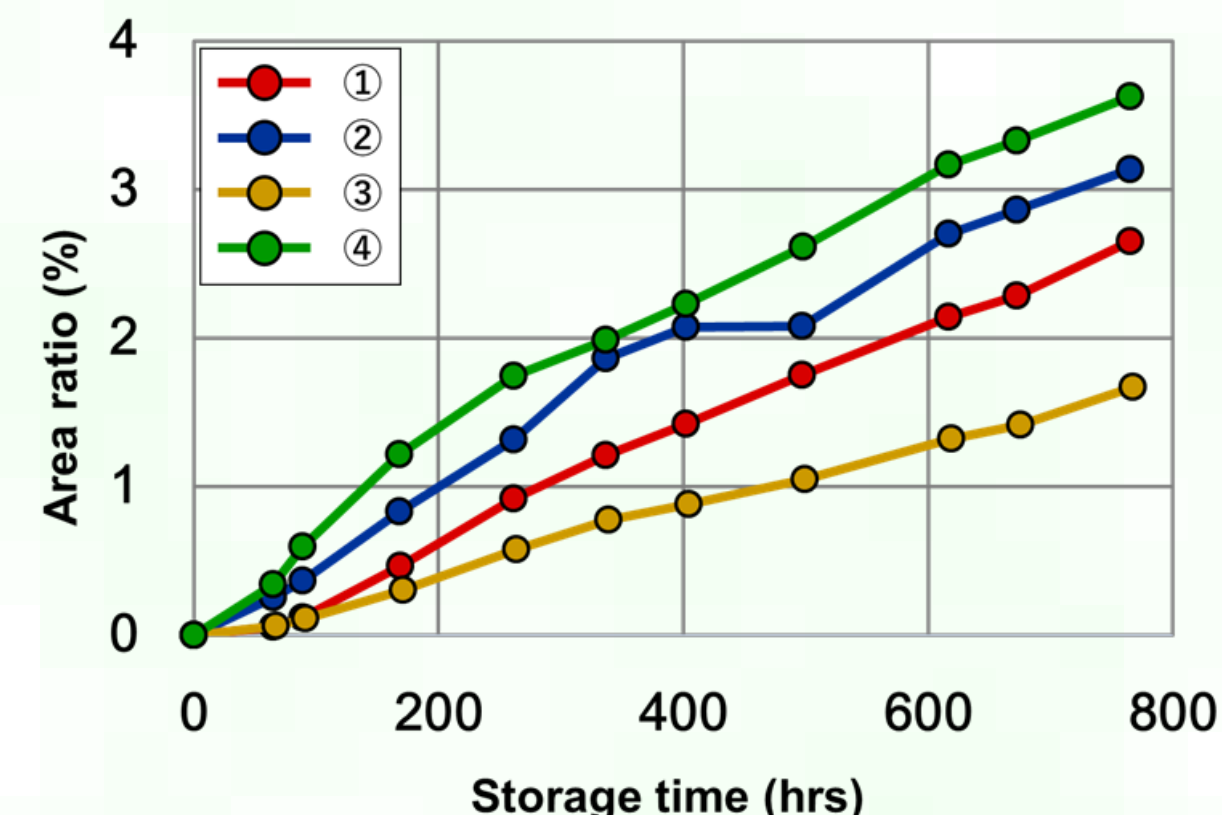
Structure of Ca corrosion device



Microscopic observation of Ca corrosion



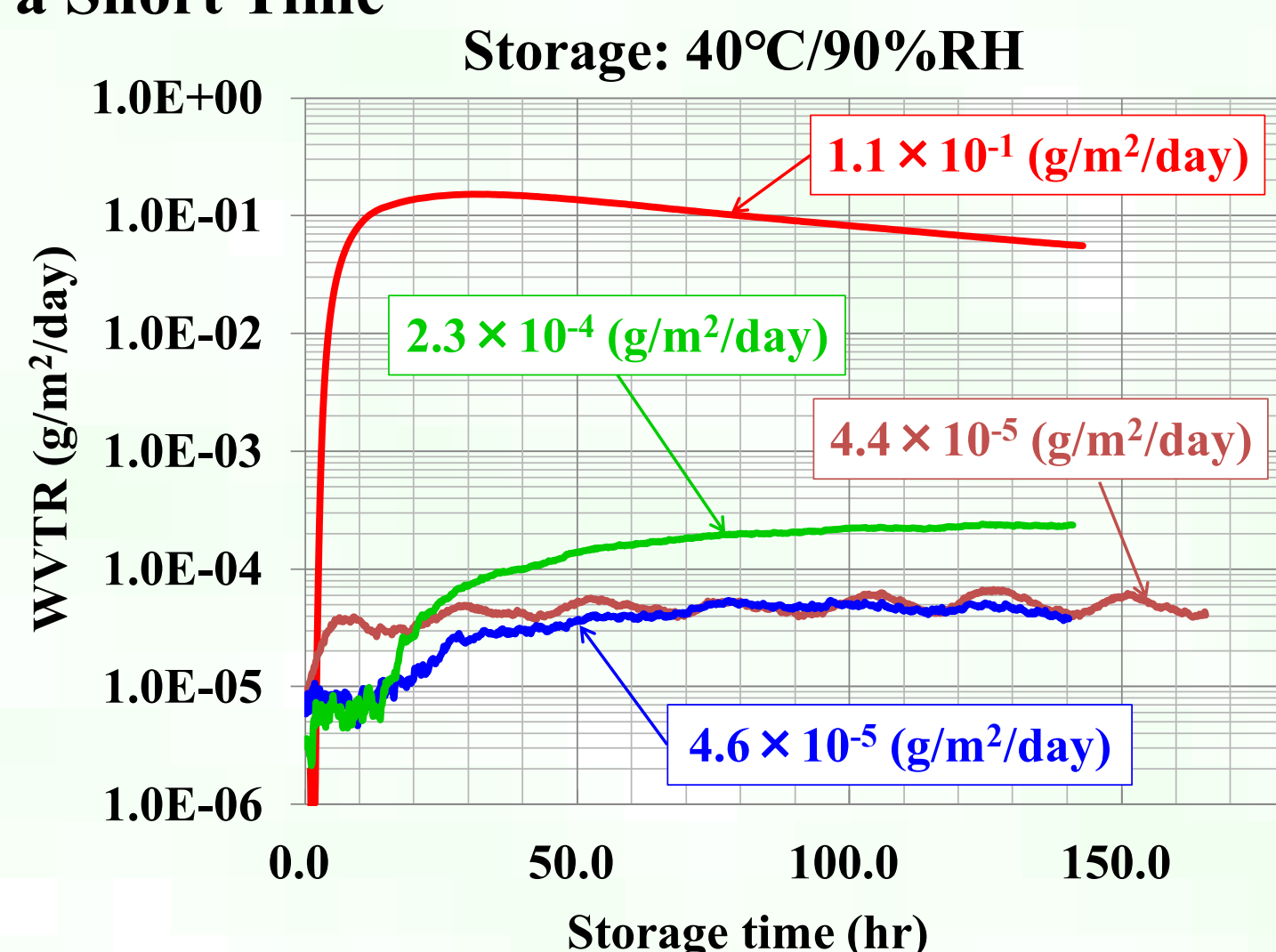
Evaluation equipment



MA method

WVTR (Water Vapor Transmission Rate) evaluation (Collaborating with MORESCO)

- We provide WVTR (Water Vapor Transmission Rate) evaluation, using the WVTR measurement equipment “**Super Detect**” of **MORESCO**.
- The “Super Detect” utilizes the MA method (Modified differential pressure method with an Attached support) developed by the collaboration of MORESCO and AIST (National Institute of Advanced Industrial Science and Technology).
- **SEMI D80** - Test Method for Measurement of Water Vapor Transmission Rate for High Gas Barrier Plastic Film in a Short Time



WVTR equipment
(MA method)



Evaluation of film substrate

- ✓ **SEMI D74** - Guide for Measuring Dimensions of Plastic Films/Substrates

Collaboration

TEIJIN LIMITED, MORESCO Corporation

Related program

- MEXT: Construction Program of Open Innovation Organization [FY2018~FY2022].
- JST: OPERA Program Grant Number JPMOP1614 [FY2016~FY2021].

Developed
technology

YU-FIC

Flexible OLEDs on Ultra-thin Glass

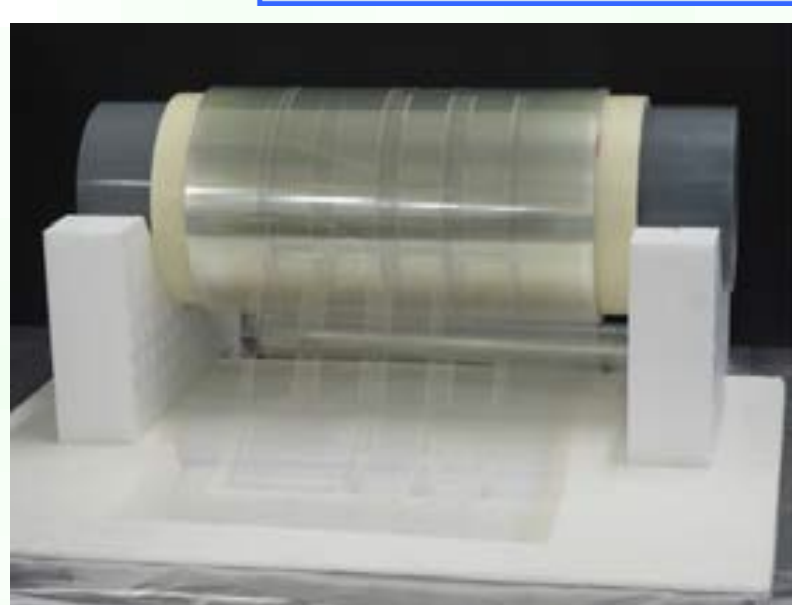
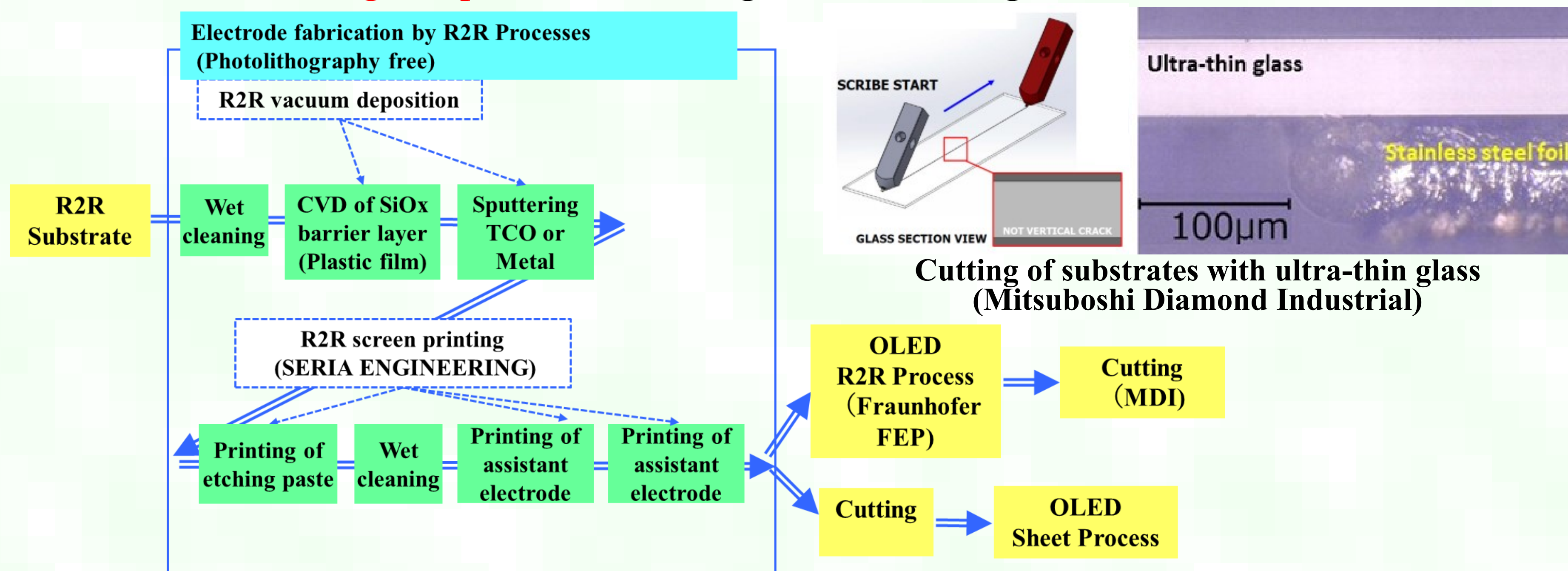
We develop flexible OLED lighting devices on **ultra-thin glass** with electrodes fabricated by roll-to-roll (R2R) technologies.

Technological features

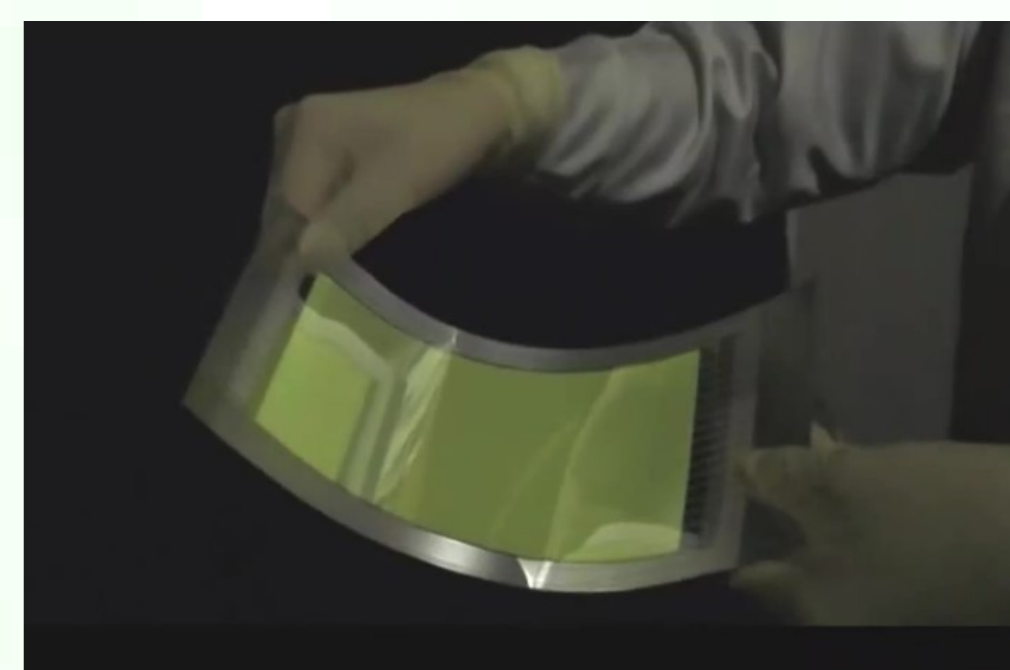
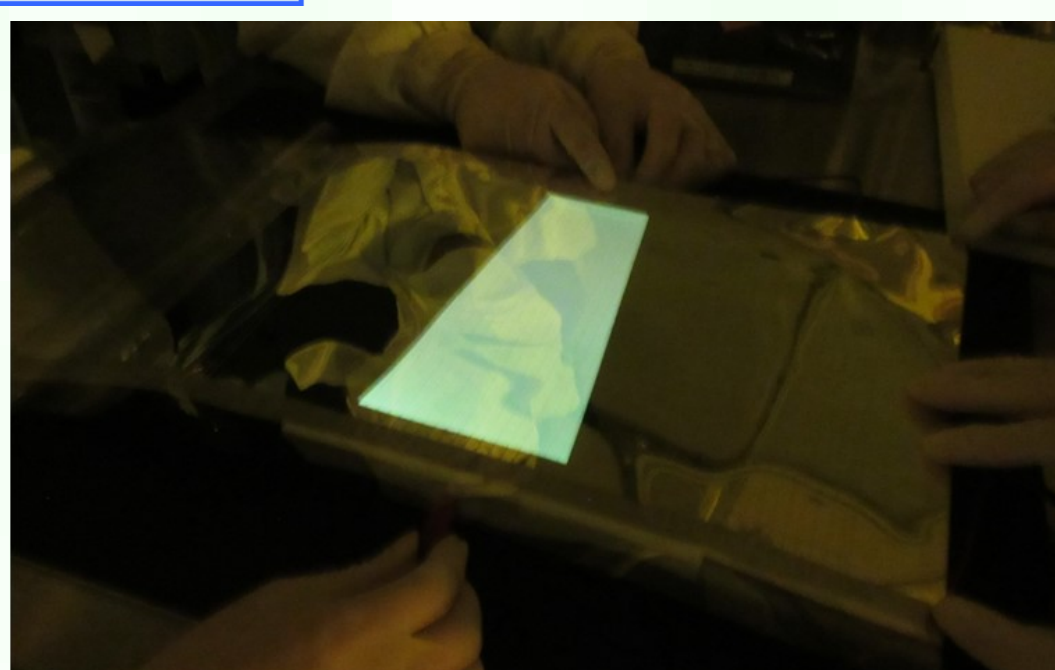
- Advantages of **ultra-thin glass G-Leaf®** of **Nippon Electric Glass**
 - Flexibility due to the thickness of **50μm**; Applicability to **Roll-to-roll (R2R)** fabrication
 - Intrinsic advantages of glass
(High gas barrier, surface smoothness, temperature stability, chemical stability, size stability, etc.)

Developed technologies

- Flexible OLED devices on ultra-thin glass with the thickness of 50μm.
 - Roll-to-roll (R2R) photolithography-free** fabrication of electrodes
 - Unique glass cutting** technology giving no damage to OLED devices with ultra-thin glass
 - Flexible laminating encapsulation** matching with ultra-thin glass



Ultra-thin glass with patterned electrodes (Nippon Electric Glass)



Collaboration

Fraunhofer FEP, Nippon Electric Glass Co., Ltd., SERIA ENGINEERING, INC., FEBACS CO., LTD., Mitsubishi Diamond Industrial Co., Ltd., NIPPON STEEL Chemical & Material Co., Ltd., FUJIKURA KASEI CO., LTD., Taica Corporation, tesa tape K.K.

Related program

- Yamagata University Flexible Electronics Japan-Germany International Collaborative Practical Utilization Consortium (YU-FIC) [Oct. 2017~Mar. 2023].
- JST: OPERA Program Grant Number JPMOP1614 [FY2016~FY2020].
- MEXT: Construction Program of Open Innovation Organization [FY2018~FY2022].

Publication

- T. Furukawa, M. Koden, IEICE Trans. Electron, E100-C, 949 (2017).
“Novel roll-to-roll deposition and patterning of ITO on ultra-thin glass for flexible OLEDs”
- T. Furukawa, J. Hauptmann, T. Nakagaki, R. Ikeuchi, M. Sagawa, D. Nagata, J. Nakatsuka, IDW’21, FLX5/FMC6-1 (2021). “Roll-to-Roll Fabrication for OLED Lighting Using Ultra-Thin Glass Substrate and Encapsulating Stainless Steel Foil”
- T. Nakagaki, T. Kawabata, H. Takimoto, T. Furukawa, IDW’19, FLXp1-9L (2019).
“Scribing Tool and Cutting Method for Ultra-thin Glass”
- T. Furukawa, K. Mitsugi, S. Akiyama, H. Itoh, D. Kobayashi, T. Suzuki, H. Kuroiwa, M. Sakakibara, K. Tanaka, M. Kawamura, M. Koden, IDW’14, FLX3-4 (2014). “Patterned ITO Film by Roll-to-Roll Process on Ultra-thin Glass”

Developed
technology

YU-FIC

Improved Mechanical Strength of Flexible OLEDs on Ultra-thin Glass

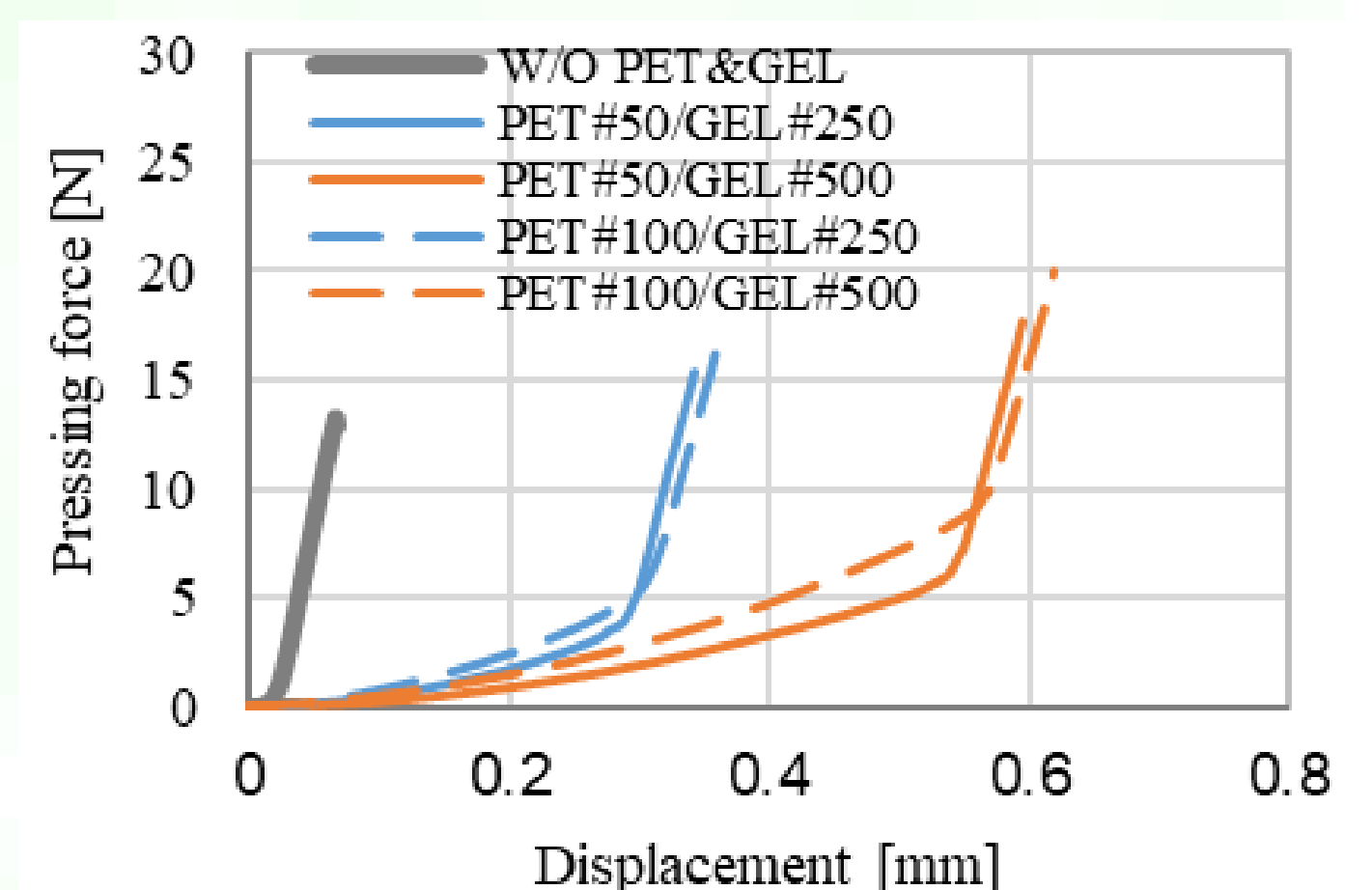
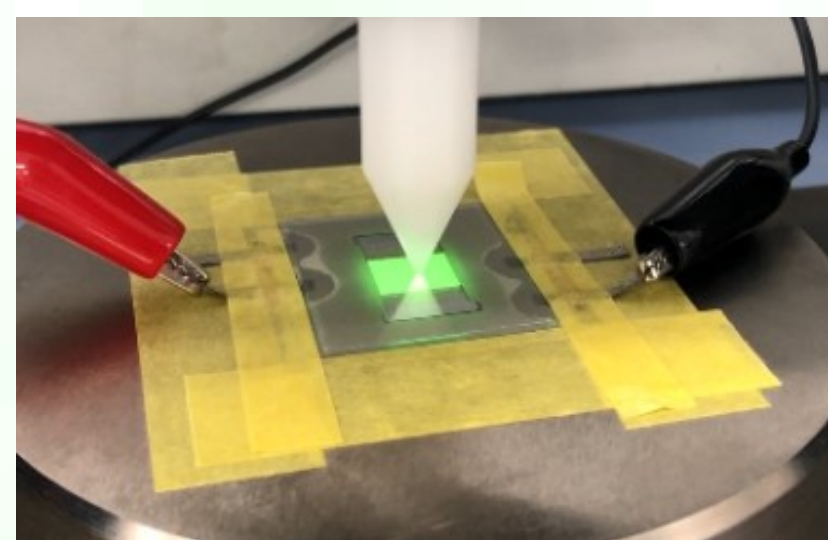
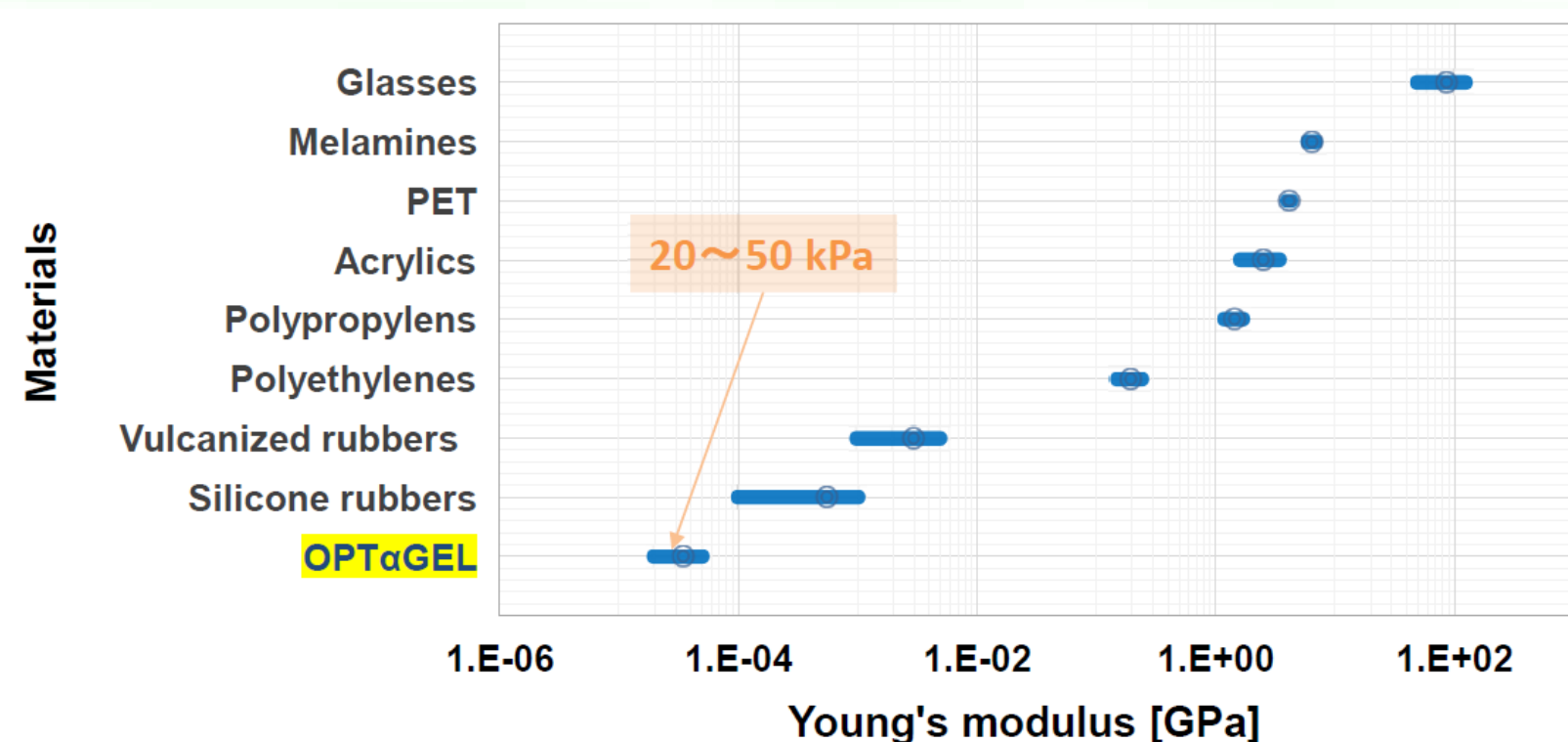
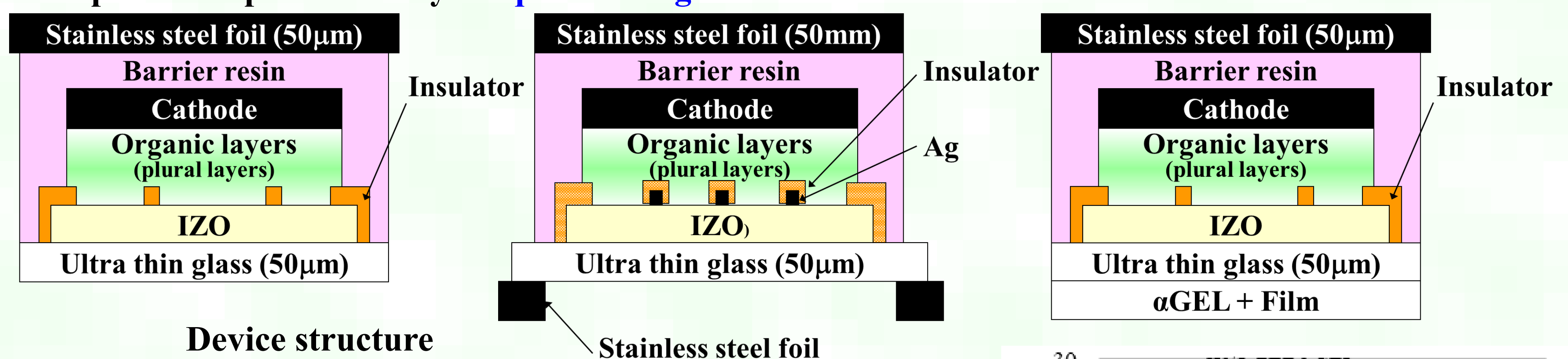
We develop technologies for **improvement of mechanical strength** of flexible OLED devices fabricated on ultra-thin glass.

Technological features

- Improved mechanical strength of flexible OLED devices **ultra-thin glass** with the thickness of 50 μ m.

Developed technologies

- Improved mechanical strength by encapsulation with **stainless steel foil**.
- Reduced side edge crack under **glass cutting**.
- Improved impact stress by **unique silicon gel**.



Young's modulus of various materials

Pressure stress test (α GEL)

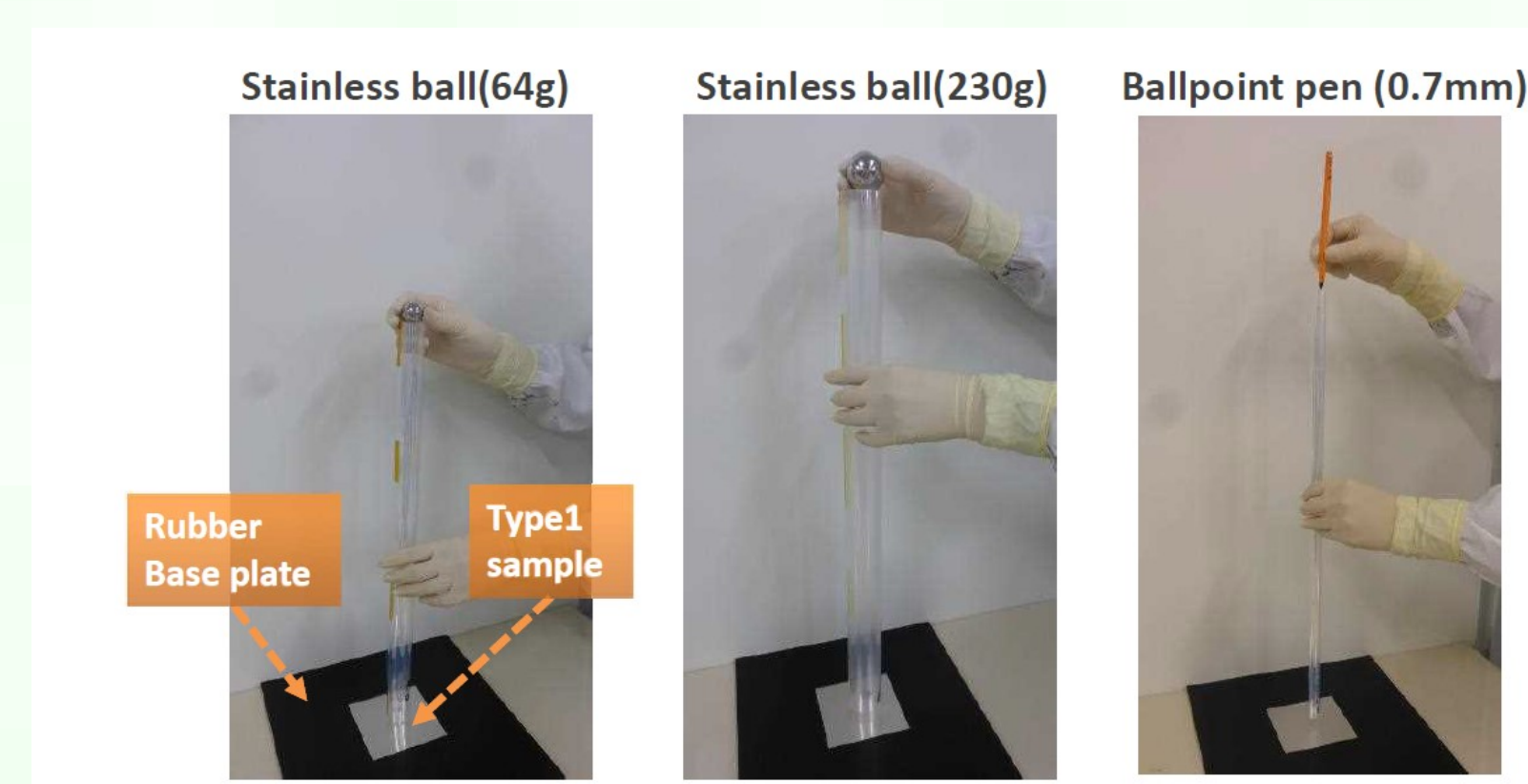


Table Drop impact test result				
Protection layer		Height when glass cracked [cm]		
Cover film / Thickness [μ m]	Needle penetration [1/10mm]	Stainless ball drop 64 [g]	Stainless ball drop 230 [g]	Ballpoint pen drop
-	-	60~80	20~40	10
PET / 100	-	90~100	60~80	20~50
PC / 200	-	50~60	> 100	50~70
PET / 100	130	> 100	70	50~60
PC / 200	130	> 100	90	50~70
PC / 200	90	> 100	> 100	80
PC / 200	50	> 100	100	50~60
PC / 200	25	> 100	80~90	60

Drop Impact test (α GEL)

Collaboration

Nippon Electric Glass Co., Ltd., Mitsuboshi Diamond Industrial Co., Ltd., NIPPON STEEL Chemical & Material Co., Ltd., Taica Corporation, tesa tape K.K.

Related program

- Yamagata University Flexible Electronics Japan-Germany International Collaborative Practical Utilization Consortium (YU-FIC) [Oct. 2017~Mar. 2023].
- JST: OPERA Program Grant Number JPMOP1614 [FY2016~FY2020].
- MEXT: Construction Program of Open Innovation Organization [FY2018~FY2022].

Publication

- T. Furukawa, J. Hauptmann, T. Nakagaki, R. Ikeuchi, M. Sagawa, D. Nagata, J. Nakatsuka, IDW'21, FLX5/FMC6-1 (2021). "Roll-to-Roll Fabrication for OLED Lighting Using Ultra-Thin Glass Substrate and Encapsulating Stainless Steel Foil"
- M. Natsuka, Y. Ono, H. Mataki, S. Usui, H. Suzuki, M. Abe, T. Furukawa, IDW'21, FLX5/FMC6-2 (2021). "Protection of OLED Lighting with Ultra-Thin Glass by Special Silicone Gel"

Developed
technology

YU-FIC

Flexible OLEDs on Stainless Steel Foil or Barrier Film

We develop flexible OLED devices on **stainless steel foil** of NIPPON STEEL CORPORATION GROUP or **PEN film** of Teijin.

Technological features

■ Stainless steel foils of NIPPON STEEL CORPORATION GROUP

- Thickness: 50μm or 30μm
- Excellent surface smoothness (Ra~0.6nm)
- Excellent temperature and process resistances
- High gas barrier ability

■ PEN or PET film

- Roll-to-roll (R2R) CVD for barrier layer
- High gas barrier: WVTR~10⁻⁶g/m²/day
(WVTR: Water Vapor Transmission Rate)

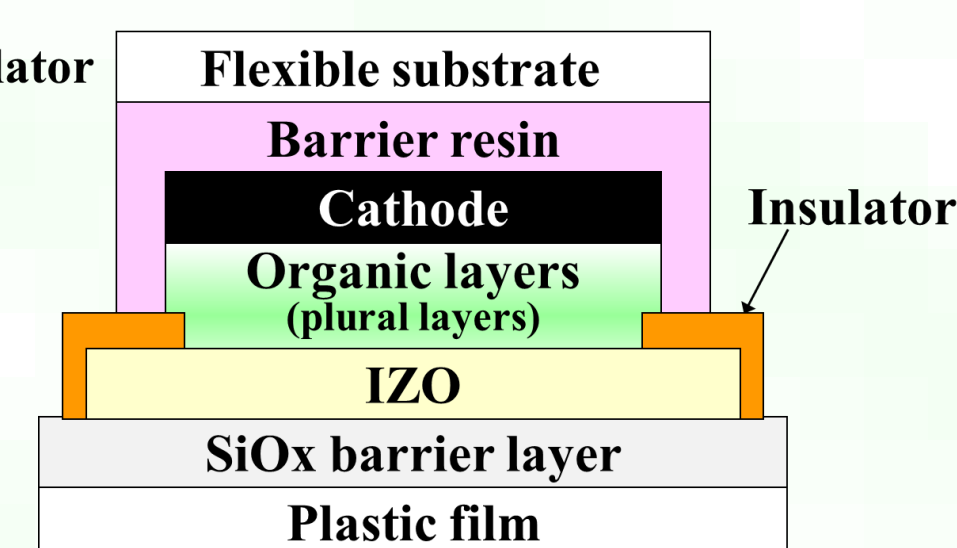
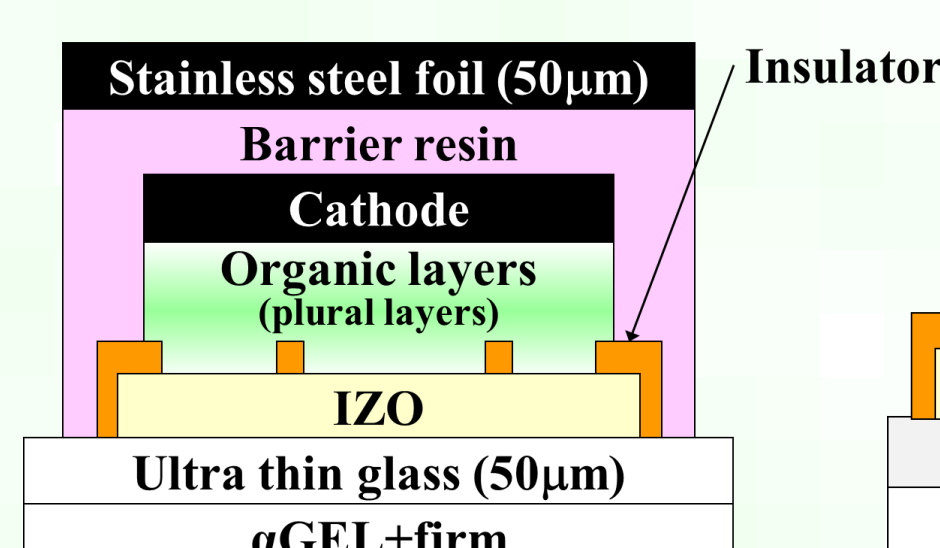
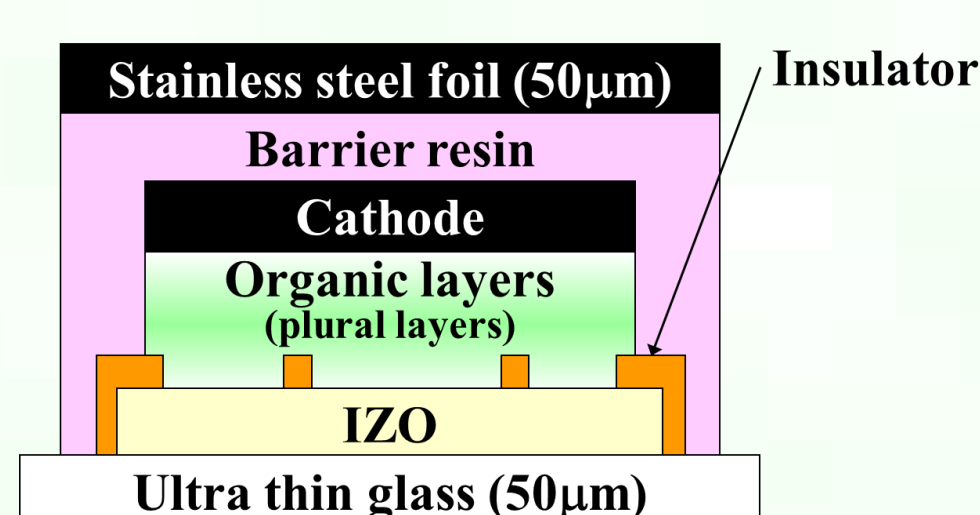
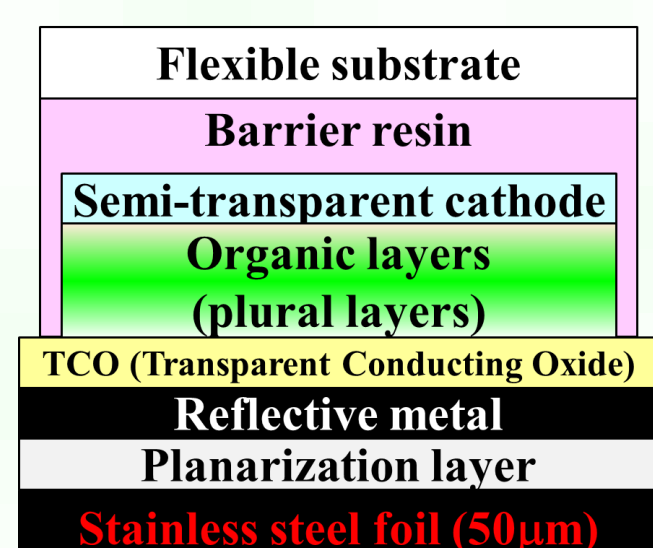
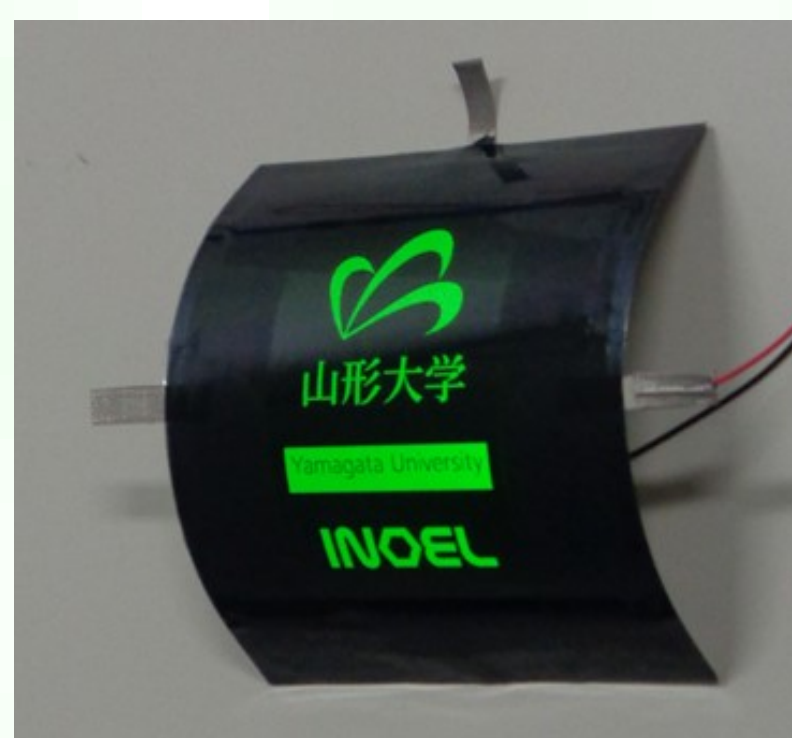
Developed technologies

■ Stainless steel foil

- Reflective electrode fabrication by **Roll-to-roll (R2R) photolithography-free processes**
- Prototype flexible OLEDs on stainless steel foil
- Laminating encapsulation with stainless steel foil for improving mechanical strength of flexible OLED devices on ultra-thin glass

■ Barrier film

- **Roll-to-roll (R2R) fabrication of single layer barrier and transparent electrode** on flexible film
- Prototype flexible OLEDs on barrier film



Collaboration

TEIJIN LIMITED, NIPPON STEEL Chemical & Material Co., Ltd., Nippon Electric Glass Co., Ltd., Mitsuboshi Diamond Industrial Co., Ltd., FUJIKURA KASEI CO., LTD., tesa tape K.K.

Related program

- Yamagata University Flexible Electronics Japan-Germany International Collaborative Practical Utilization Consortium (YU-FIC) [Oct. 2017~Mar. 2023].
- MEXT: Construction Program of Open Innovation Organization [FY2018~FY2022].

Publication

- K. Taira, Taiga Suzuki, W. Konno, H Chiba, H. Itoh, M. Koden, T. Takahashi, T. Furukawa, IDW'18, FLX2-4L (2019). "Development of High Gas Barrier Film Using Novel Precursor by Roll to Roll PECVD"
- T. Suzuki, W. Konno, K. Taira, H Chiba, H. Itoh, M. Koden, T. Takahashi, T. Furukawa, IDW'18, FLXp1-10L (2019). "High Gas Barrier Films with Heterogeneous Multilayer"
- K. Taira, T. Furukawa, N. Kawamura, M. Koden, T. Takahashi, IDW'17, FLXp1-8L (2018). "High gas barrier film for OLED"
- T. Furukawa, N. Kawamura, M. Koden, H. Itoh, H. Kuroiwa, K. Nagai, LOPEC (2017). "Gas barrier film for OLED devices"
- Y. Hagiwara, T. Furukawa, T. Yuki, S. Yamaguchi, N. Yamada, J. Nakatsuka, M. Koden, H. Nakada, IDW'17, FLXp1-9L (2017). "Roll-to-Roll Patterning of Reflective Electrode on Planarized Stainless Steel Foil"
- M. Koden, T. Furukawa, T. Yuki, H. Kobayashi, H. Nakada, IDW/AD'16, FLX3-1 (2016). "Substrates and Non-ITO Electrodes for Flexible OLEDs"
- Y. Hagiwara, H. Itoh, T. Furukawa, H. Kobayashi, S. Yamaguchi, N. Yamada, J. Nakatsuka, M. Koden, H. Nakada, IDW/AD'16, FLXp1-5 (2016). "Roll-to-Roll Processing of Silver/ITO Continuous Deposition on Planarized Stainless Steel Foil"

Developed
technology

YU-FIC

Roll-to-Roll (R2R) Fabrication of Barrier Film with Transparent Electrode

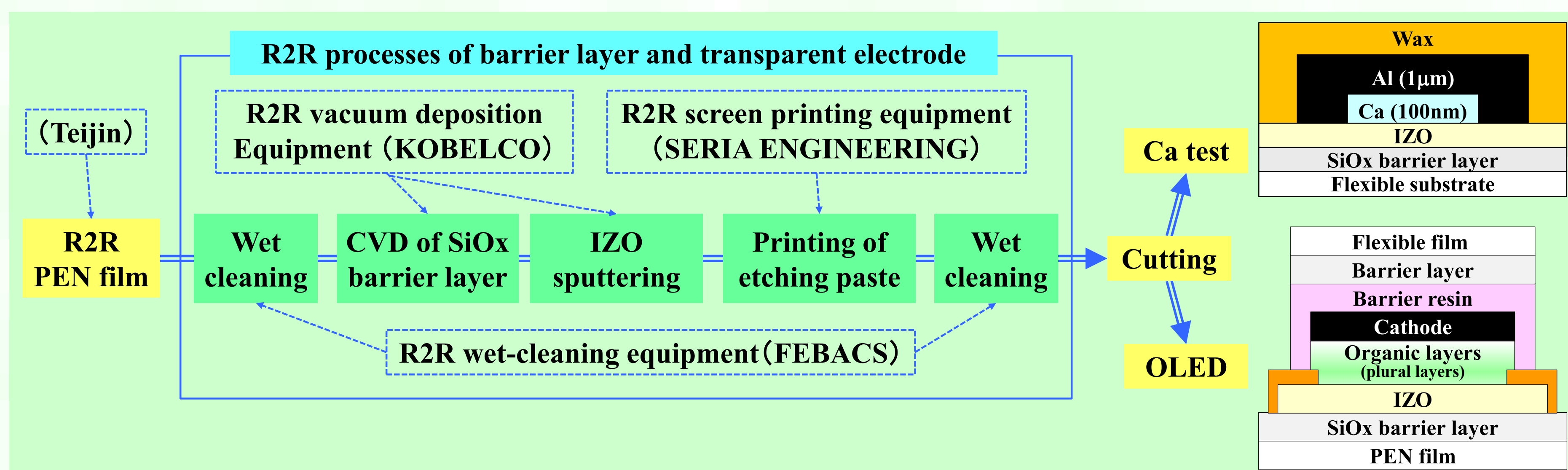
We develop fabrication technologies of gas barrier layer and transparent electrode on flexible films, using **roll-to-roll (R2R)** depositions, which are **PE-CVD (Plasma Enhanced Chemical Vapor Deposition)** and **sputtering**.

Technological features

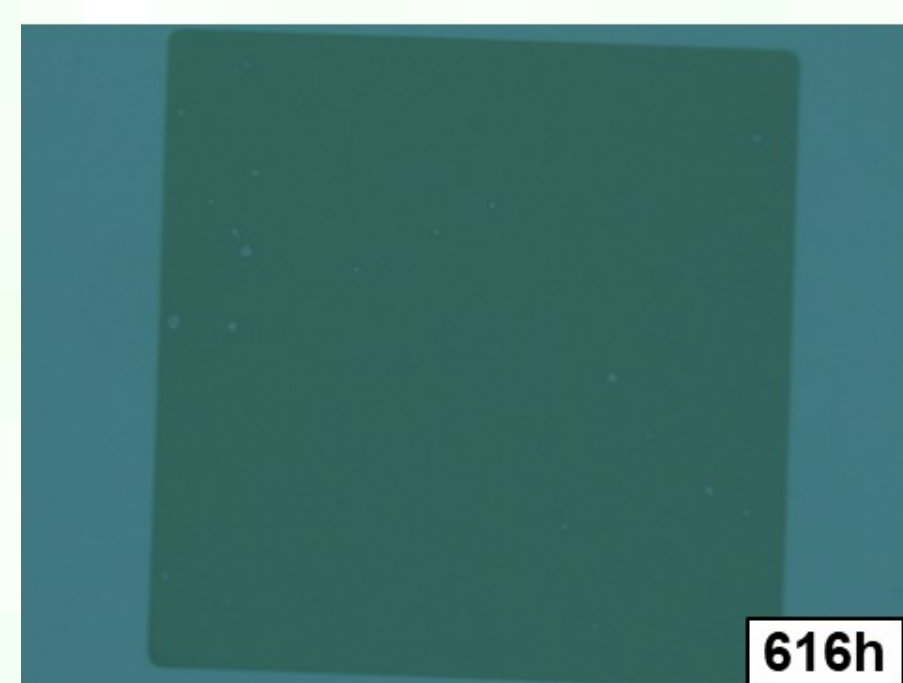
- Roll-to-roll (R2R) PE-CVD deposition of gas barrier layer on flexible films
- High barrier ability with WVTR (Water Vapor Transmission Rate) of the order of $10^{-6}\text{g/m}^2/\text{day}$
- **High gas barrier films with transparent electrode**

Developed technologies

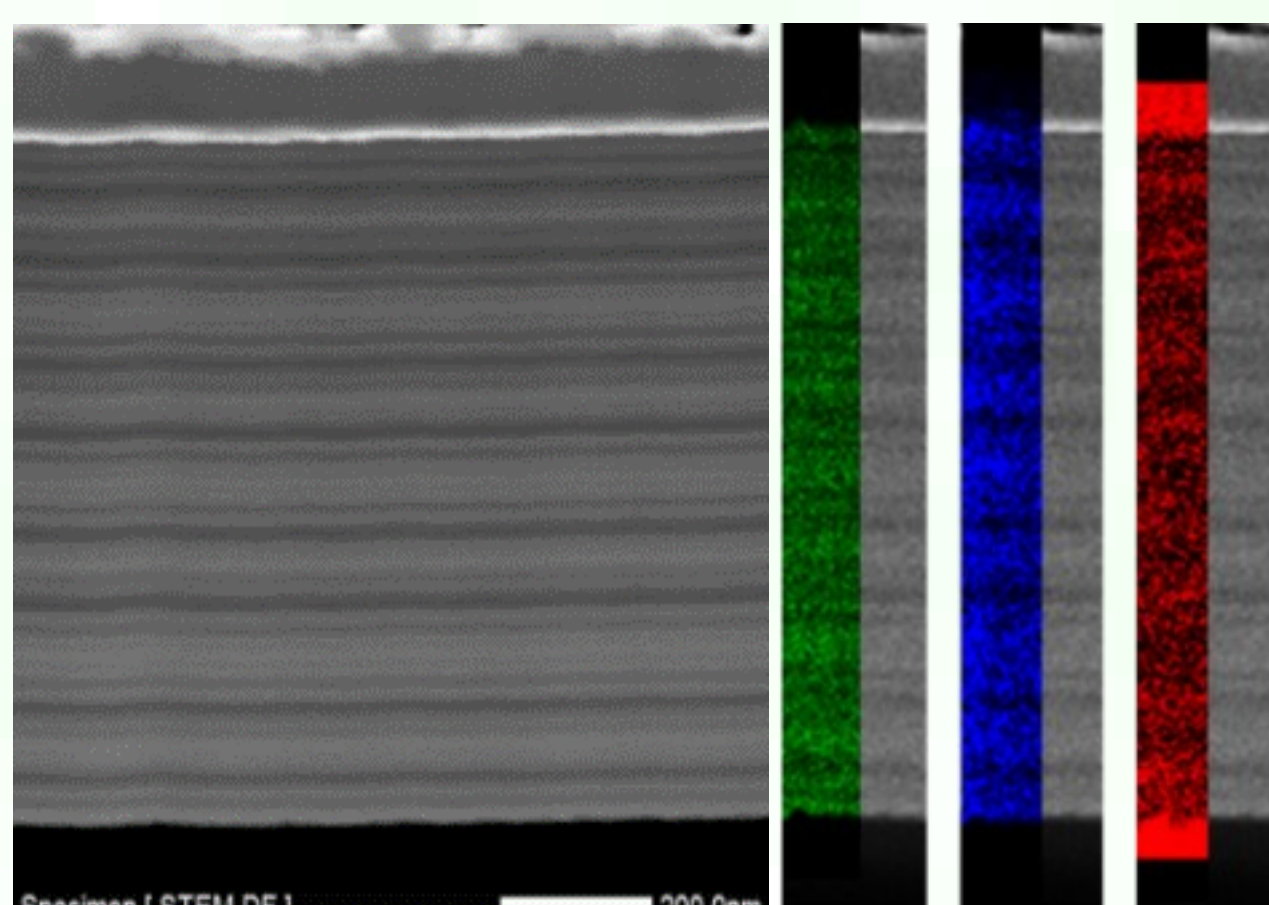
- **Roll-to-roll (R2R) photolithography-free** fabrication of barrier layer and transparent electrode on flexible films



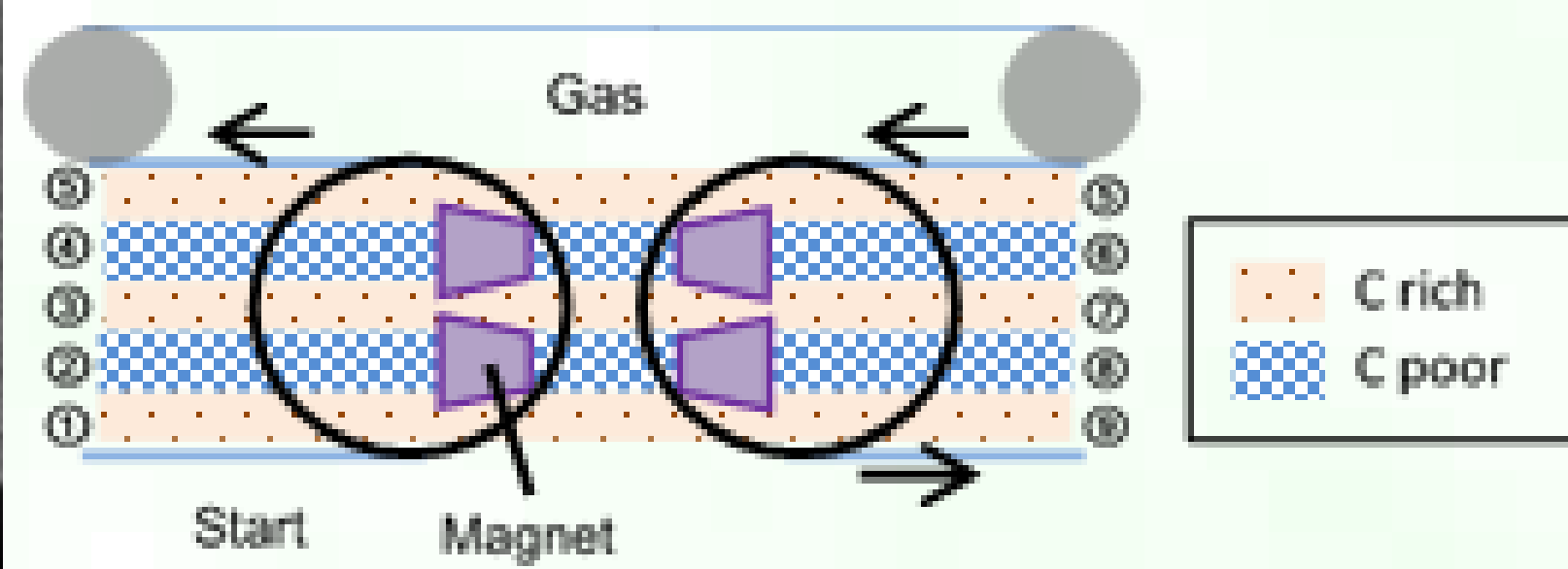
- **High gas barrier property: WVTR = $6.3 \times 10^{-6}\text{g/m}^2/\text{day}$**



Ca corrosion device after 616 hours
under 40°C/90%RH
(Thickness of barrier layer: 720nm)



Cross section of barrier layer



CVD deposition mechanism

Collaboration

TEIJIN LIMITED, Tosoh Corporation, MORESCO Corporation

Related program

- Yamagata University Flexible Electronics Japan-Germany International Collaborative Practical Utilization Consortium (YU-FIC) [Oct. 2017~Mar. 2023].
- MEXT: Construction Program of Open Innovation Organization [FY2018~FY2022].

Publication

- K. Taira, Taiga Suzuki, W. Konno, H Chiba, H. Itoh, M. Koden, T. Takahashi, T. Furukawa, IDW'18, FLX2-4L (2018). "Development of High Gas Barrier Film Using Novel Precursor by Roll to Roll PECVD"
- T. Suzuki, W. Konno, K. Taira, H Chiba, H. Itoh, M. Koden, T. Takahashi, T. Furukawa, IDW'18, FLXp1-10L (2018). "High Gas Barrier Films with Heterogeneous Multilayer"
- K. Taira, T. Furukawa, N. Kawamura, M. Koden, T. Takahashi, IDW'17, FLXp1-8L (2017). "High gas barrier film for OLED"
- T. Furukawa, N. Kawamura, M. Koden, H. Itoh, H. Kuroiwa, K. Nagai, LOPEC (2017). "Gas Barrier Film for OLED Devices"

In-Mold Electronics (IME) Technology

We develop novel **in-mold electronics (IME)** technologies, molding functional components, printed electrodes on flexible substrates.

Technological features

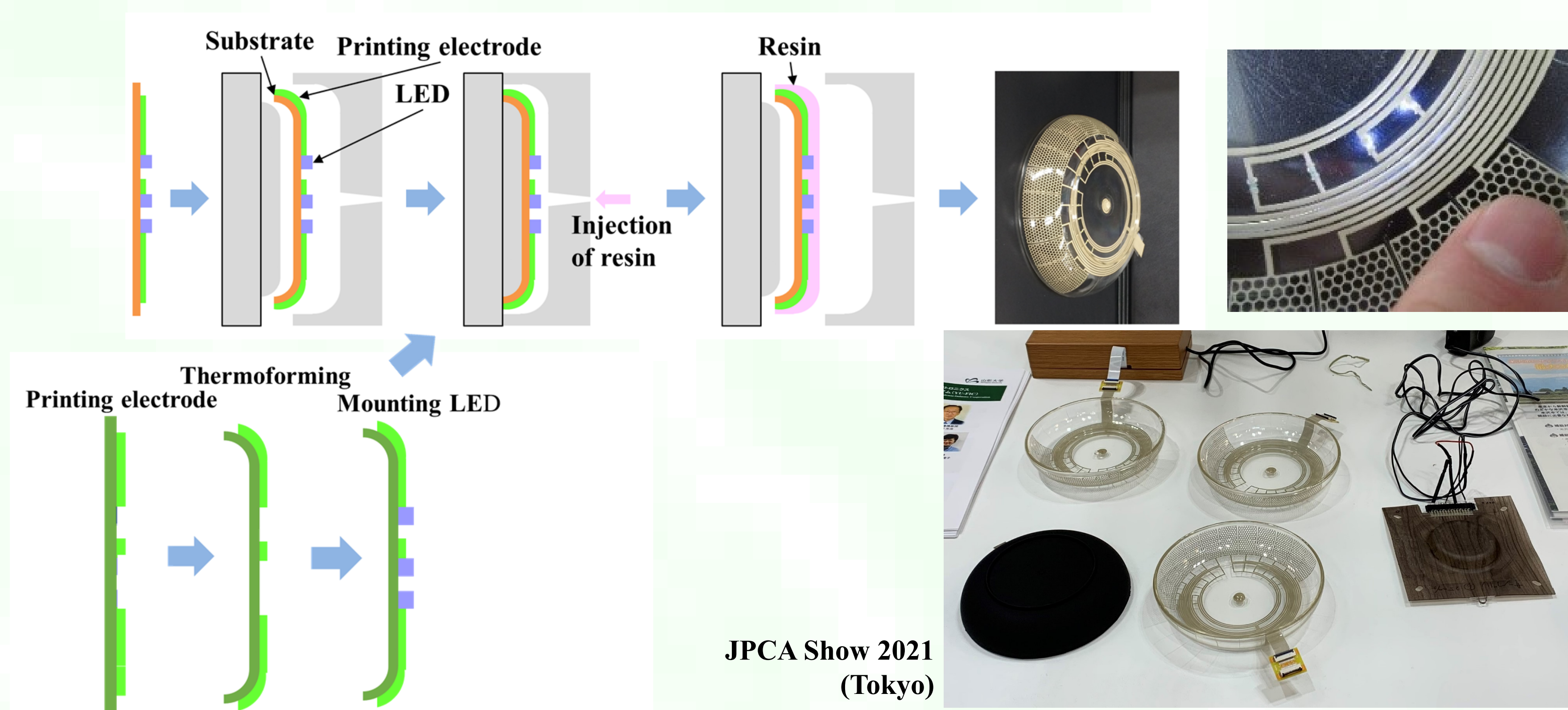
- **3D-molding technologies** with electrodes
- Process simplification in fabrication of circuit board by **printing technologies**

Applications

- Sensors (agricultural sensors, in-water sensors, etc.)
- Automotive interiors (lighting, controller, etc. of instrument panels and consoles)
- Thin IoT devices

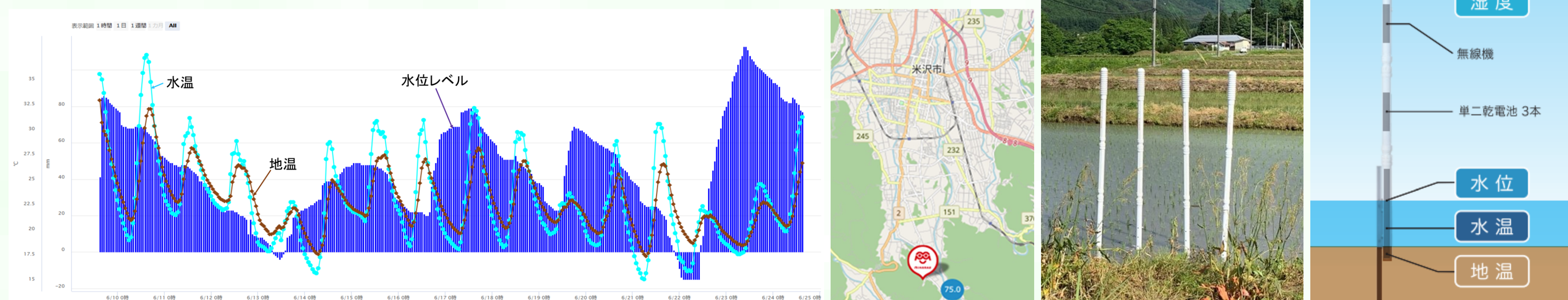
Developed technologies

- **3D-shaped prototype with touch screen and LEDs**



- **Agricultural sensor / Verification test**

- Applied to agricultural sensors of **Nishimu Electronics Industries**
- Verification test in Paddy fields of Yonezawa city and Tome city.



Collaboration

Aiwa Lite Corporation, The Japan Steel Works, LTD., TEIJIN LIMITED, FUJIKURA KASEI CO., LTD., Nishimu Electronics Industries Co., Ltd.

Related program

- Yamagata University Flexible Electronics Japan-Germany International Collaborative Practical Utilization Consortium (YU-FIC) [Oct. 2017~Mar. 2023].
- MEXT: Construction Program of Open Innovation Organization [FY2018~FY2022].

Publication

- Y. Kawamura, T. Takahashi, T. Furukawa, ICFPE 2021, 2Rm401-08-02 (2021). "Student Oral Presentation Award" "Improvement of printed electrodes disconnection after 3D thermoforming by optimizing print process on PC film"
- Y. Kawamura, T. Takahashi, K. Wakabayashi, H. Hirose, Y. Azakami, H. Itoh, T. Furukawa, IDW'20, FLX3-04L (2020). "Effect of Pressure Forming Conditions on PC Sheet integrating Electric Wiring for 3D Electronics Technology"
- 山形大学; 「有機デバイス総合展」(2021.10 / 東京ビッグサイト).
- 山形大学; 「JFlex2020展」(2020.1 / 東京ビッグサイト), 「JFlex2021展」(2020.12 / オンライン).

Developed
technology

Mechanism analysis of electrode disconnection in 3D thermoforming

We study on <https://sid.onlinelibrary.wiley.com/toc/21680159/2008/39/1> processes.

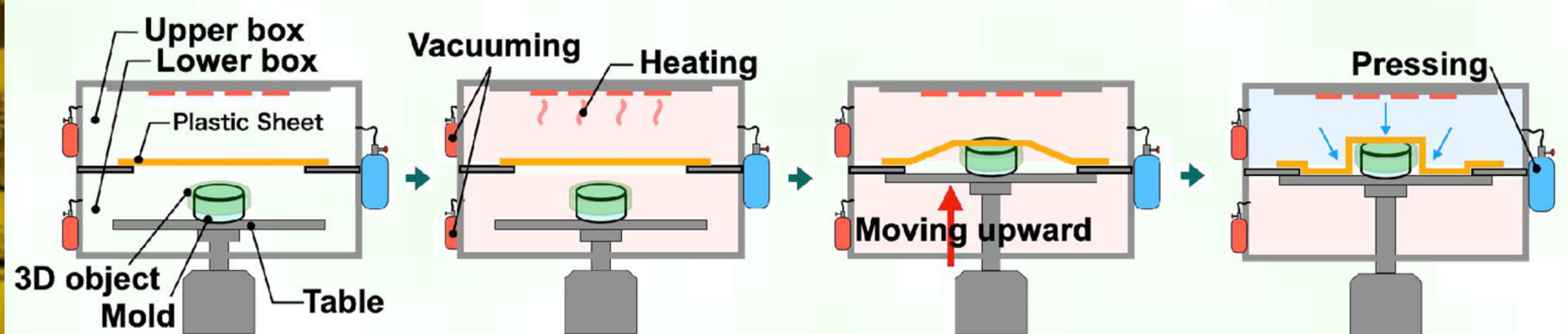
Processes



Screen printing
equipment

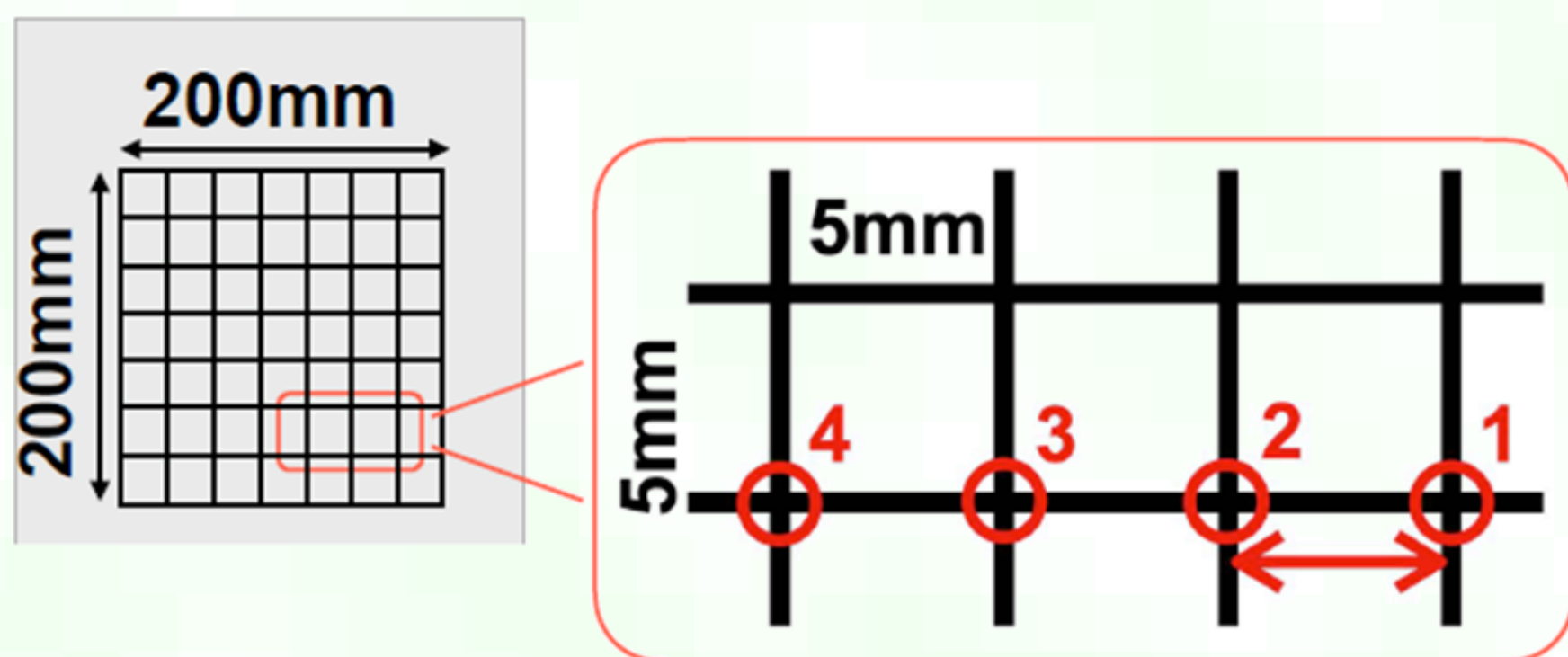


3D thermoforming
equipment

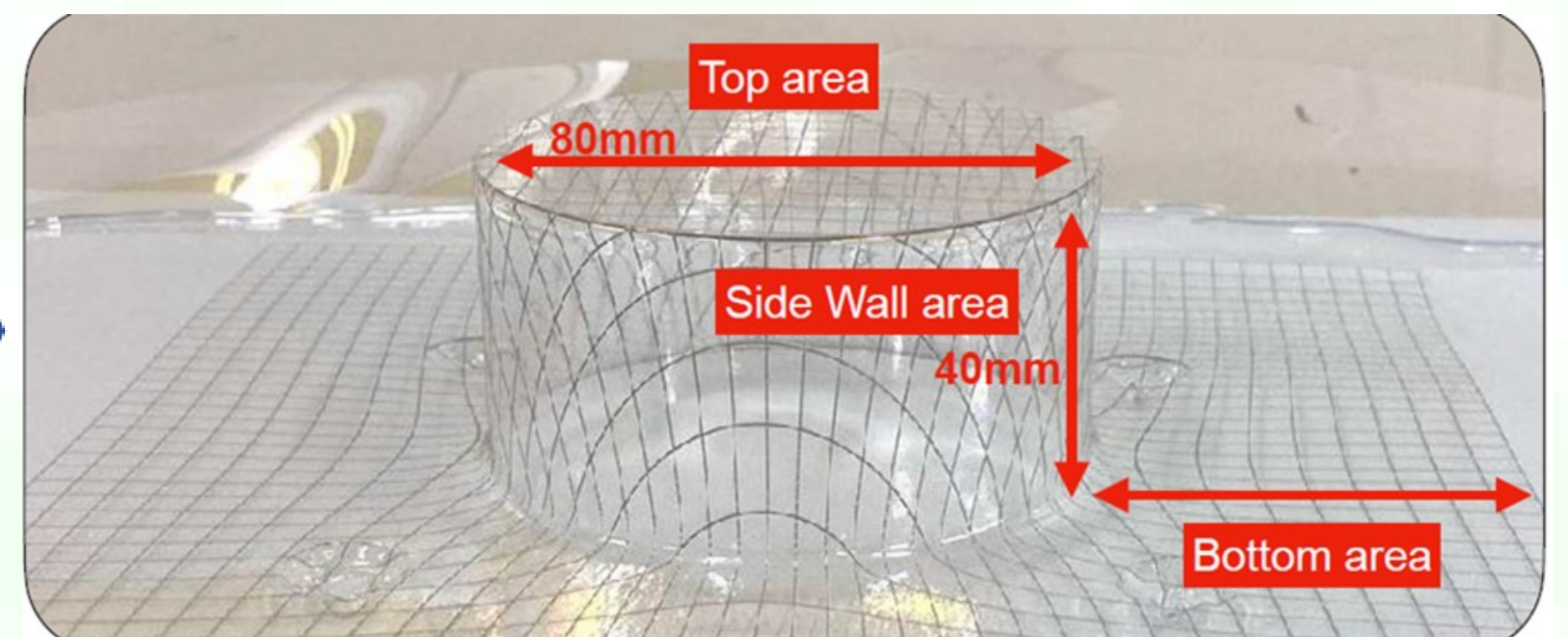


3D thermoforming process

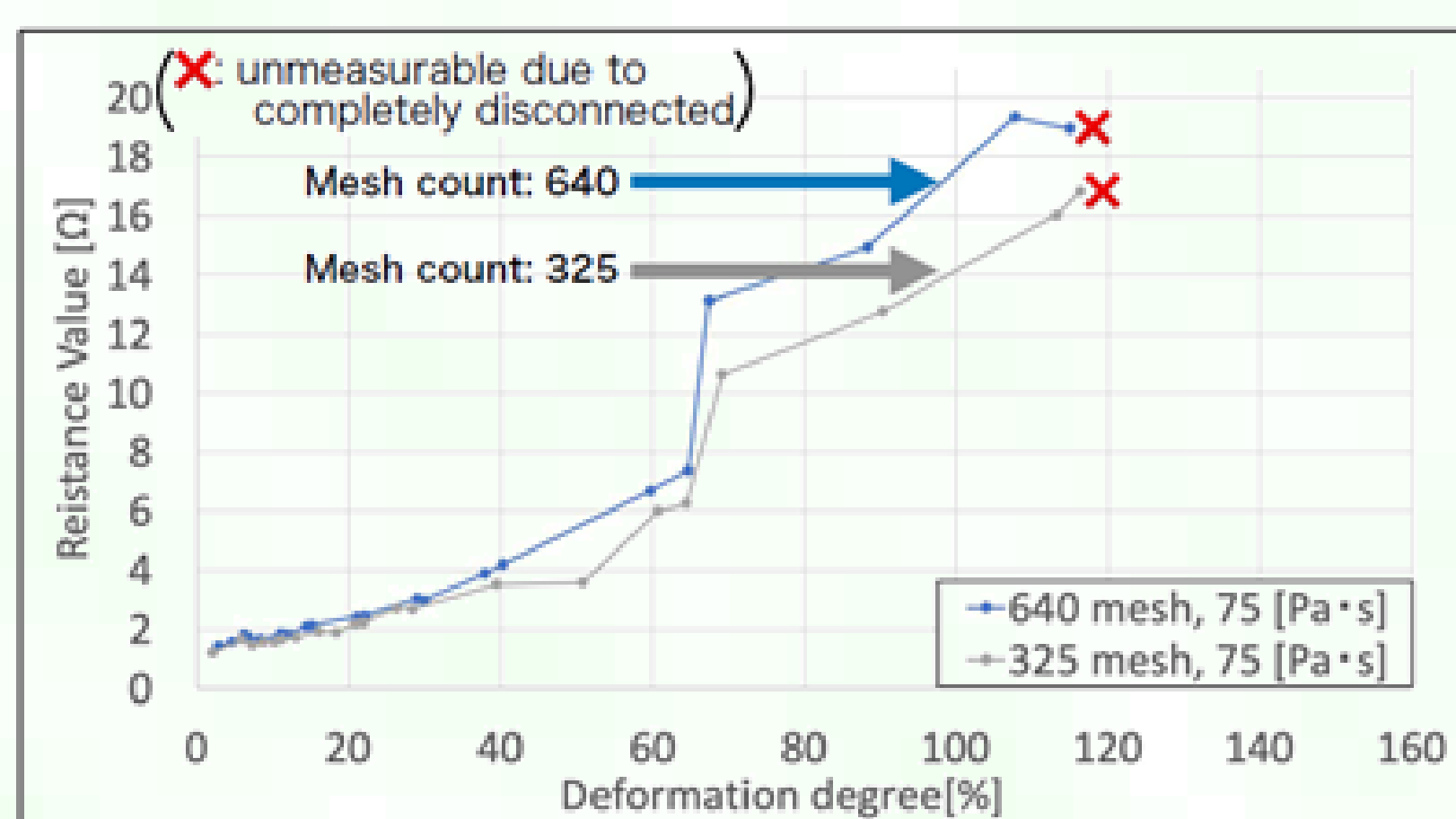
Thermoforming experiments



Printing of conducting paste on plastic sheet

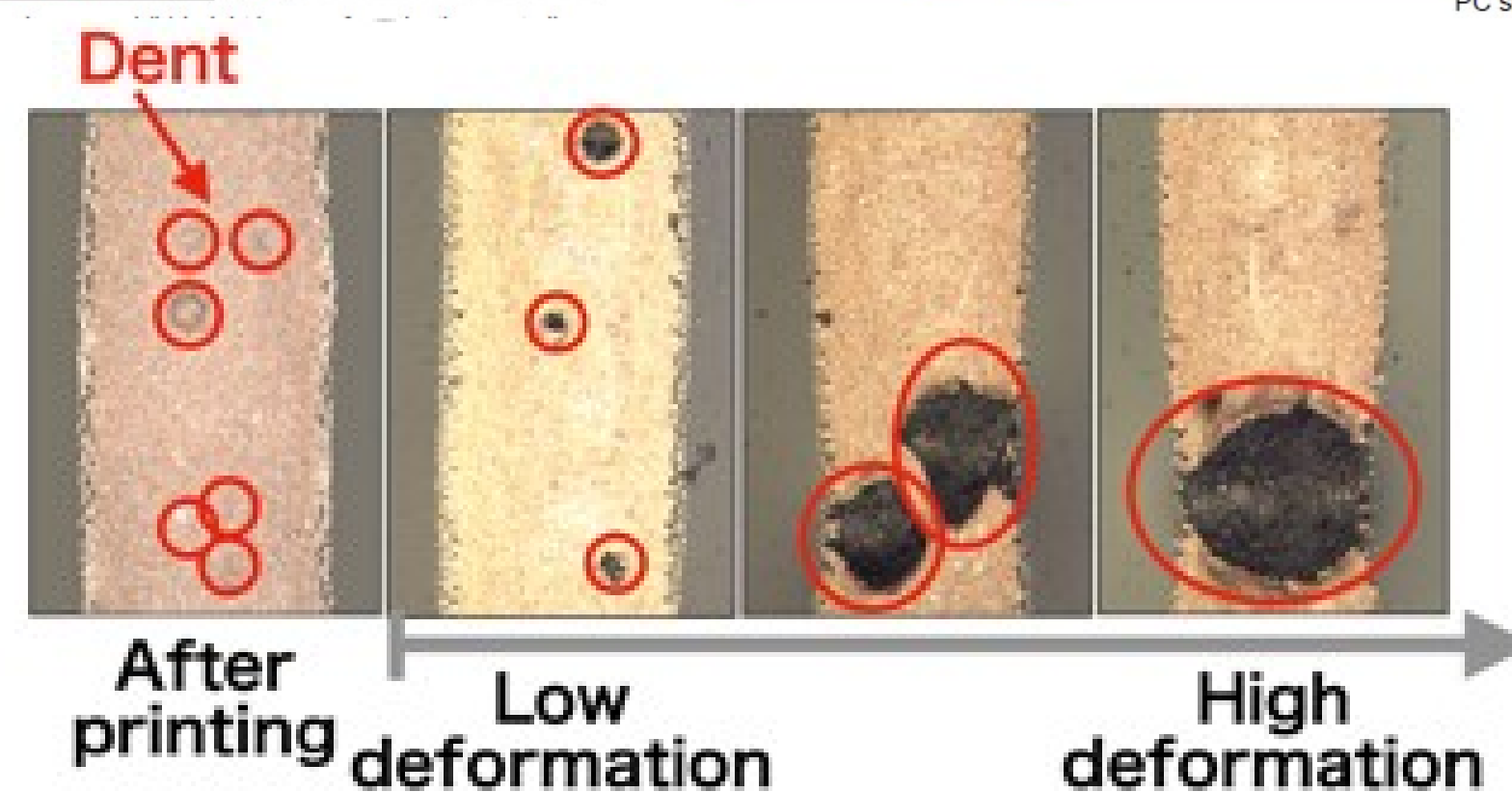
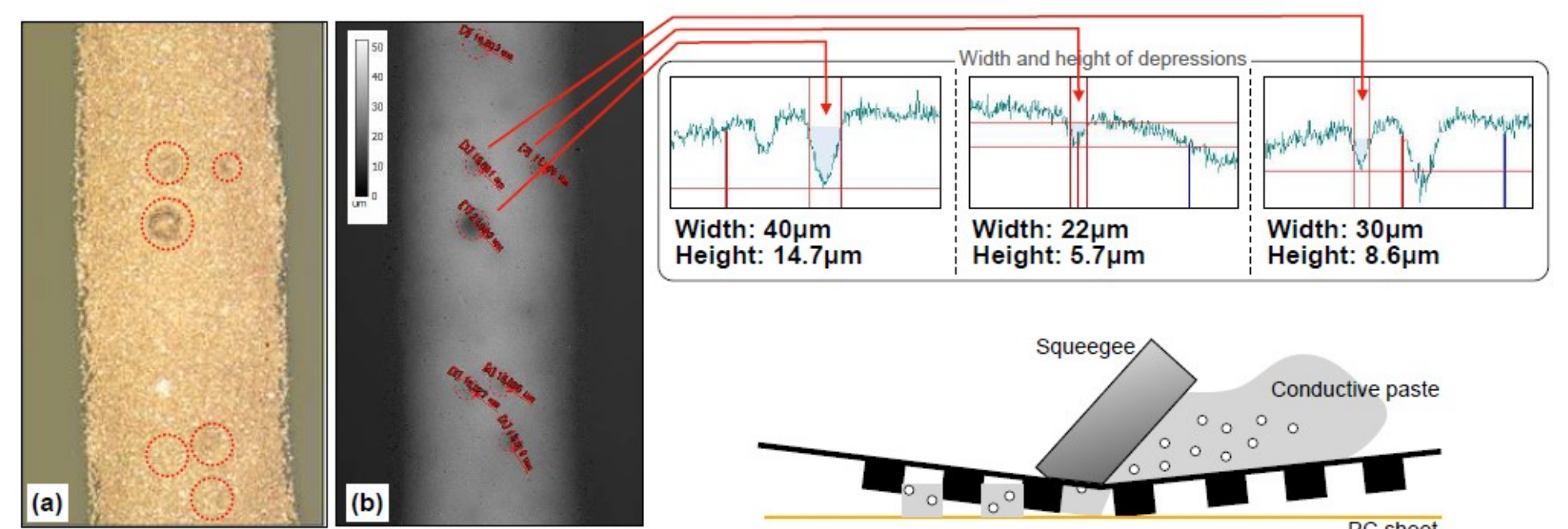


Thermoforming



[Relation between resistance value and deformation degree]

Relationship between deformation degree
of substrate and electrical resistance



Mechanism of electrode disconnection

Collaboration

TEIJIN LIMITED, FUJIKURA KASEI CO., LTD.

Related program

- Yamagata University Flexible Electronics Japan-Germany International Collaborative Practical Utilization Consortium (YU-FIC) [Oct. 2017~Mar. 2021].
- JST: OPERA Program Grant Number JPMOP1614 [FY2016~FY2020].
- MEXT: Construction Program of Open Innovation Organization [FY2018~FY2022].

Publication

- Y. Kawamura, T. Takahashi, T. Furukawa, ICFPE 2021, 2Rm401-08-02 (2021). "Student Oral Presentation Award" "Improvement of printed electrodes disconnection after 3D thermoforming by optimizing print process on PC film"
- Y. Kawamura, T. Takahashi, K. Wakabayashi, H. Hirose, Y. Azakami, H. Itoh, T. Furukawa, IDW'20, FLX3-04L (2020). "Effect of Pressure Forming Conditions on PC Sheet integrating Electric Wiring for 3D Electronics Technology"

Developed
technology

YU-FIC

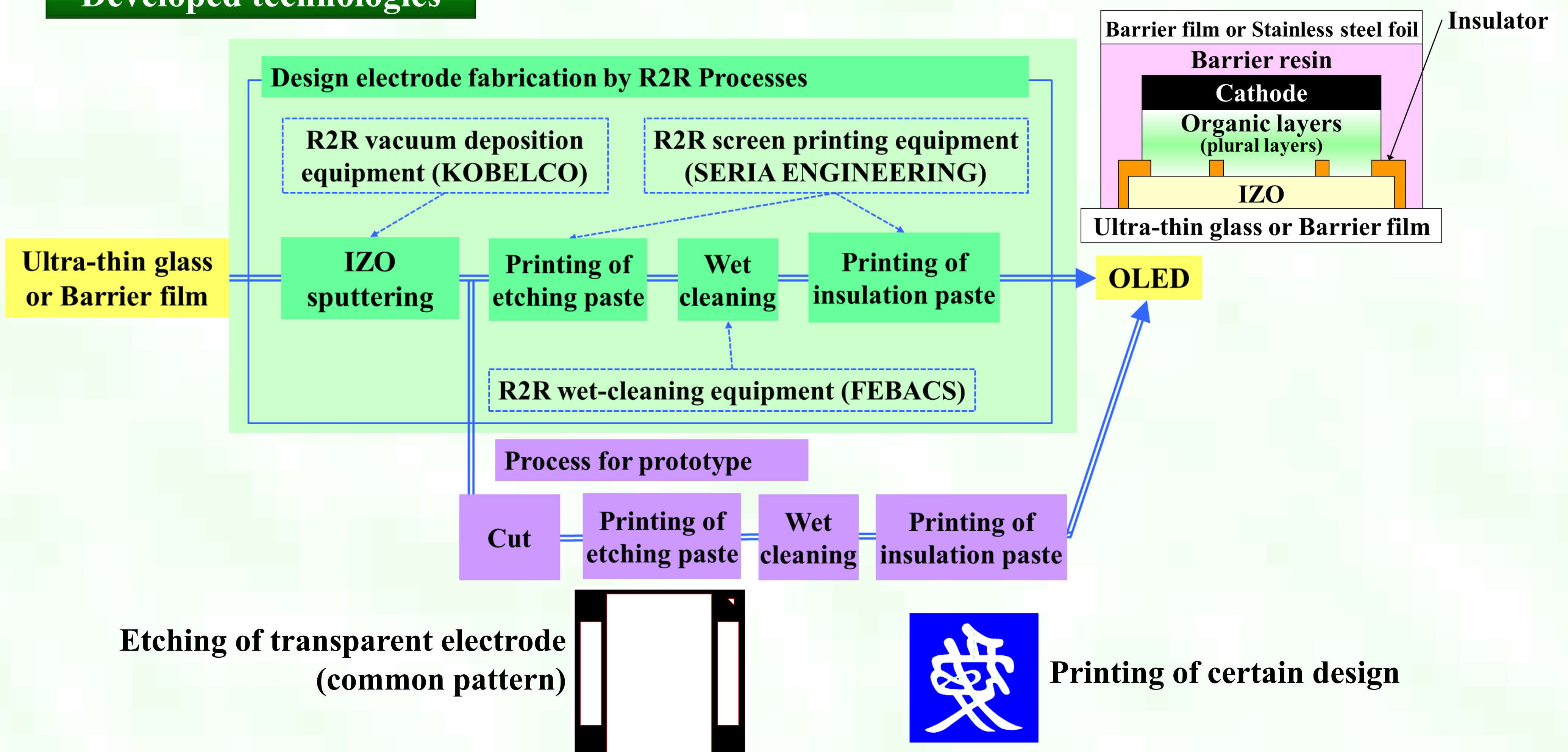
Application of organic electronics technologies to interactive advertisement

We develop flexible OLED devices for packages, etc., aiming at the application of organic electronics products to **advertisement**.

Technological features

- Flexible OLED packages for various applications
- Applied to package, advertisement, souvenir, name plate, bookmark, etc.

Developed technologies



Bookmark



Medicine case



Pencil case



Nameplate



Souvenir



Amulet

Collaboration

**KOMORI Corporation, TAKEDA PRINTING CO., LTD.,
Taica Corporation**

Related program

- Yamagata University Flexible Electronics Japan-Germany International Collaborative Practical Utilization Consortium (YU-FIC) [Oct. 2017~Mar. 2023].
- MEXT: Construction Program of Open Innovation Organization [FY2018~FY2022].

Developed
technology

YU-FLEC

Non-ITO Transparent Electrode with Implanted Metal-mesh Structure

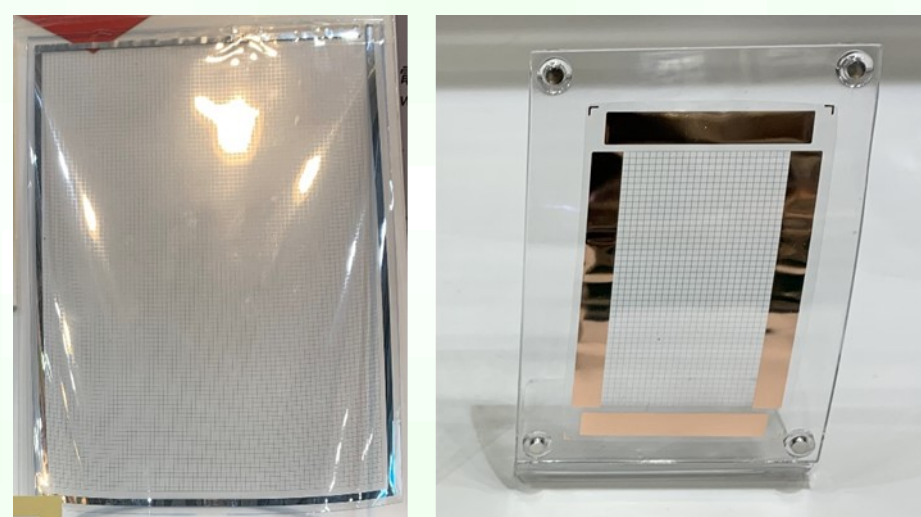
ITO (Indium Tin Oxide), which is the most common transparent electrode in LCDs and OLEDs, has issues in cost, productivity, etc.

We develop OLED devices using a **non-ITO transparent electrode** with novel **implanted metal-mesh** structure fabricated by **Toyo Aluminium**.

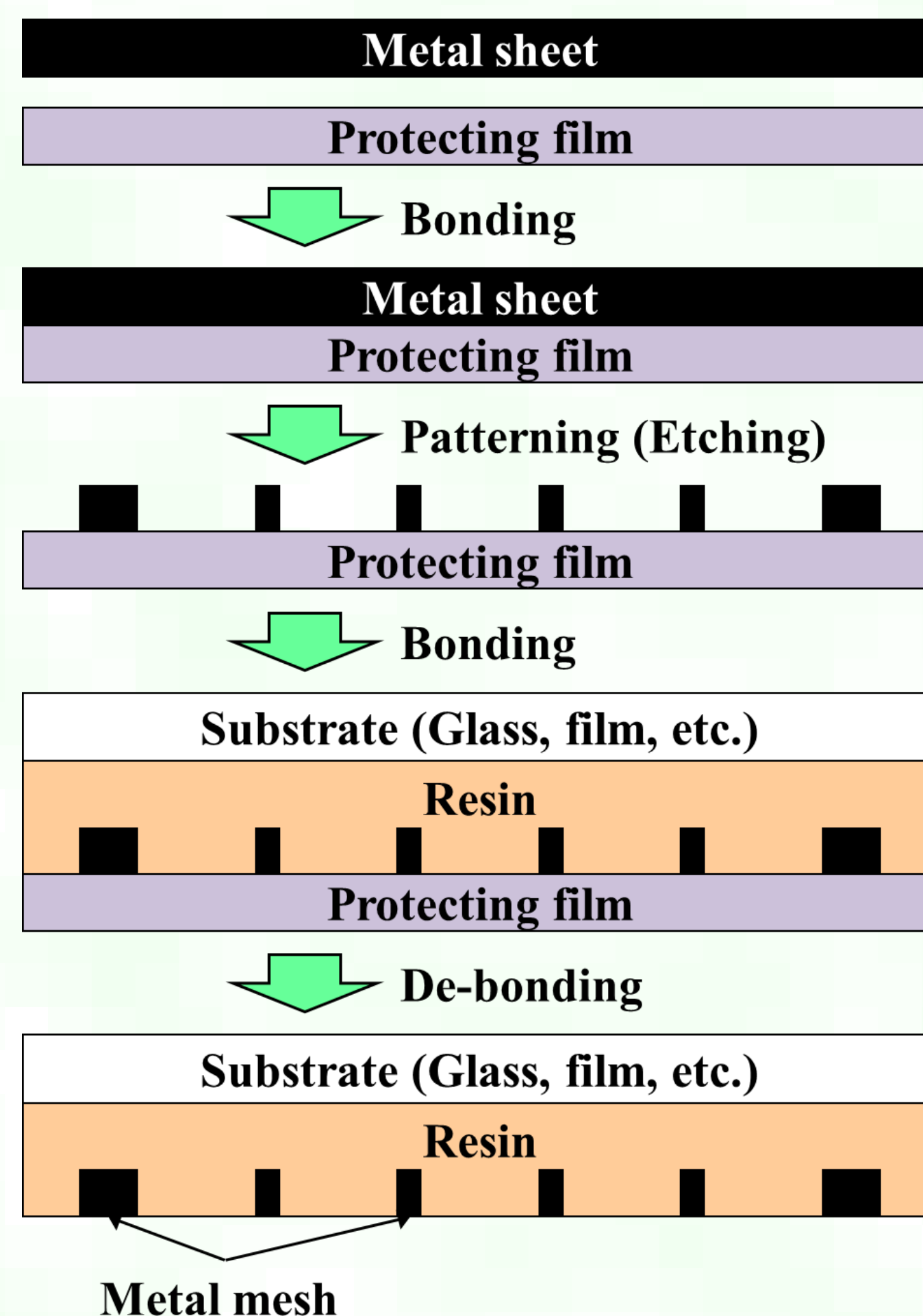
Technological features

■ Non-ITO transparent electrode with implanted metal-mesh structure fabricated by Toyo Aluminium K.K.

- High conductivity led by **Al-mesh** or **Cu-mesh**
- Smooth surface due to the implanted metal-mesh electrode into resin
- Applicable to OLED, OPV, etc.
- Applicable to flexible devices



	Sheet resistance
ITO (on glass)	~10Ω/□
ITO (on film)	~40Ω/□
Al mesh (thickness: 15μm)	0.036Ω/□
Cu mesh (thickness: 15μm)	0.023Ω/□

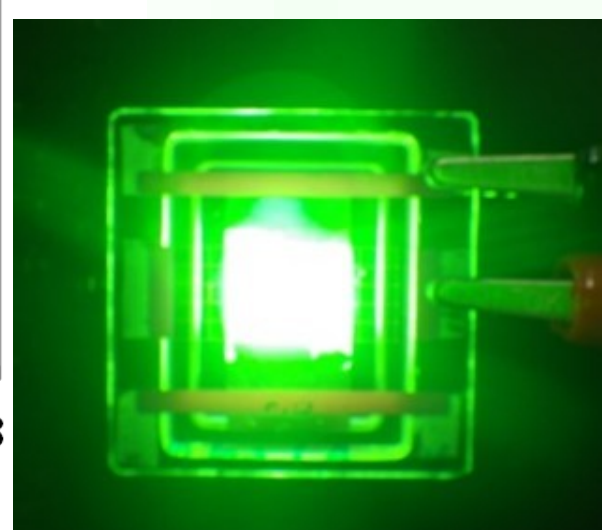
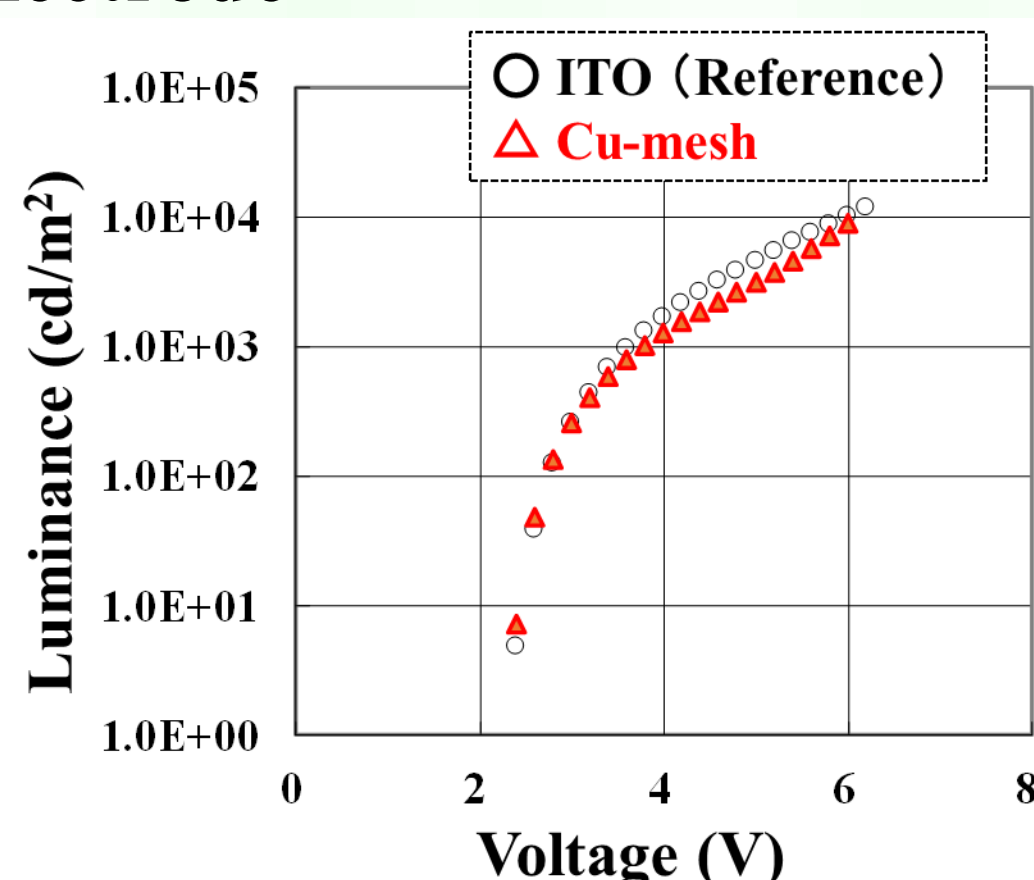


Fabrication process of metal-mesh substrate

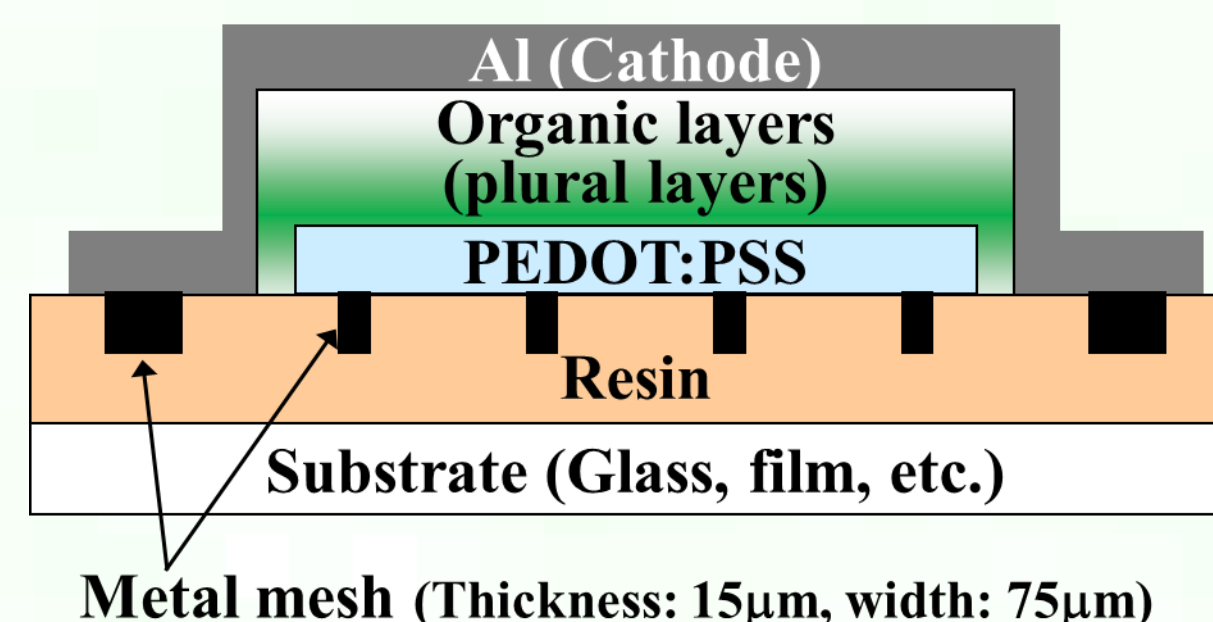
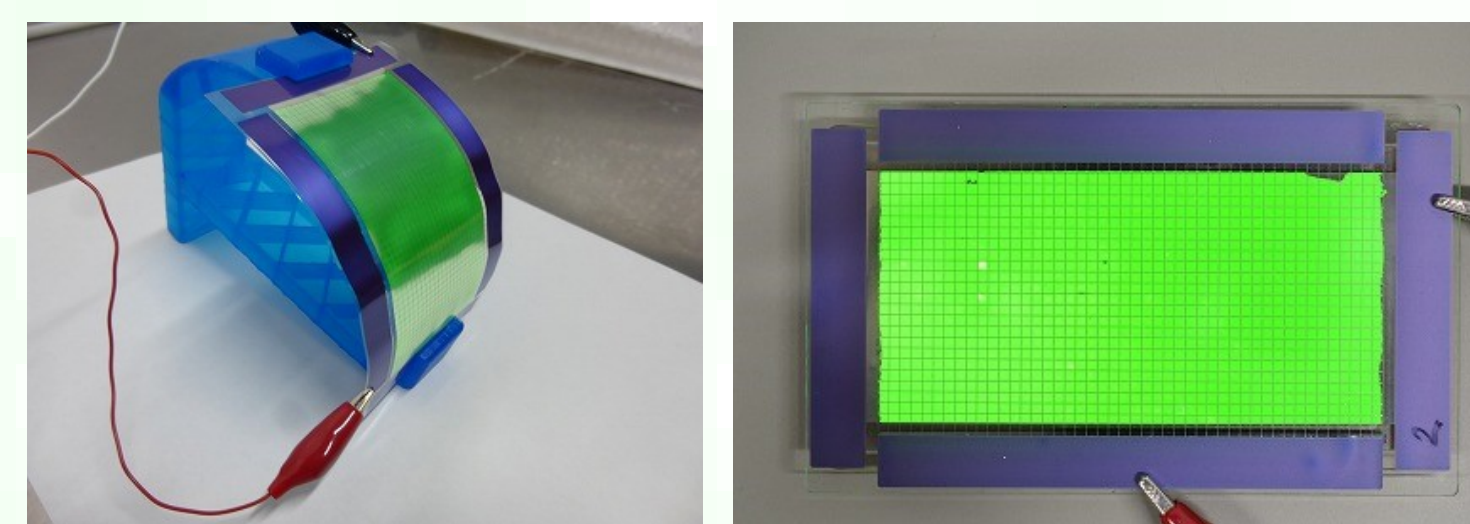
Developed technologies

■ OLED devices using non-ITO transparent electrode with implanted metal-mesh electrode

- Comparative performance with normal ITO electrode



■ OLED device samples with implanted metal-mesh electrode



Metal mesh (Thickness: 15μm, width: 75μm)

Collaboration

Toyo Aluminium K.K., Prof. Takeshi Sano (INOEL, Yamagata University)

Related program

- Yamagata University Flexible Electronics Consortium for Academia-Industry Cooperation (YU-FLEC) [Jan. 2018~Mar. 2023].
- JST: OPERA Program Grant Number JPMOP1844 [FY2018~FY2022].
- MEXT: Construction Program of Open Innovation Organization [FY2018~FY2022].

Publication

- M. Koden, N. Kawamura, T. Yuki, H. Nakada, R. Waguri, K. Den, R. Nakao, H. Minamiyama, The 31th Meeting of Japan OLED Forum, S7-2 (2020).
- R. Waguri, K. Den, R. Nakao, H. Minamiyama, MES2020, 1B1-2 (2020).
- Yamagata University; "JFlex2020" (Jan. 2020 / Tokyo), "TCTJAPAN" (Jan. 2020 / Tokyo), "JFlex2019" (Jan. 2019 / Tokyo).
- Toyo Aluminium; Japan Chemical Daily (20 Jan. 2020), Japan Metal Daily (18 Mar. 2020).
- R. Waguri, Toyal Technical Report (2019).
- Toyo Aluminium; "INTERNEPCON Japan" (Jan. 2020, Jan. 2019 / Tokyo).

Developed
technology

YU-FLEC

TFE (Thin Film Encapsulation) Technologies for OLEDs

We develop **TFE (Thin Film Encapsulation)** technologies for OLED devices, using organic resins developed by TOYO CHEM CO., LTD. (TOYO INK SC HOLDINGS group).

Technological features

Advantages of “Non-solvent UV-IJ resin ink” developed by TOYO CHEM

- To support SiNx barrier layer
- UV cure type (**non-solvent**)
- Applicable to **ink-jet**

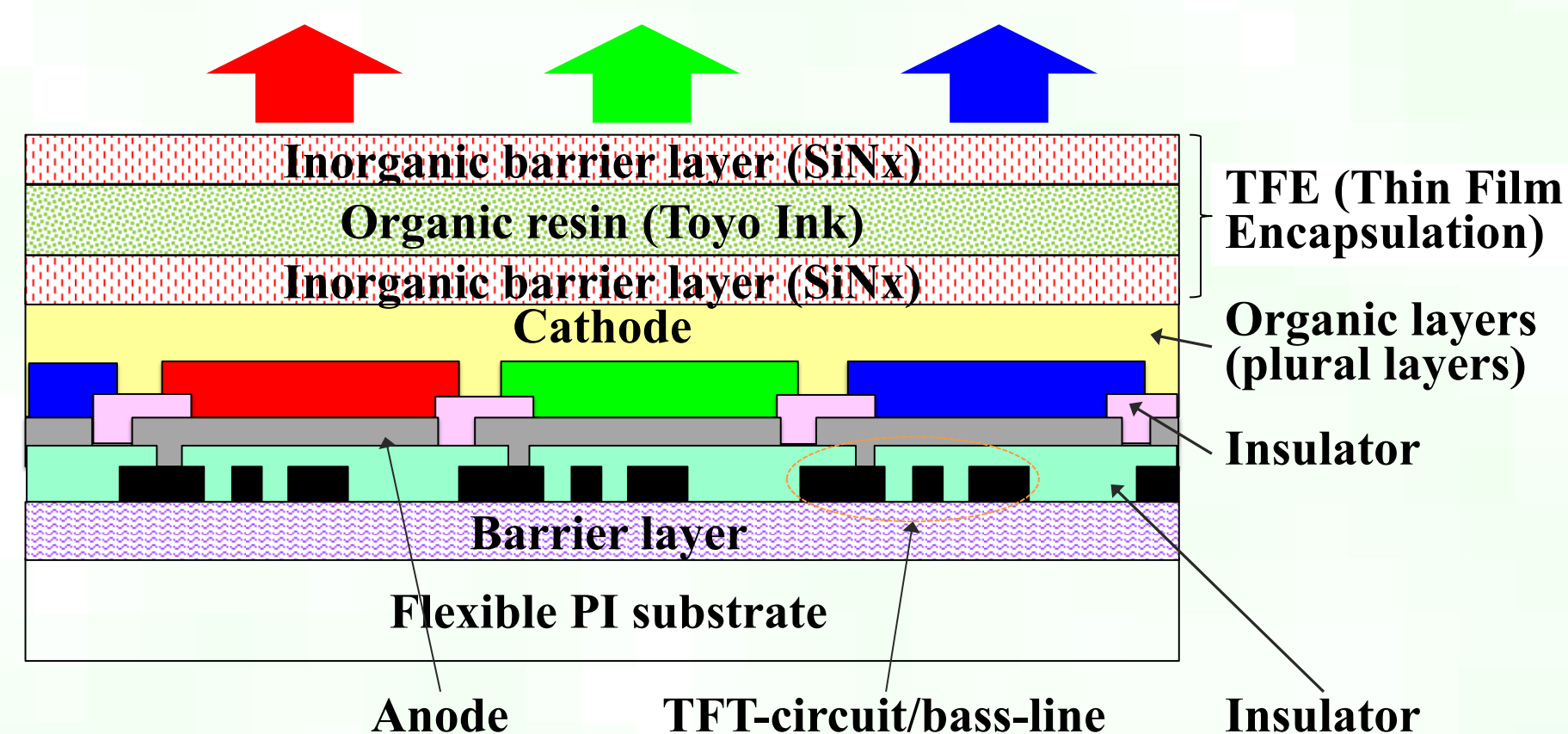


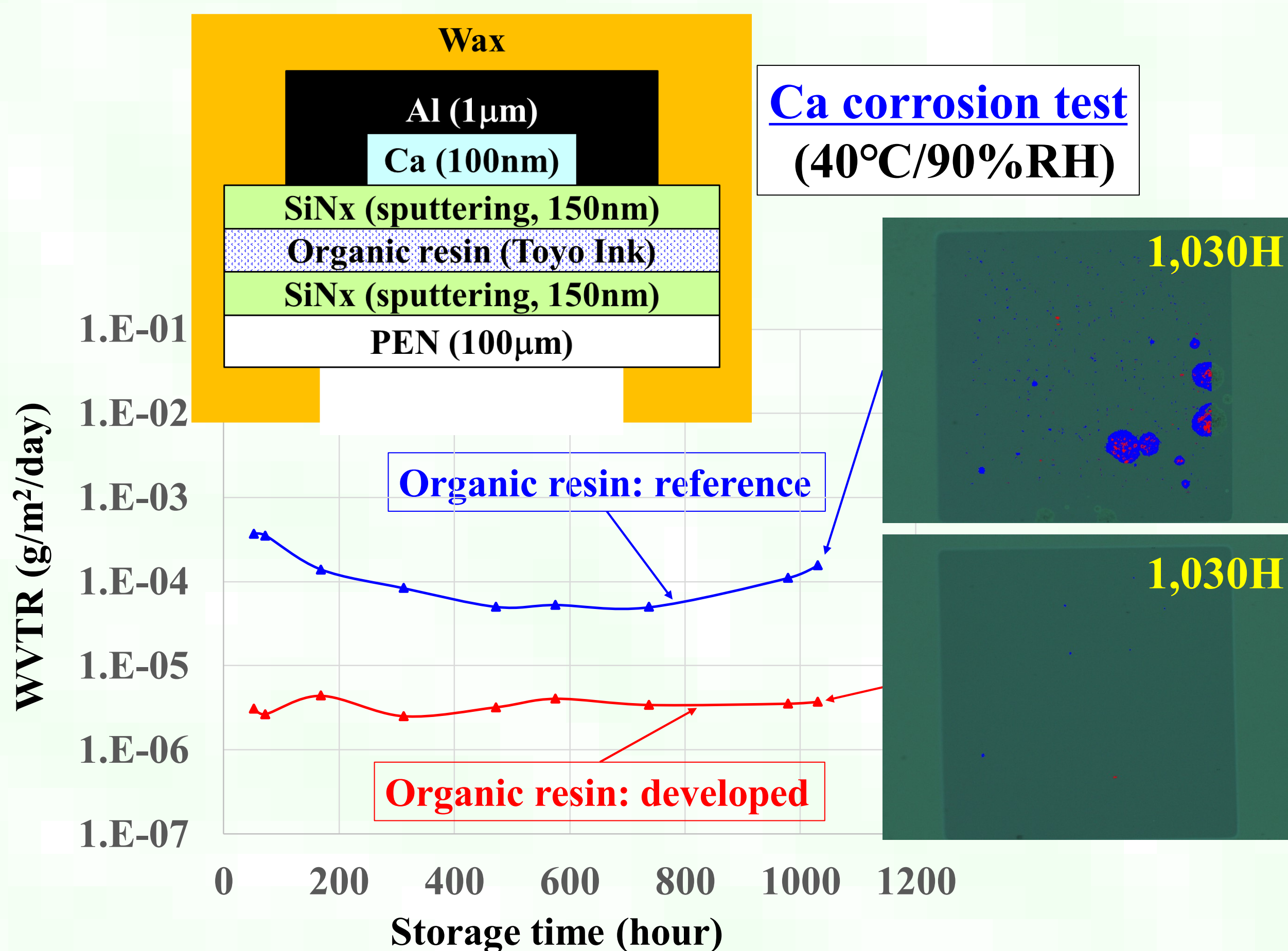
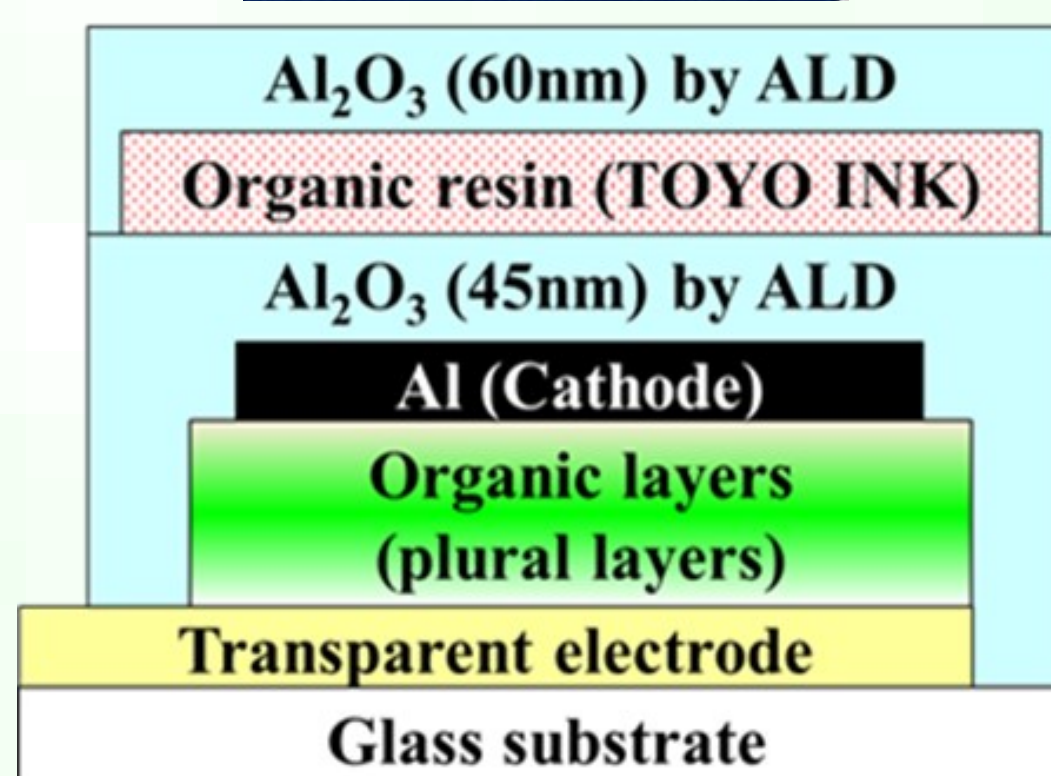
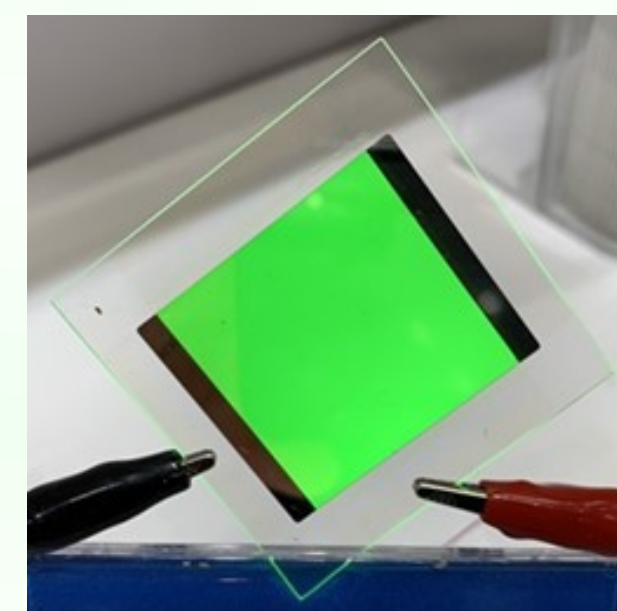
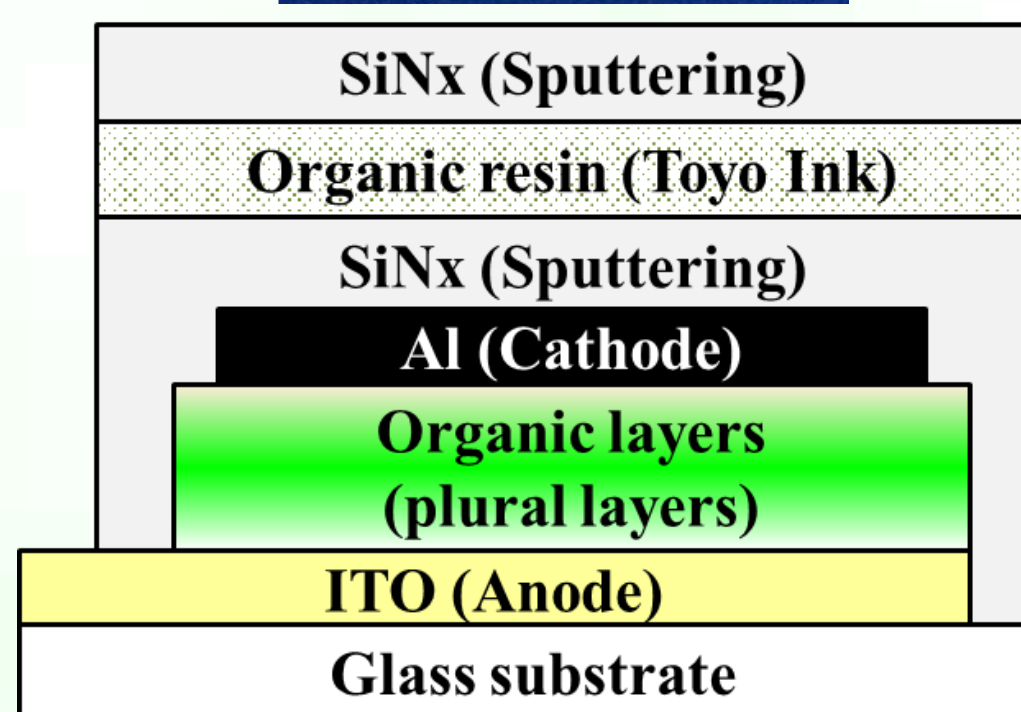
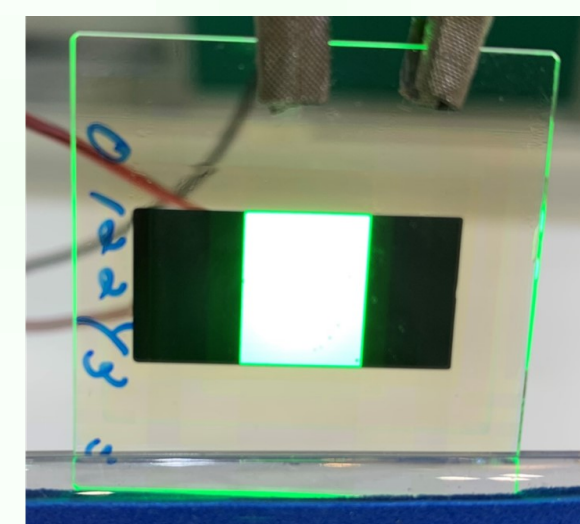
Image of OLED with TFE

Developed technologies

TFE structure with high gas barrier property

- TFE with “Non-solvent UV-IJ resin ink” developed by TOYO CHEM
- No actual damage after storage test of 1,000 hours under 40°C/90%RH
- WVTR (Water Vapor Transmission Rate): order of **10⁻⁶g/m²/day** (40°C/90%RH)

OLED device with the developed TFE structure



Collaboration

TOYO CHEM CO., LTD.

Related program

- Yamagata University Flexible Electronics Consortium for Academia-Industry Cooperation (YU-FLEC) [Jan. 2018~Mar. 2023].
- MEXT: Construction Program of Open Innovation Organization [FY2018~FY2022].

Publication / Commercialization

- Yamagata University; “JFlex2020” (Jan. 2020 / Tokyo); “JFlex2019” (Jan. 2019 / Tokyo).
- The developed results have been applied to LIORESIT™ NSP 800 series (UV Curing/ IJ printing) of TOYO CHEM CO., LTD.

Developed
technology

YU-FLEC

OnDemand Patterning of OLEDs by Ink-jet Printed Insulators

OnDemand patterning of OLEDs was developed by on-demand patterns of insulators fabricated by **ink-jet** printing. The developed technology can be applied to **small lot OLED productions** with **various designs**, inducing novel applications.

Technological features

■ Ink-jet printing of insulators

- simple and inexpensive processes
- **On-Demand design**
(small lot with various designs)
- Eco-friendly (small volume of waste liquid)
- Suppression of contamination
(Non-contact between substrates and masks)

■ LIORESIT™ NSP 800 of TOYO CHEM CO., LTD.

- UV curing transparent insulation material
- Printable with IJ printer
- Curable with 365~395nm UV light
- No solvent included

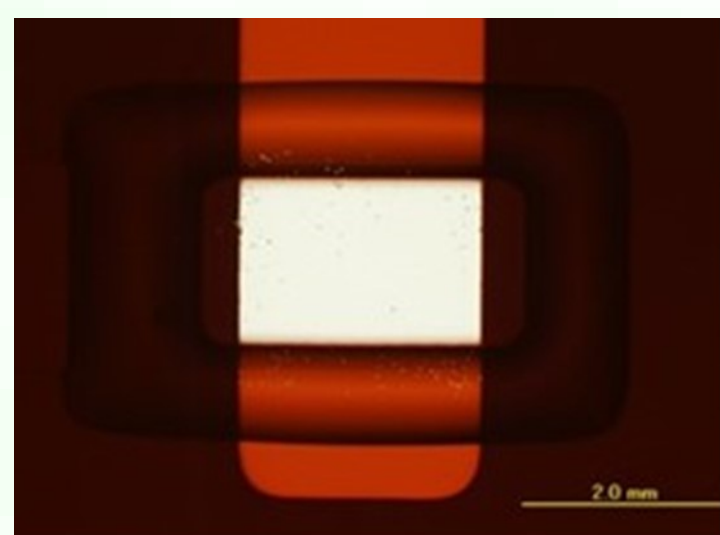
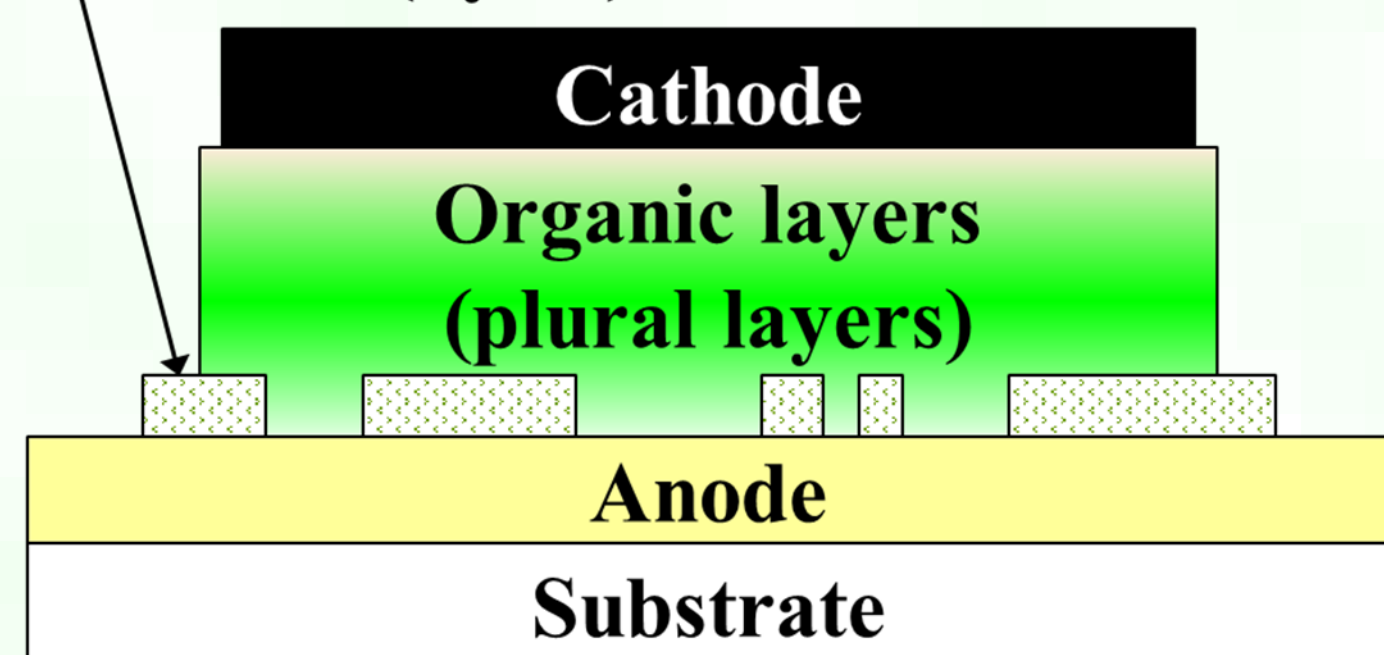
[*] TOYO CHEM CO., LTD. is a wholly owned subsidiary company of Toyo Ink SC Holdings Co., Ltd.

Developed technologies

■ OLED devices with On-Demand patterns of insulators printed by ink-jet

- Uniform emission including with edges of insulators
- Comparable characteristics and lifetime with OLEDs without the insulators
- Resolution: **L/S=61/62μm** (almost comparable with **400dpi**)

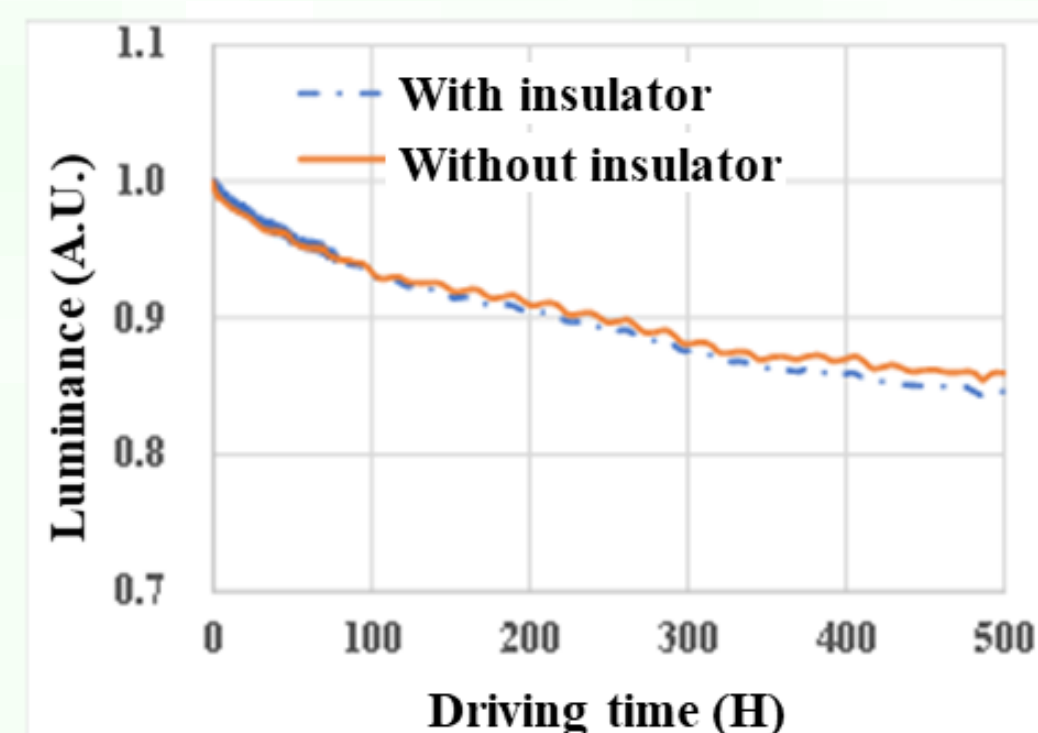
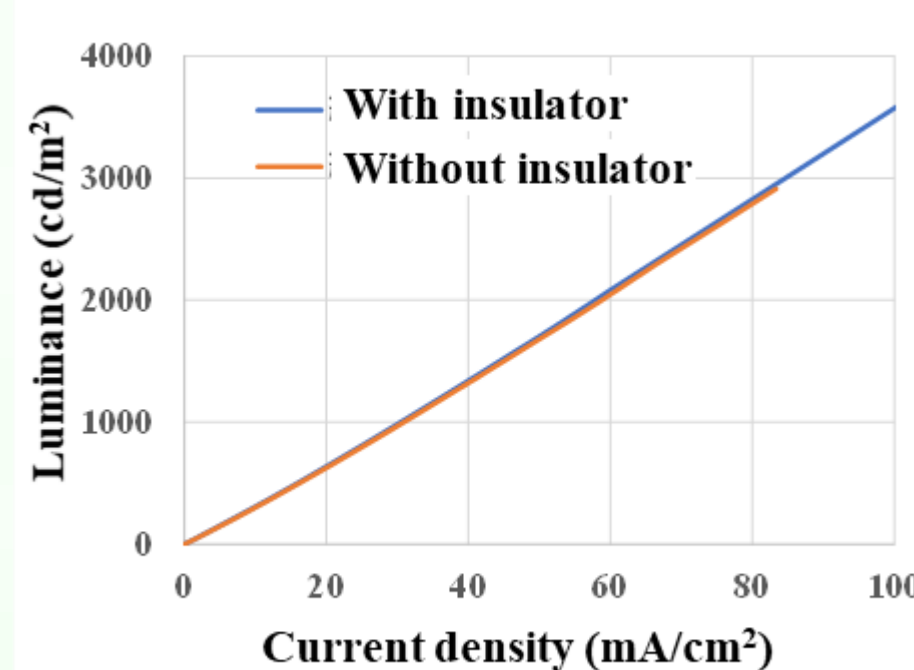
Insulator (by IJ)



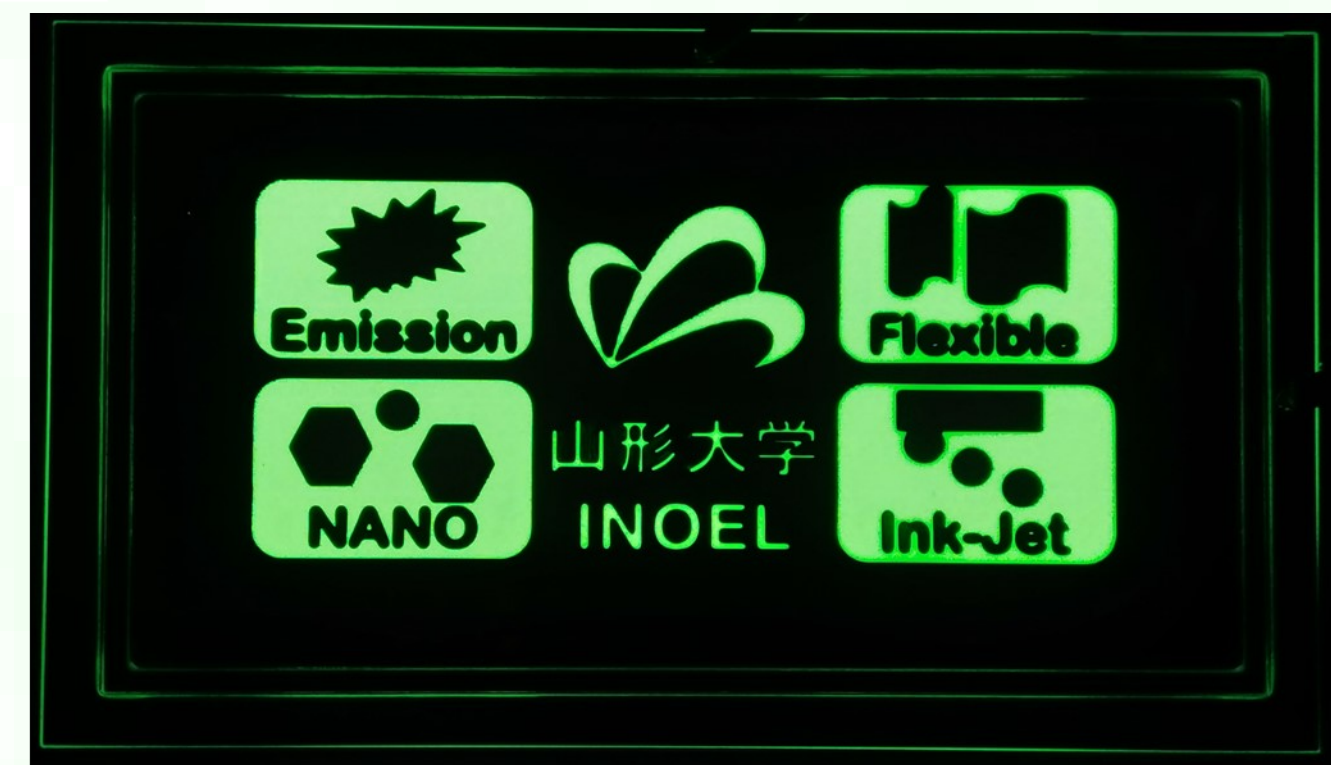
With insulator



Without insulator



Substrate size : 50mm × 50mm



Substrate size : 60mm × 100mm

Collaboration

TOYO CHEM CO., LTD.

Related program

- Yamagata University Flexible Electronics Consortium for Academia-Industry Cooperation (YU-FLEC) [Jan. 2018~Mar. 2023].
- MEXT: Construction Program of Open Innovation Organization [FY2018~FY2022].

Publication

- M. Sugimoto, Y. Fukuchi, H. Tsuruta, M. Koden, H. Nakada, T. Yuki, A-COE 2021, PA-17 (2021).
“OLEDs with on-demand patterns drawn by ink-jet printing”

Developed
technology

Barrier layer by ALD (Atomic Layer Deposition)

ALD (Atomic Layer Deposition) can fabricate barrier layers with excellent surface coverage and can be applied flexible electronics devices.

We provide **high gas barrier layers** using ALD method for applying various collaborations on flexible organic electronics.

Technological features

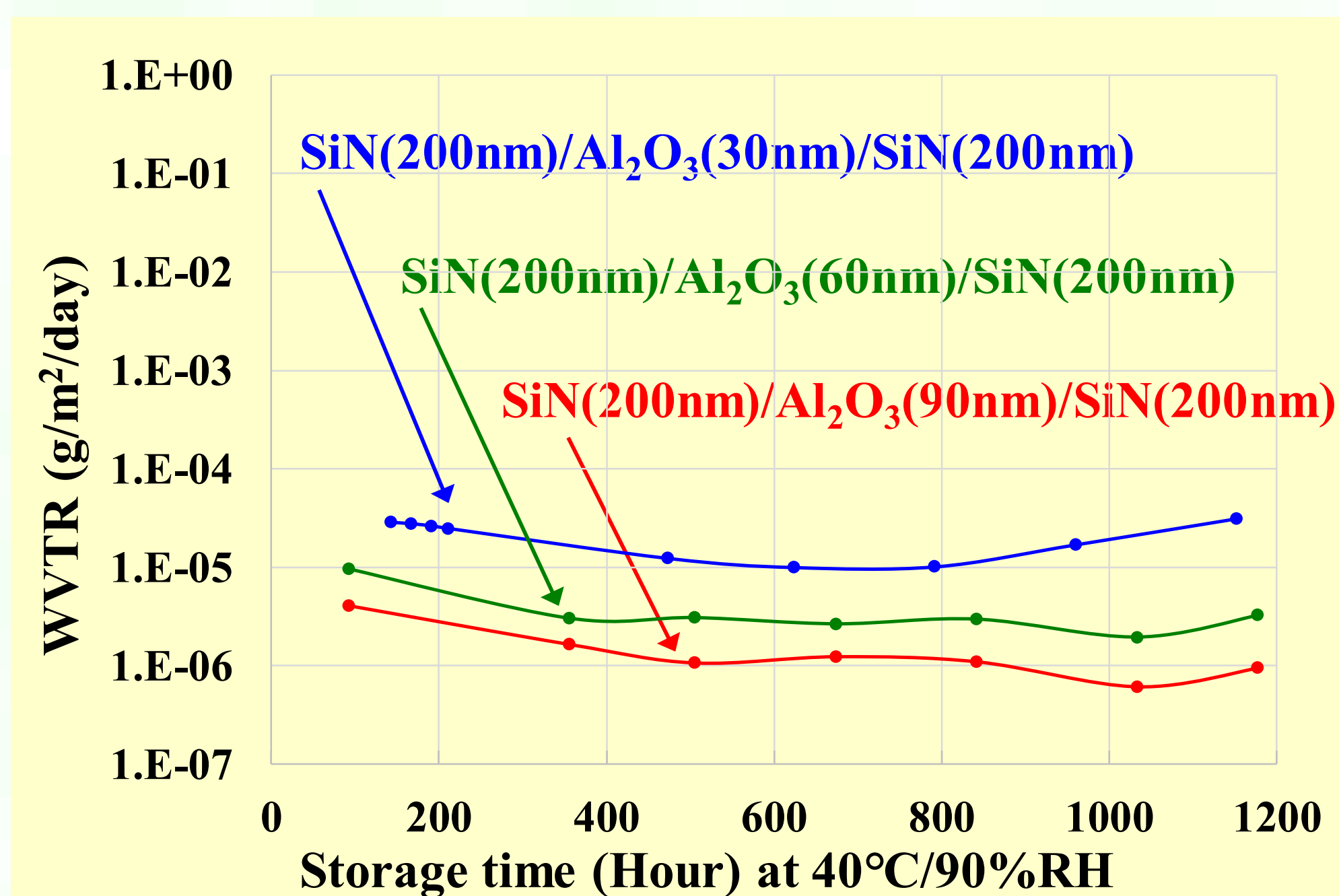
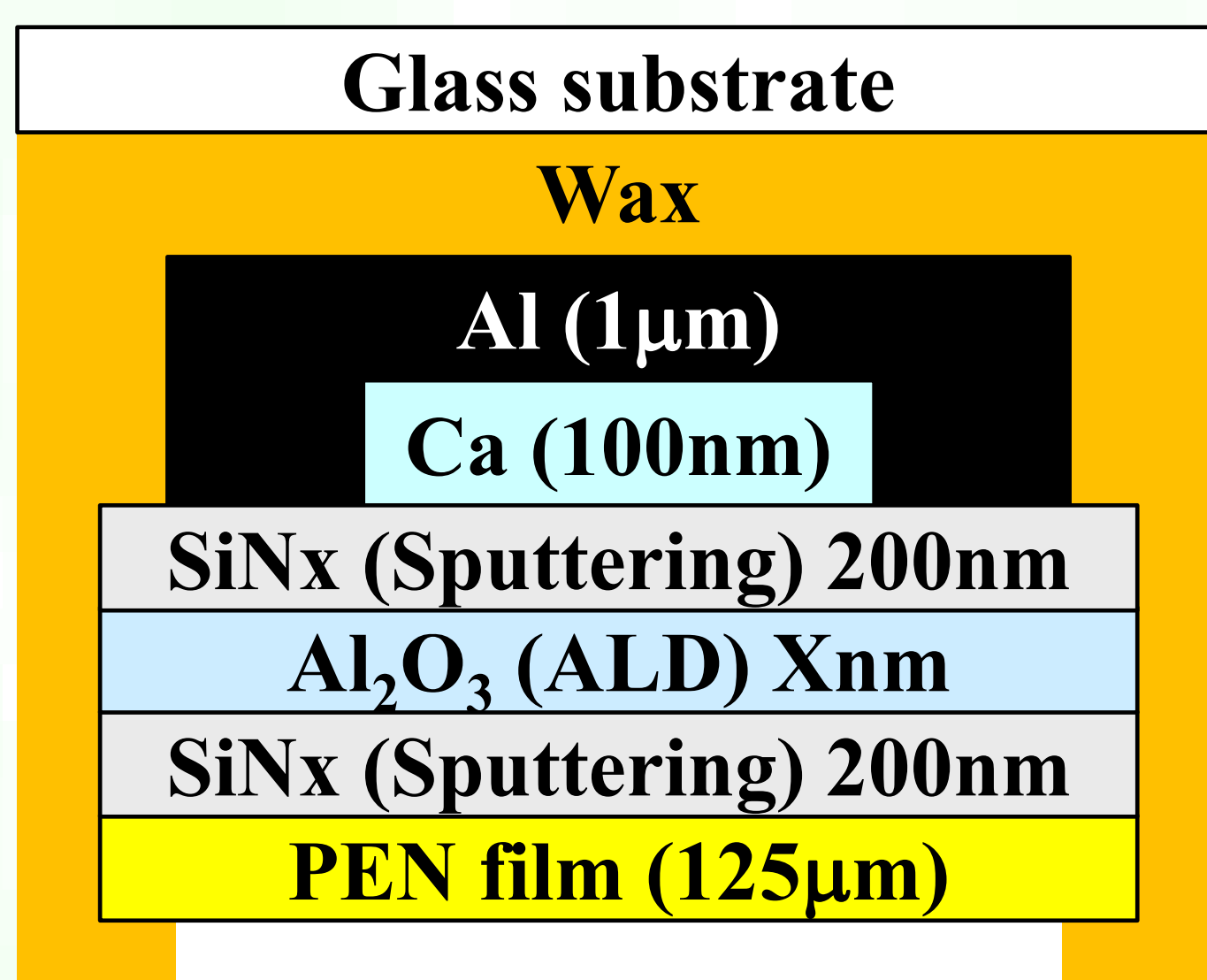
- Excellent surface coverage by ALD
- High gas barrier property by multi-layer structure with SiNx.
WVTR: order of 10^{-6} g/m²/day
(WVTR: Water Vapor Transmission Rate)
- Equipment: ALD of SUGA CO., Ltd.
(Maximum substrate size: 10cm × 10cm)



ALD equipment (SUGA CO., Ltd.)

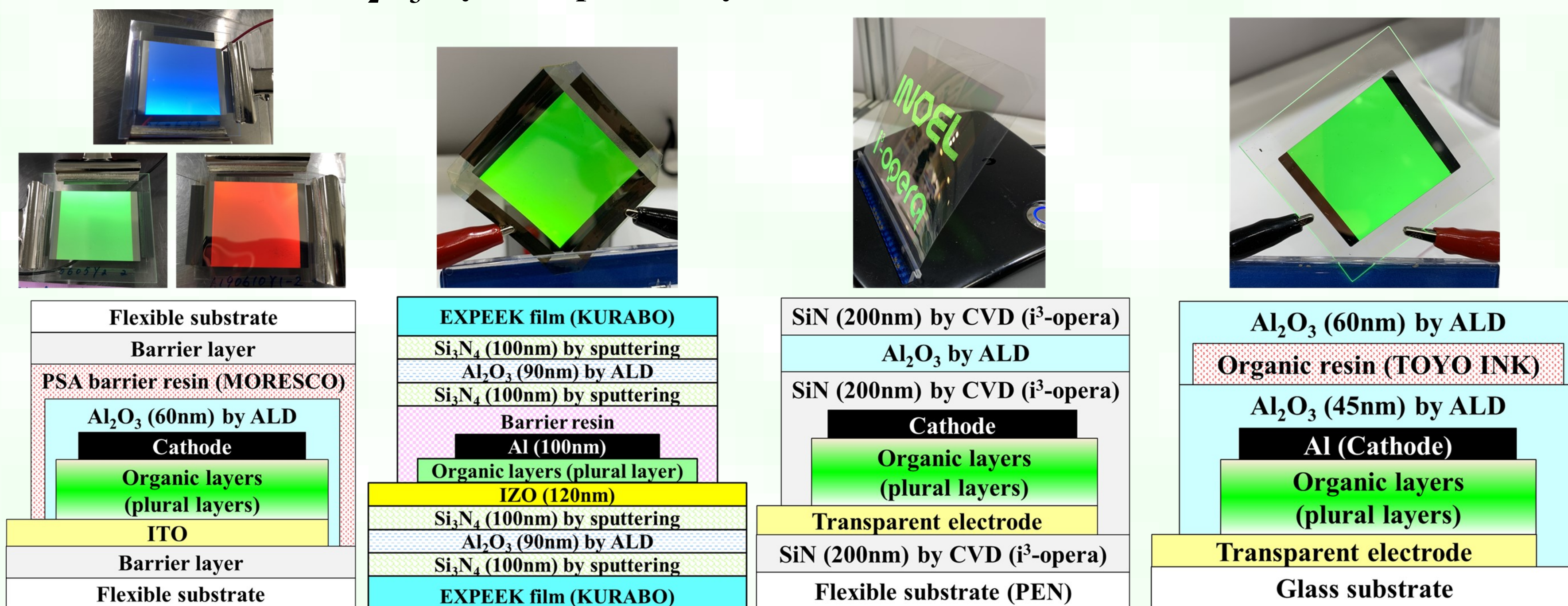
Developed technologies

- Multi-layered barrier with Al₂O₃(ALD) and SiNx (Sputtering) layers
WVTR: order of 10^{-6} g/m²/day



WVTR (Water Vapor Transmission Rate) measurement by Ca corrosion method

- OLED devices with Al₂O₃ layers deposited by ALD



Related program

- Yamagata University Flexible Electronics Consortium for Academia-Industry Cooperation (YU-FLEC) [Jan. 2018~Mar. 2023].
- MEXT: Construction Program of Open Innovation Organization [FY2018~FY2022].

Developed
technology

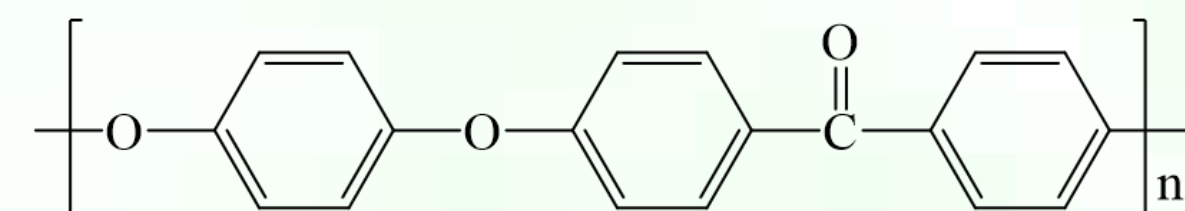
YU-FLEC

High Temperature Tolerant Barrier Films for Flexible OLEDs

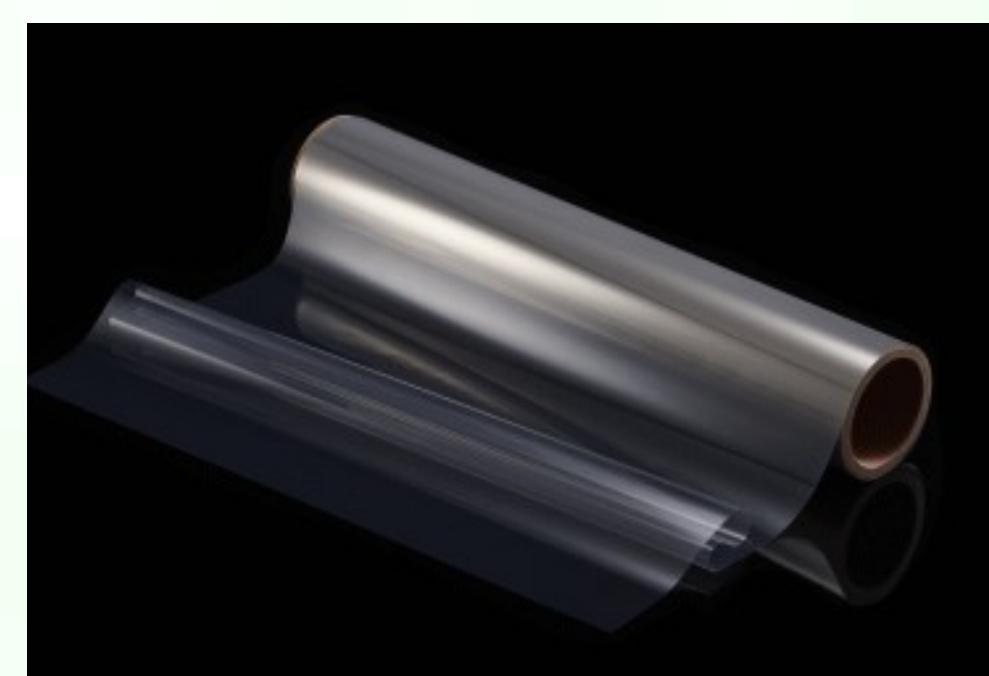
OLED fabrication often requires high temperature processes (higher than 200°C). From this point of view, we develop **high temperature tolerant barrier films** for flexible OLEDs, using **EXPEEK®** film developed by **KURABO**.

Technological features

- Advantages of **high temperature tolerant film EXPEEK** (KURABO INDUSTRIES LTD.)
 - Biaxially stretched PEEK (polyetheretherketone) film
 - Similar temperature tolerance to polyimide (Tg: 320°C)
 - Excellent solvent tolerance
 - Excellent transparency
 - Low thermal shrinkage
- Application of EXPEEK with gas barrier layer to flexible OLED devices



Fundamental moiety of PEEK



EXPEEK
(KURABO INDUSTRIES)

Developed technologies

- High gas barrier property:
WVTR with order of **$10^{-5} \sim 10^{-6} \text{g/m}^2/\text{day}$**

WVTR (Water Vapor Transmission Rate) measurement by Ca corrosion method

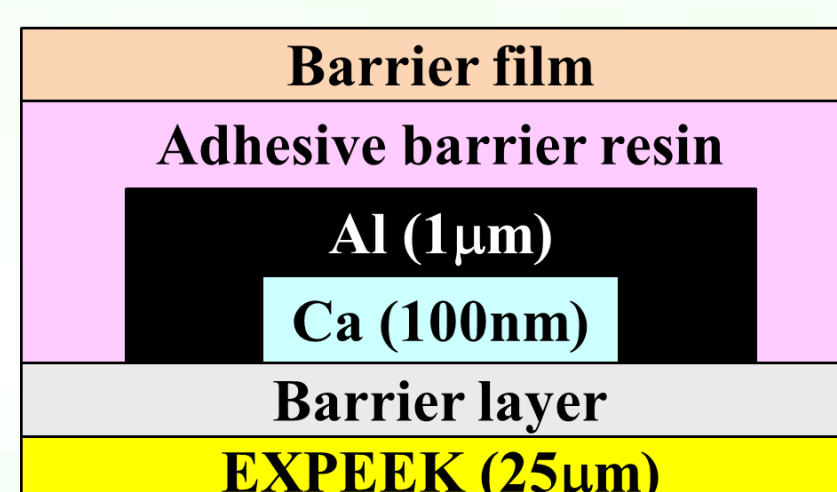
Structure of barrier film	Highest process Temperature	Typical WVTR
EXPEEK/SiNx(100nm)	<100°C	2×10^{-3}
EXPEEK/Al ₂ O ₃ (90nm)	100°C	2×10^{-2}
EXPEEK/Al ₂ O ₃ (10nm)	300°C	2×10^{-6}
EXPEEK/SiNx(100nm)/Al ₂ O ₃ (90nm)/SiNx(100nm)	100°C	2×10^{-5}
EXPEEK/Resin/SiNx(100nm)	100°C	4×10^{-4}
EXPEEK/SiNx(100nm)/Resin/SiNx(100nm)	100°C	3×10^{-6}

WVTR (Water Vapor Transmission Rate): Evaluated by Ca corrosion method under 40°C/90%RH

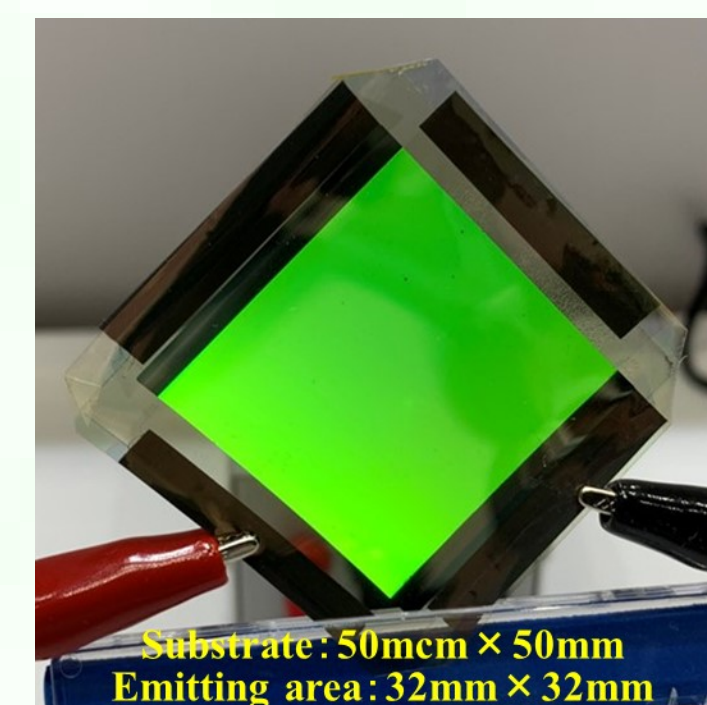
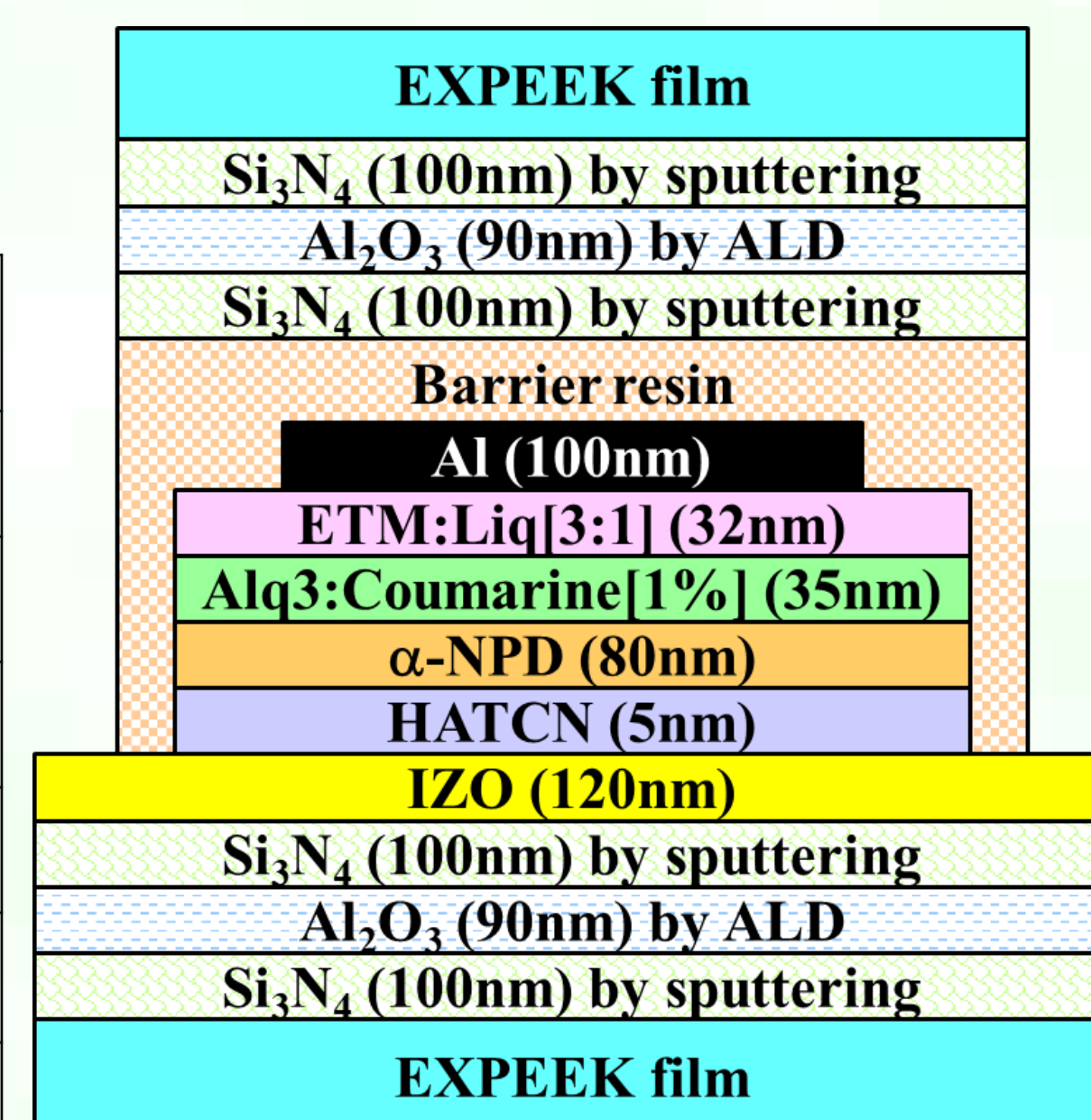
SiNx: Deposited by sputtering

Al₂O₃: Deposited by ALD (Atomic Layer Deposition)

Resin: NSP811 (Toyo Ink) coated by ink-jet (thickness: 10~15μm)



- Flexible OLED devices



“JFlex2020”
(Oct. 2020 / Tokyo)

Collaboration

KURABO INDUSTRIES LTD.

Related program

- Yamagata University Flexible Electronics Consortium for Academia-Industry Cooperation (YU-FLEC) [Jan. 2018~Mar. 2023].
- MEXT: Construction Program of Open Innovation Organization [FY2018~FY2022].

Publication

- T. Yuki, T. Nishikawa, M. Sugimoto, H. Nakada, M. Koden, ITE Trans. on MTA Vol. 9, No. 4, pp. 216-221 (2021).
“High Temperature Tolerant Barrier Films with Stacking Barrier Layers by Sputtering and ALD”
- T. Yuki, T. Nishikawa, M. Sugimoto, H. Nakada, M. Koden, IDW’20, FLX2-3 (2020).
“High Temperature Tolerant Barrier Film with Stacking Barrier Layers by Sputtering and ALD”
- Yamagata University; “JFlex2020” (Jan. 2020 / Tokyo); “JFlex2019” (Jan. 2019 / Tokyo).
- KURABO; “7th Fine Plastic Exhibition” (Dec. 2018 / Tokyo), “SEMICON Japan 2018” (Dec. 2018 / Tokyo).

EXPEEK® is a registered trademark of KURABO INDUSTRIES LTD.

Developed
technology

Printed Flexible Organic Photovoltaic (OPV) Fabricated by Roll-to-roll Processes

By the collaboration with **MORESCO Corporation**, we developed a **roll-to-roll (R2R) process** technology for **printing-type flexible Organic Photovoltaics (OPVs)**.

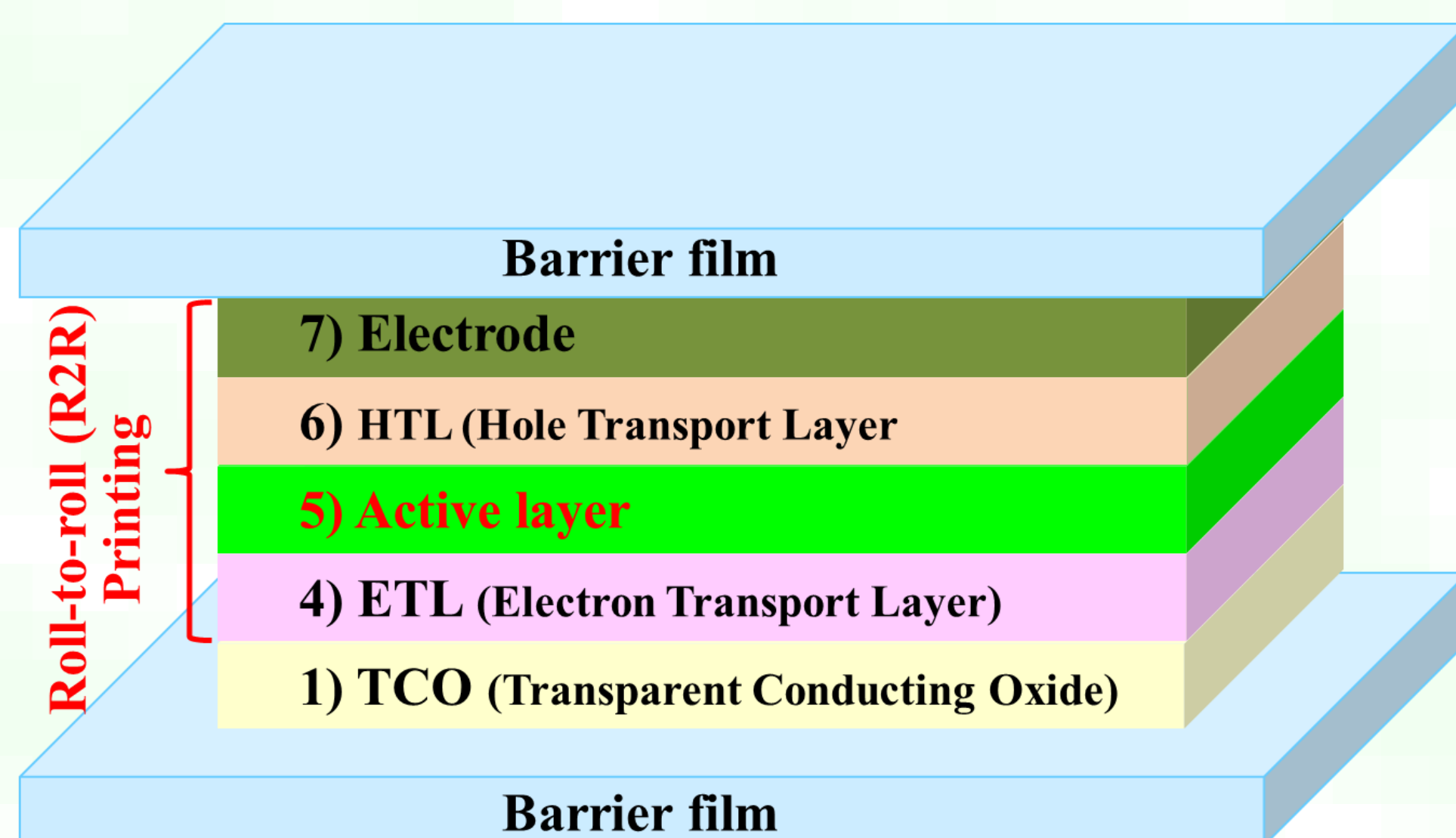
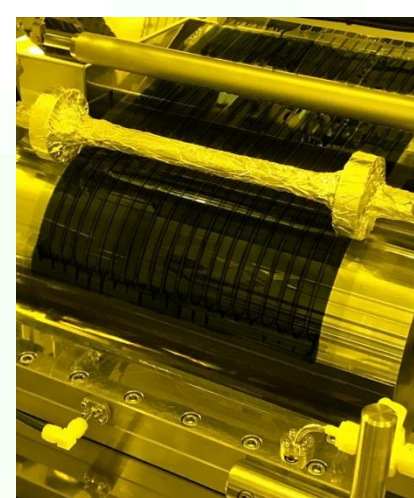
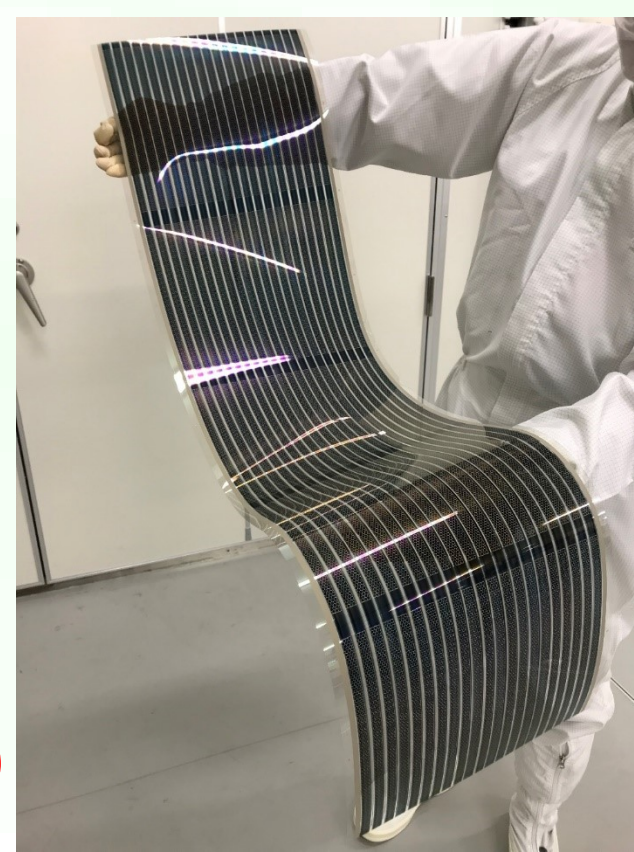
The develop devices are being evaluated by the verification test of the technology.

Features of flexible OPV

- can be applied to windows etc. due to the transparent feature.
- thin, light weight and un-breakable due to flexible and film
- applied to various places such as windows, walls, etc. by double-sided tape etc.

Technological features

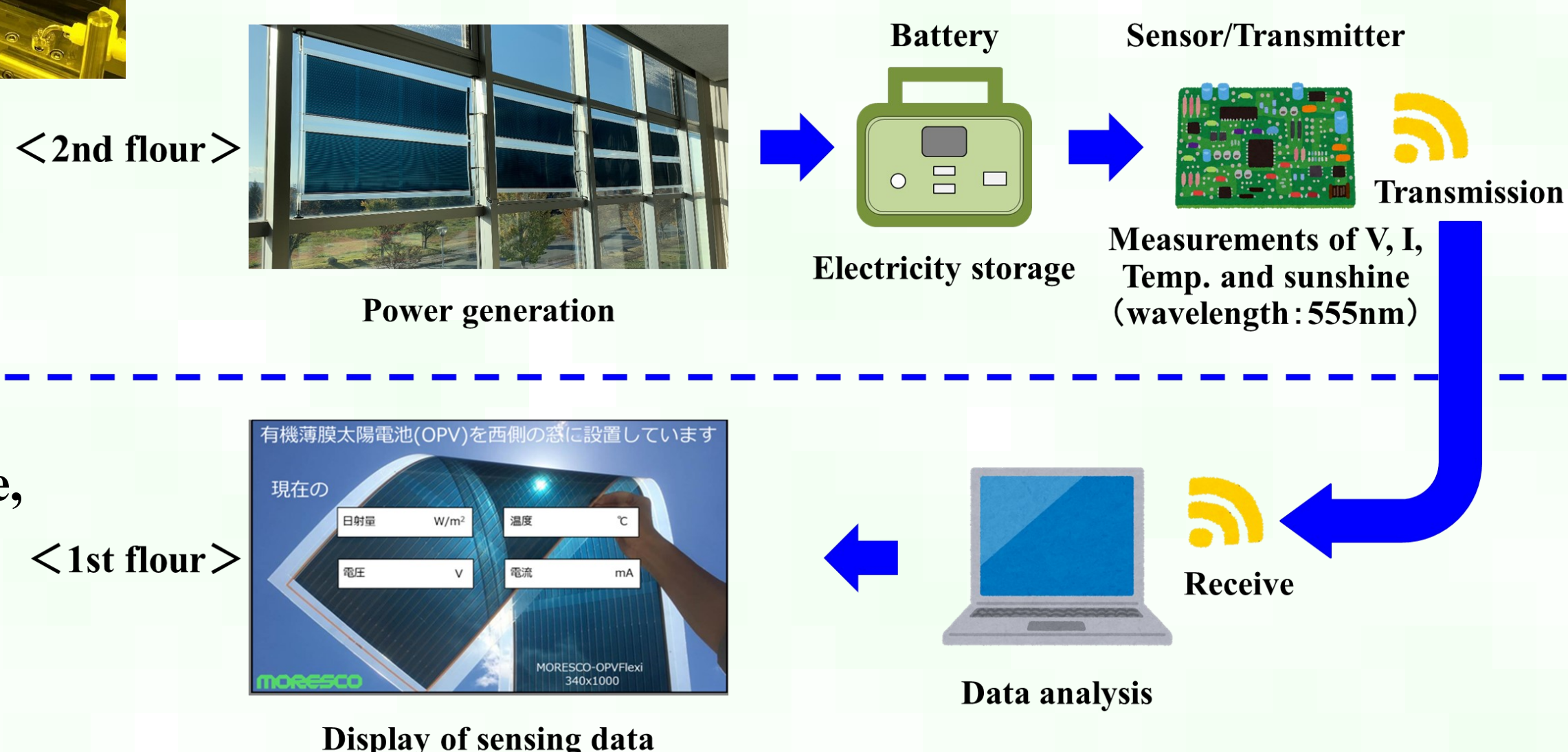
- Fabricated by **roll-to-roll (R2R) printing**
- Width:**30cm**、Length**>1m**
- Fabrication processes
 - 1) Transparent electrode (TCO) deposition
 - 2) TCO patterning
 - 3) Cleaning of substrate
 - 4) Printing of ETL (**R2R**)
 - 5) Printing of active layer (**R2R**)
 - 6) Printing of HTL (**R2R**)
 - 7) Printing of electrode (**R2R**)
 - 8) Current collection
 - 9) Encapsulation



Structure of flexible OPV

Developed technologies

- Roll-to-roll (R2R) printing technologies of flexible OPV
- Verification test:
 - 1) Laminate flexible OPVs on windows of 2nd floor
 - 2) Measure and transmit the data of voltage, current, temperature and sunshine by using the generated power.
 - 3) Display the measured data on a monitor of 1st floor.



Verification test at INOEL of Yamagata University

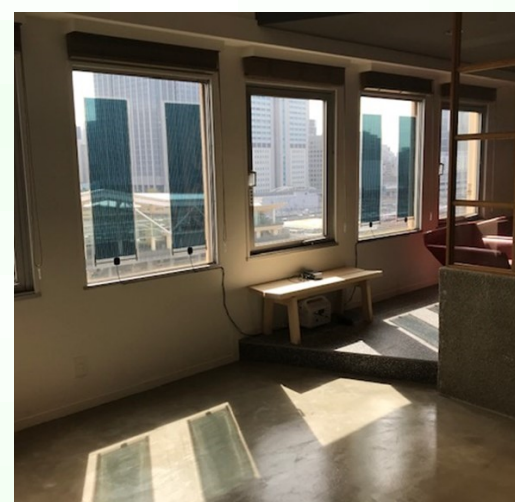
OPVs of MORESCO



Shopping street
(March 2018)



“OPTree” at KOBE ANIMAL
KINGDOM(Oct. 2020)



JR East TokyoYard Building
(Sep.2021)



“Tapestry” (designing by printing on OPV)

Collaboration

MORESCO Corporation

Related program

- JST: OPERA Program Grant Number JPMOP1614 [FY2016~FY2020].
- MEXT: Construction Program of Open Innovation Organization [FY2018~FY2022].

Publication

- Yamagata University; “JFlex2020” (Jan. 2020 / Tokyo).
- Yamagata University; “PVEXPO 2021” (March 2021 / Tokyo & Online).
- Yamagata University; Press Release (6 Nov. 2019).
- MORESCO; Press Release (6 Nov. 2019).

Developed
technology
YU-FLEC

PSA Encapsulating Technologies for OLEDs

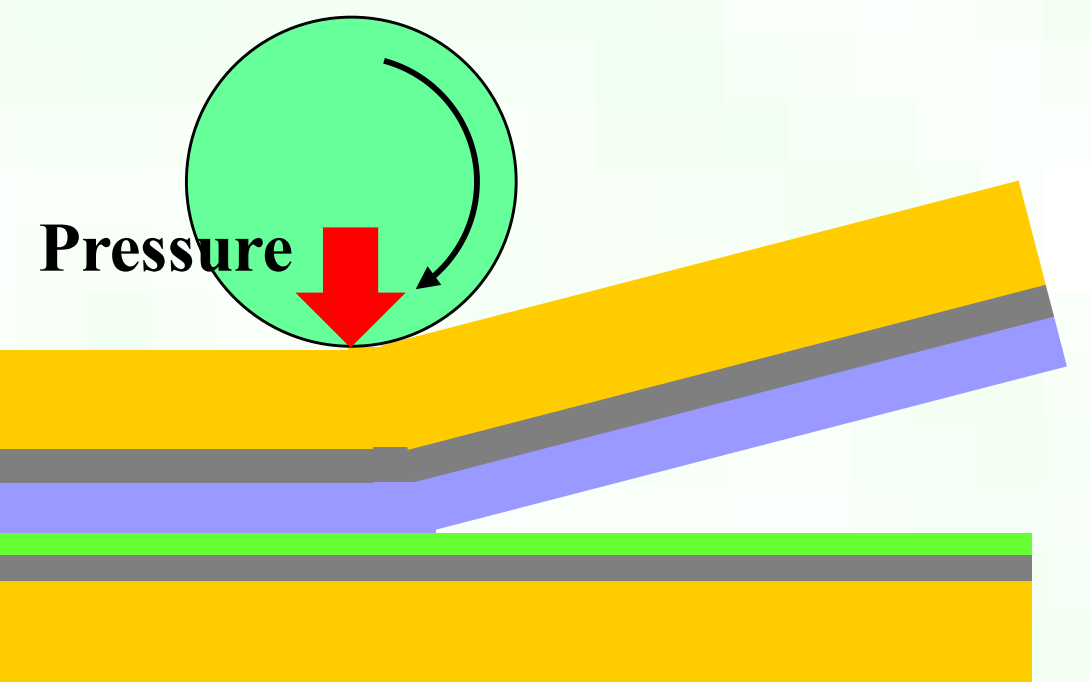
We collaborate with **MORESCO Corporation**, aiming at the development of flexible OLED devices with their **PSA (Pressure Sensitive Adhesive)** film.

Technological features

<Unique features of PSA film of MORESCO>

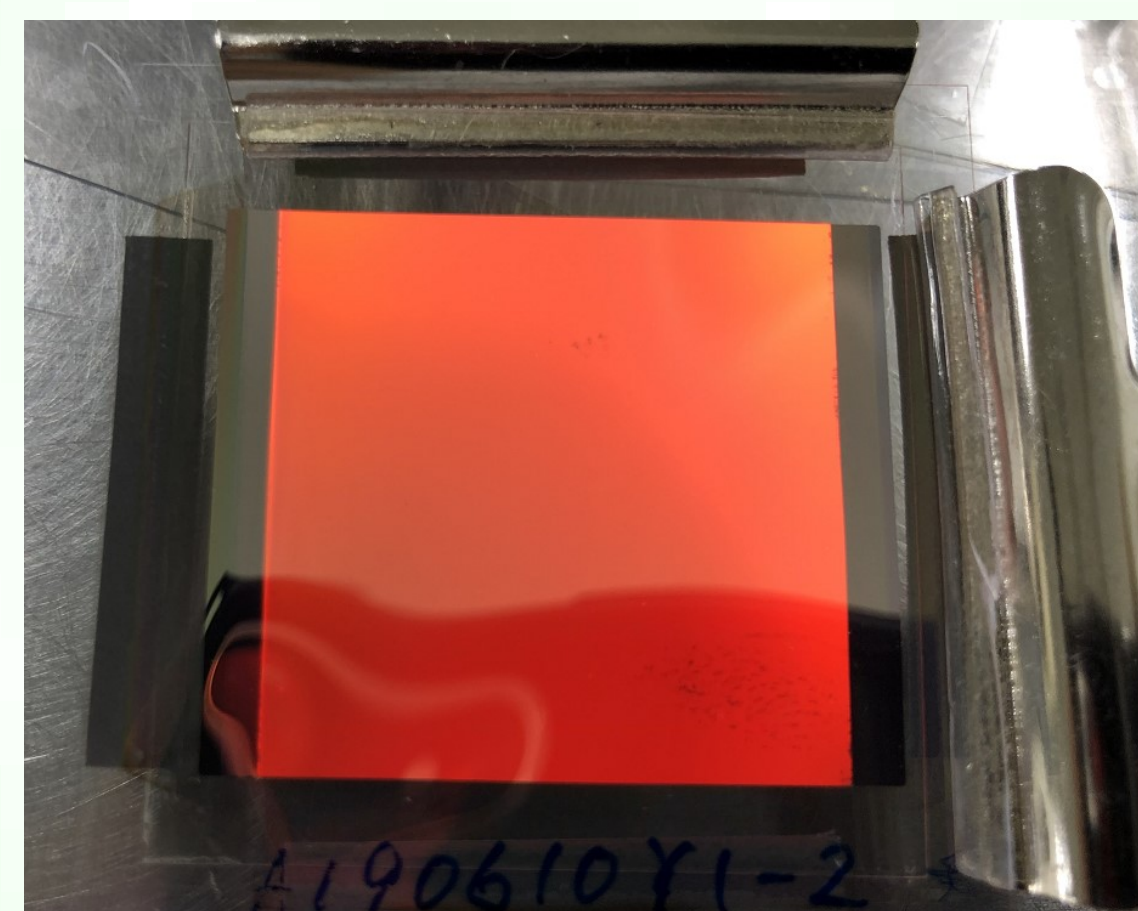
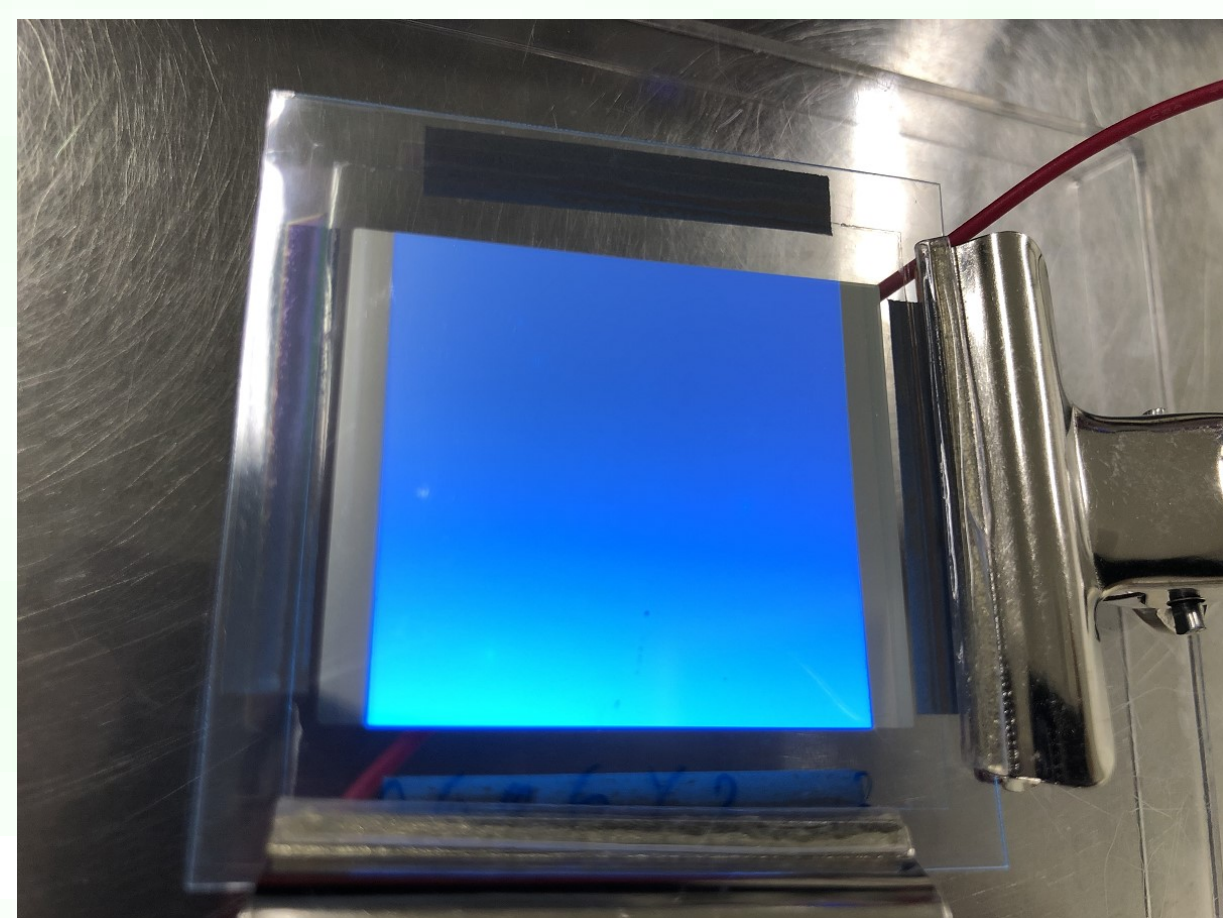
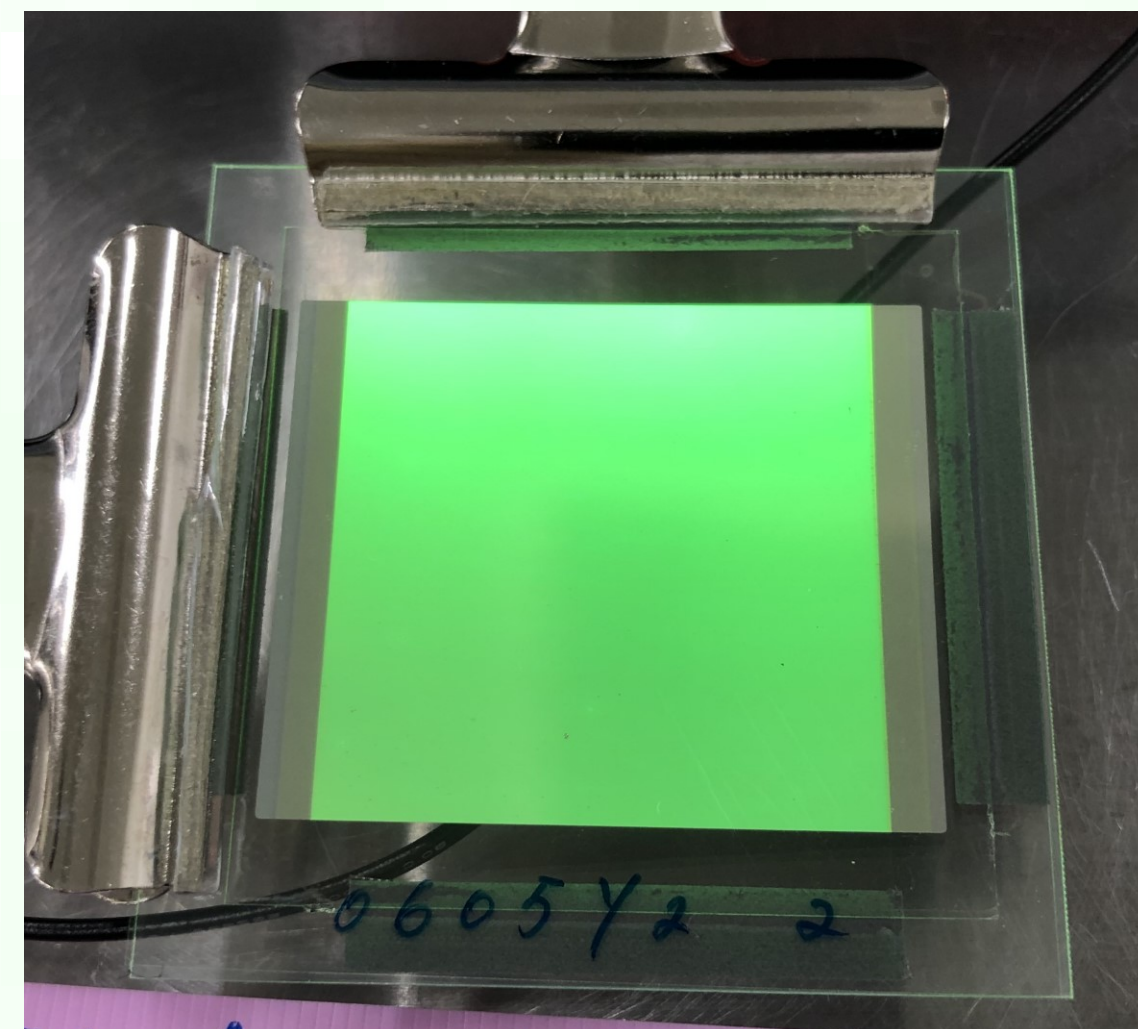
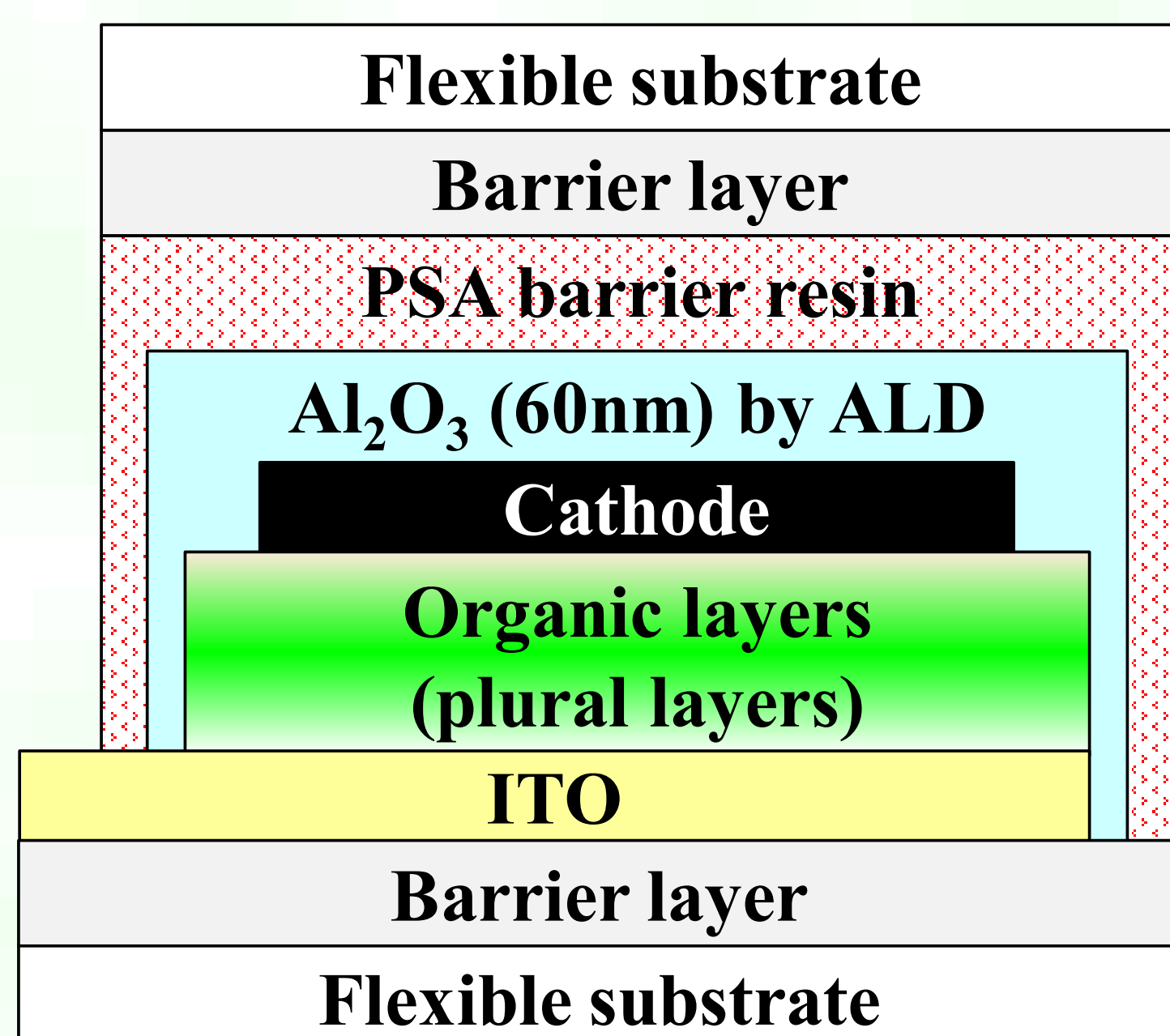
- Hot-melt type
- Simple encapsulation process
- Excellent flexibility
- Excellent adhesion (barrier layer)
- High gas barrier
- Solvent free

Flexible substrate
Barrier layer
PSA material
OLED layer
Barrier layer
Flexible substrate



Developed technologies

- Flexible OLED devices with PSA encapsulation



Collaboration

MORESCO Corporation

Related program

- Yamagata University Flexible Electronics Consortium for Academia-Industry Cooperation (YU-FLEC) [Jan. 2018~Mar. 2023].
- JST: OPERA Program Grant Number JPMOP1614 [FY2016~FY2020].
- MEXT: Construction Program of Open Innovation Organization [FY2018~FY2022].

Publication

- Yamagata University; "JFlex2020" (Jan. 2020 / Tokyo).

技術成果

Spray Coating

Spray coating technology for organic electronics devices are developed. OLED devices fabricated by spray coating gave uniform emission and comparable characteristics with those fabricated by spin coating.

Technological features

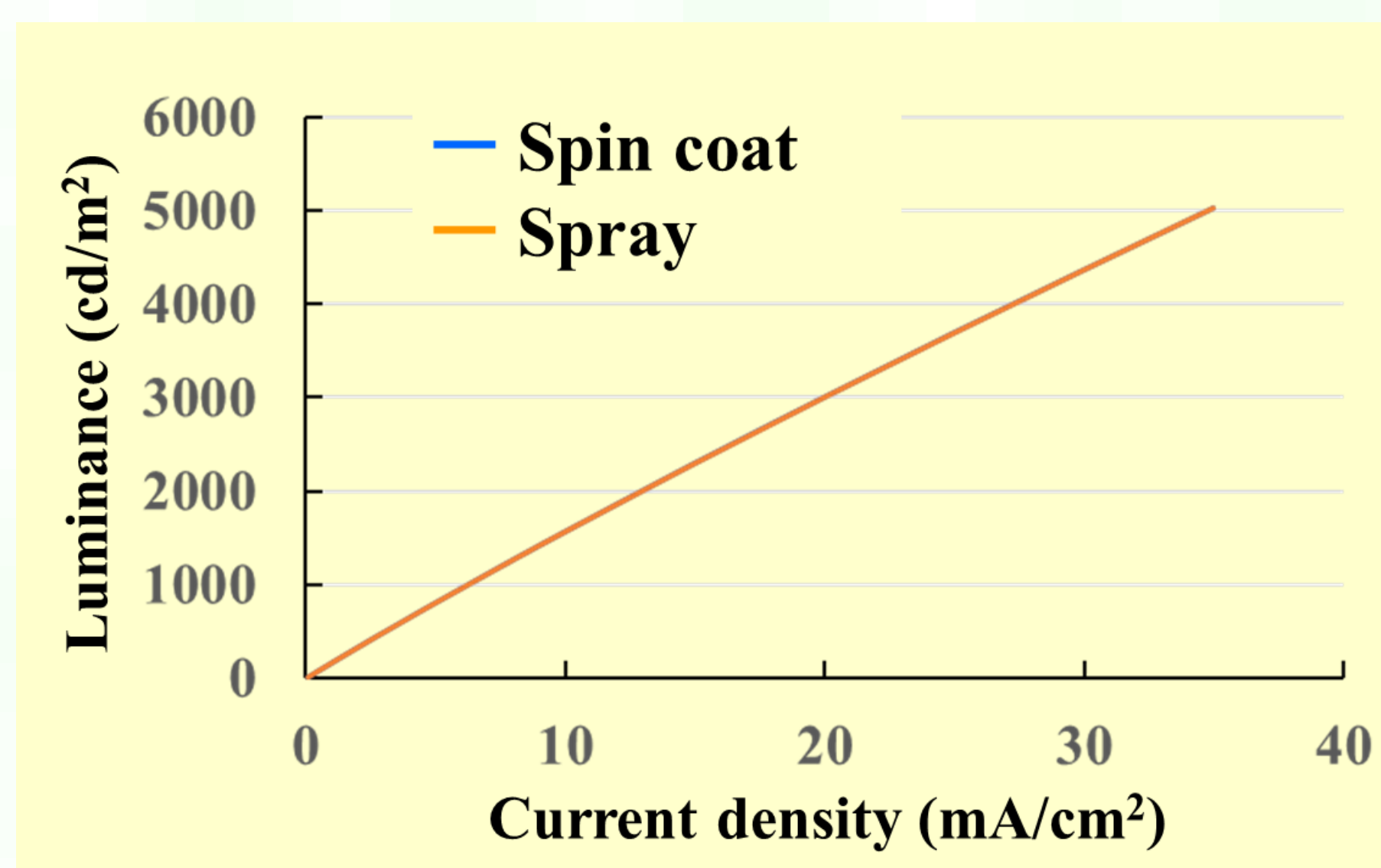
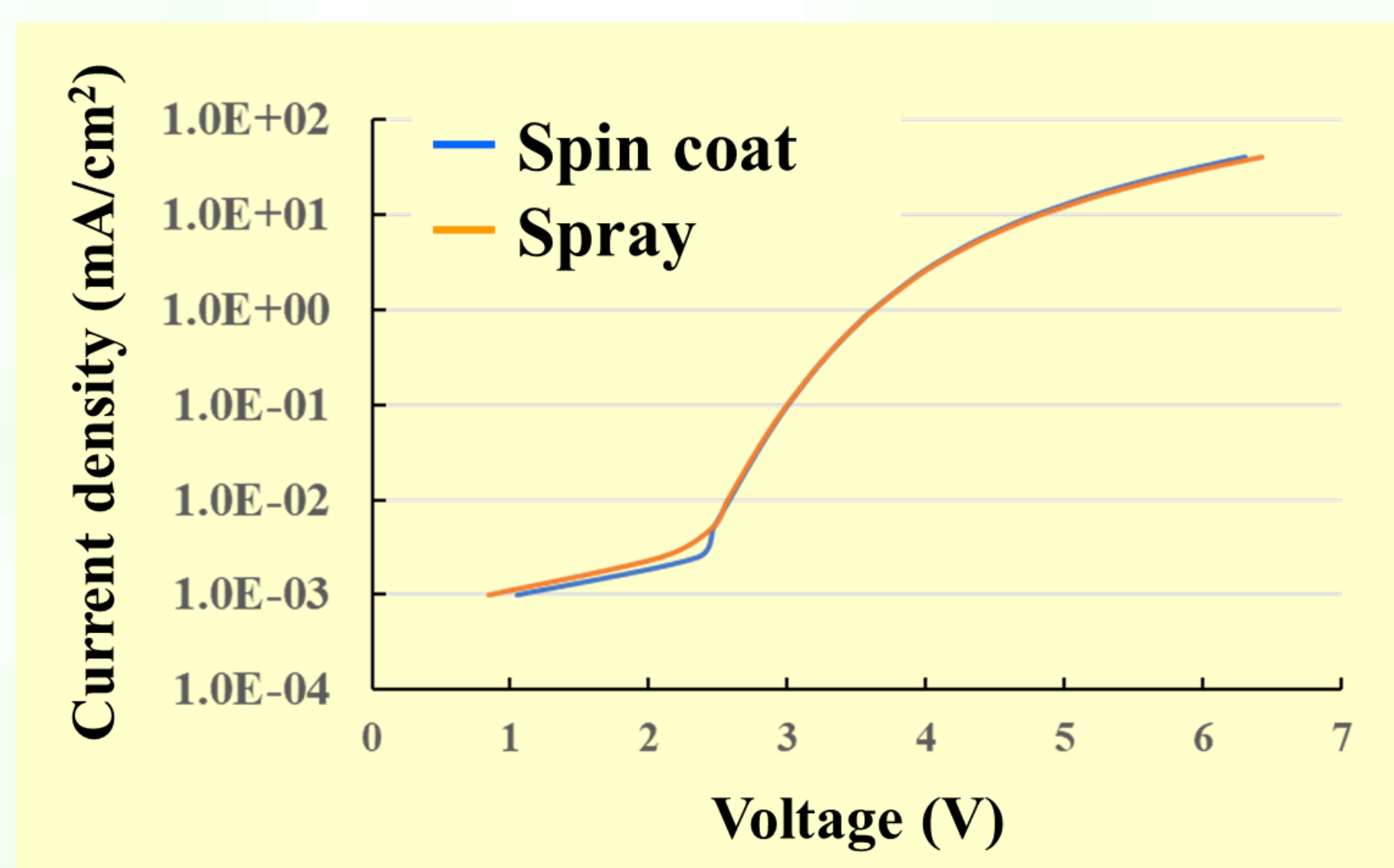
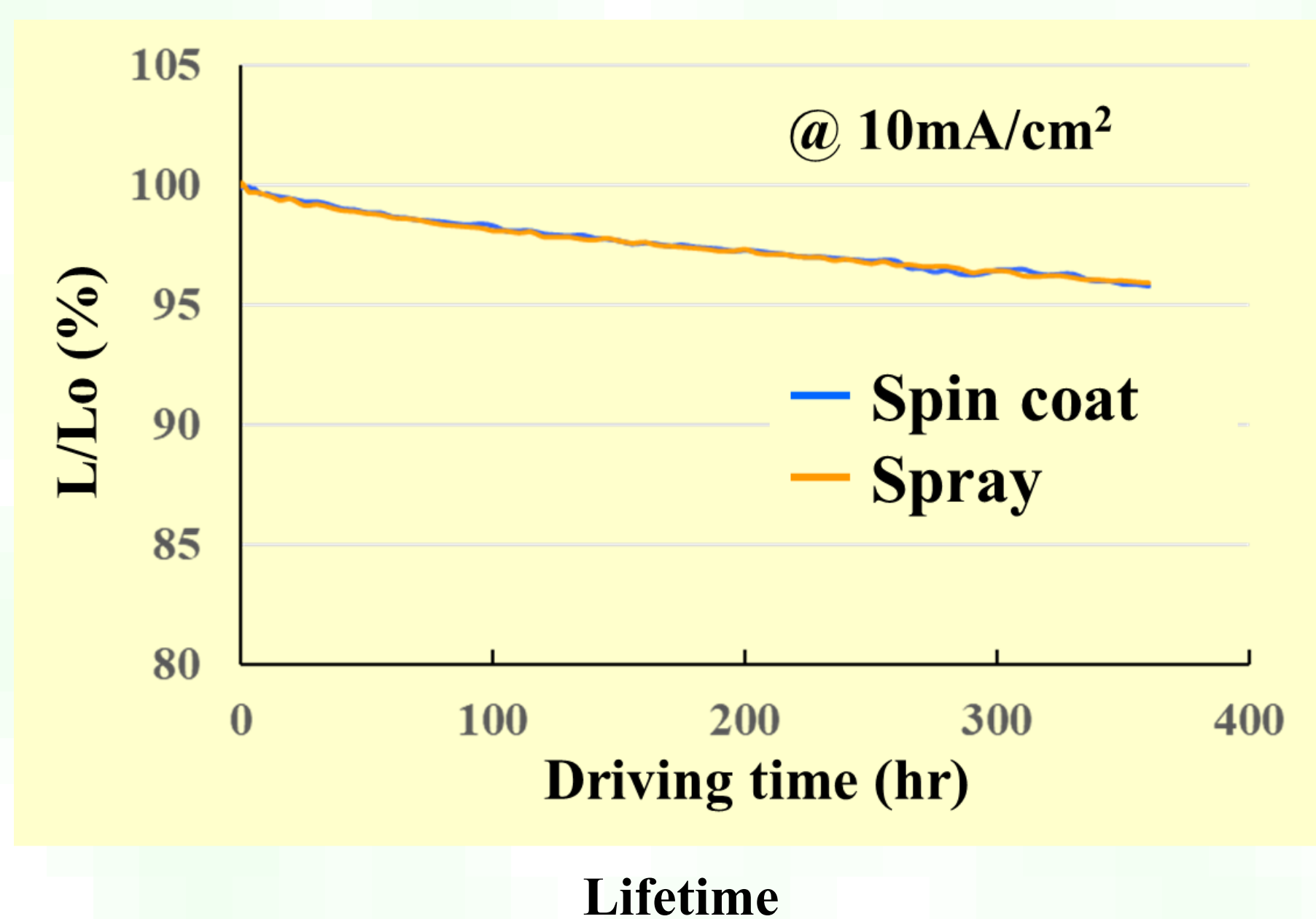
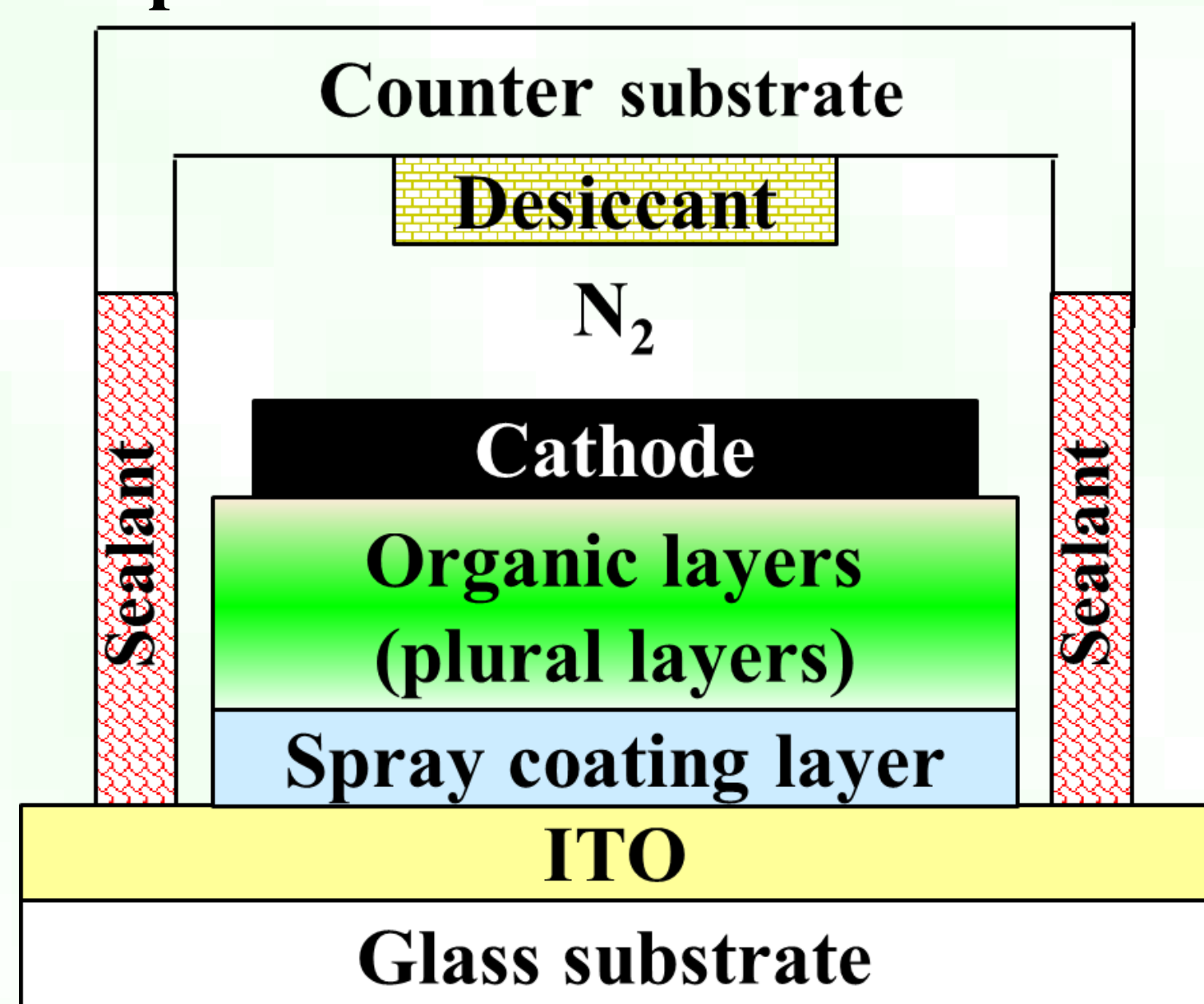
- **Uniform coating on large substrates**

Developed technologies

- Applied to OLED devices
 - Uniform emission
 - Comparable characteristics with those fabricated by spin coating



Spray equipment



OLED devices fabricated using spray coating

技術成果

Optical simulation

Optical simulation is very useful in device architecture of OLED devices.
We develop optical simulation technologies for practical OLED devices.

Technological features

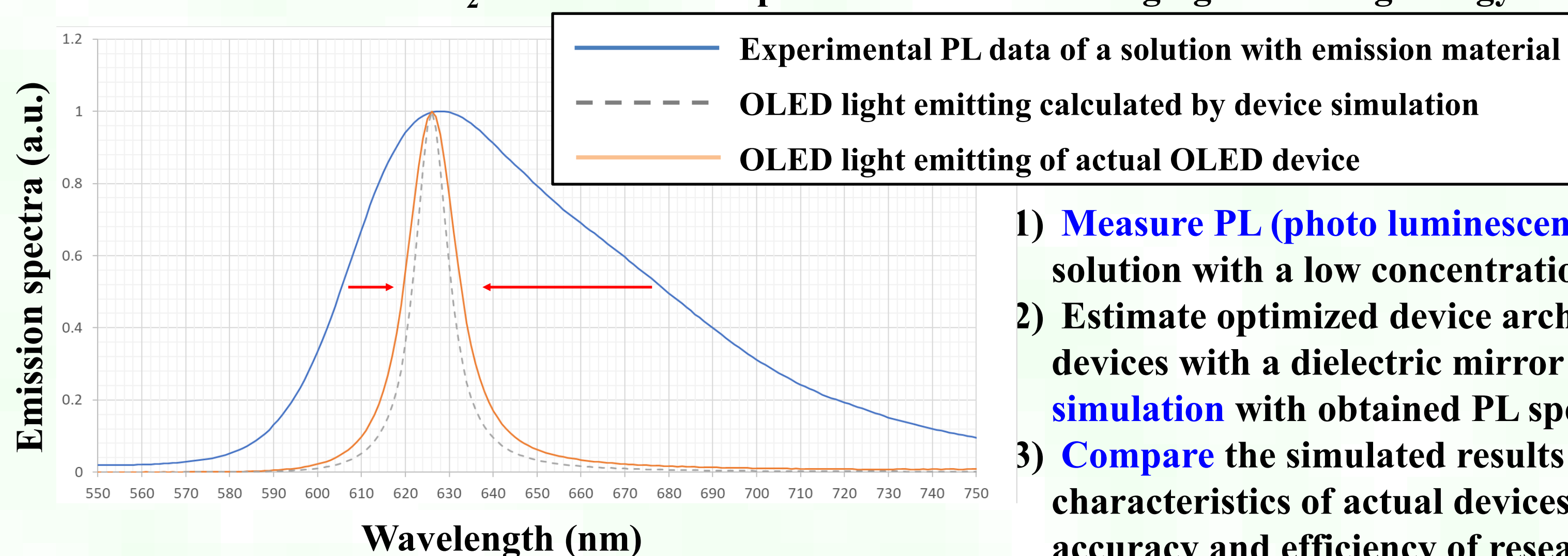
- The developed optical simulation technologies of OLED devices can contribute to accuracy and efficiency of R&D in conjunction with our rich experiences on actual OLED devices.
- Software; Fluxim Setfos (Cyber Net Inc.), etc.

Developed technologies

- **Optical simulation of OLED device architecture with a mirror plane and a micro-cavity layer with faint-reflecting Ag anode**

- Optical simulation of optimized light emitting profile of OLED devices with a dielectric mirror with high reflective index and a micro-cavity layer with faint-reflecting Ag anode
- Application of a Nb_2O_5 layer as high reflective index layer
- The thicknesses of SiO_2 and HTL were optimized for maximizing light emitting energy.

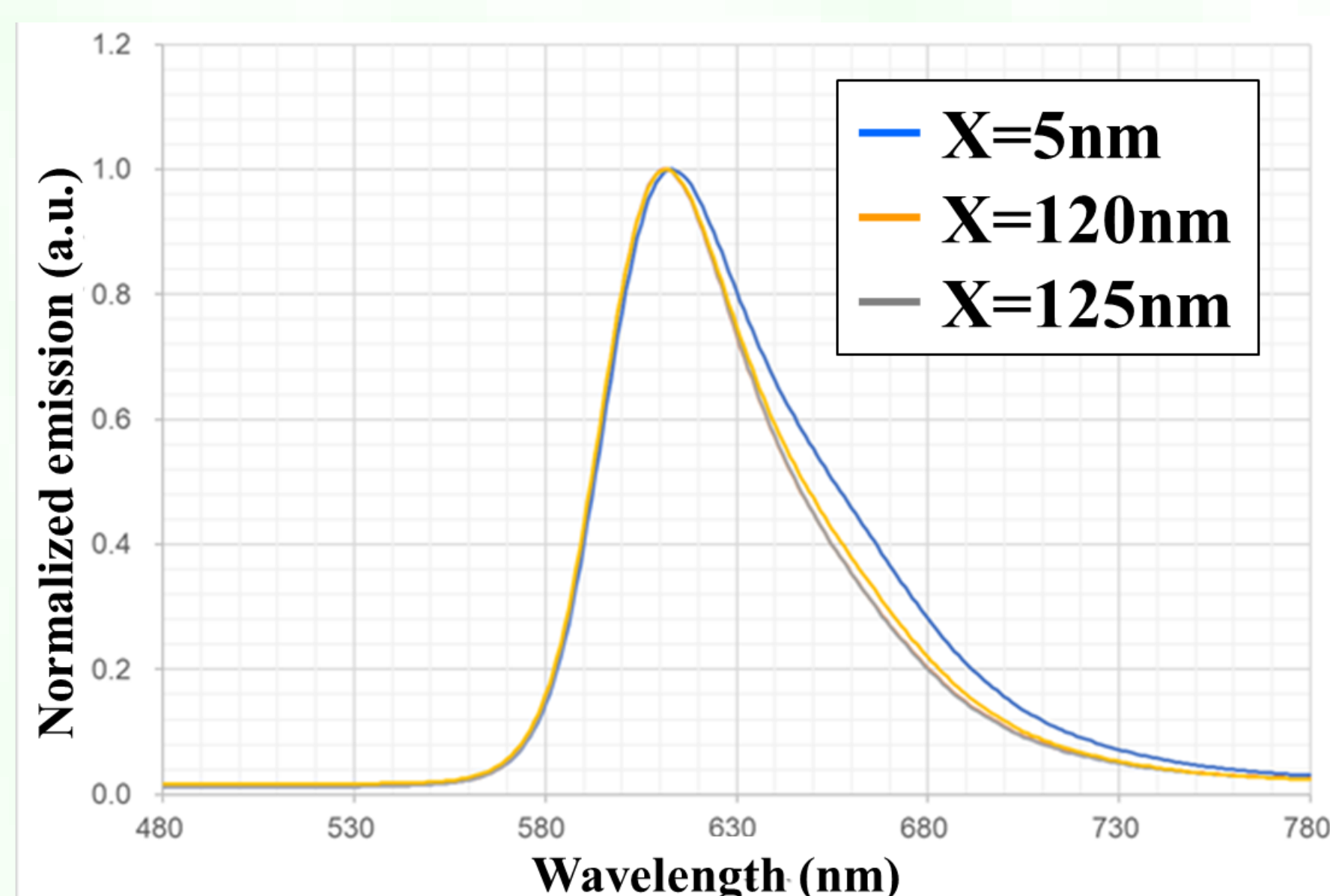
Substrate (∞)
Nb_2O_5 (68nm)
SiO_2 (105nm)
IZO_1 (15nm)
Ag (22nm)
IZO_2 (15nm)
HTL (39nm)
EML_R (42nm)
ETL (40nm)
Al (100nm)



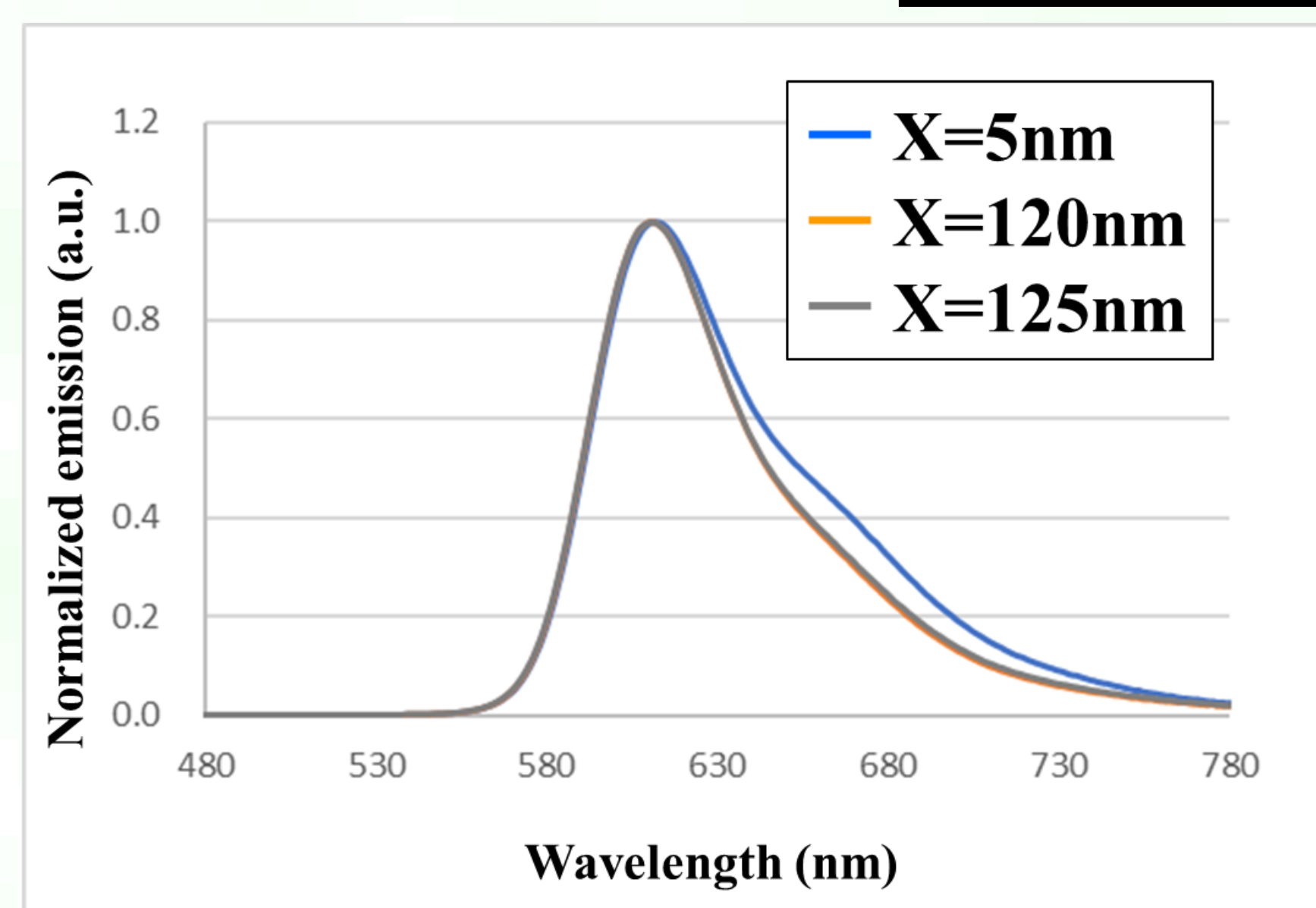
An example of comparison of an actual device and a simulation of one layer of dielectric mirror with high reflective index and a micro-cavity layer with faint-reflecting Ag anode.

- **Spectra simulation of OLED devices with different thickness of organic layers**
- Simulation of OLED emission spectra dependence on thickness of hole injection layer (HIL) in OLED devices.
- Excellent consistency between simulations and experimental results.

Substrate (∞)
ITO (150nm)
HIL (Xnm)
HTL (65nm)
EML_R (46nm)
ETL (46nm)
Al (100nm)



Device simulation



Experimental result

Developed
technology

Analysis of defects, failures, structures, etc.

We contribute to practical device technologies by using various analysis such as analysis of defects failures, structures, etc..

Technological features

- Optical microscope
- Digital microscope
- AFM (Atomic Force Microscope)
- Film thickness measurement apparatus
- Emission microscope
- Ionization potential measurement apparatus, etc.

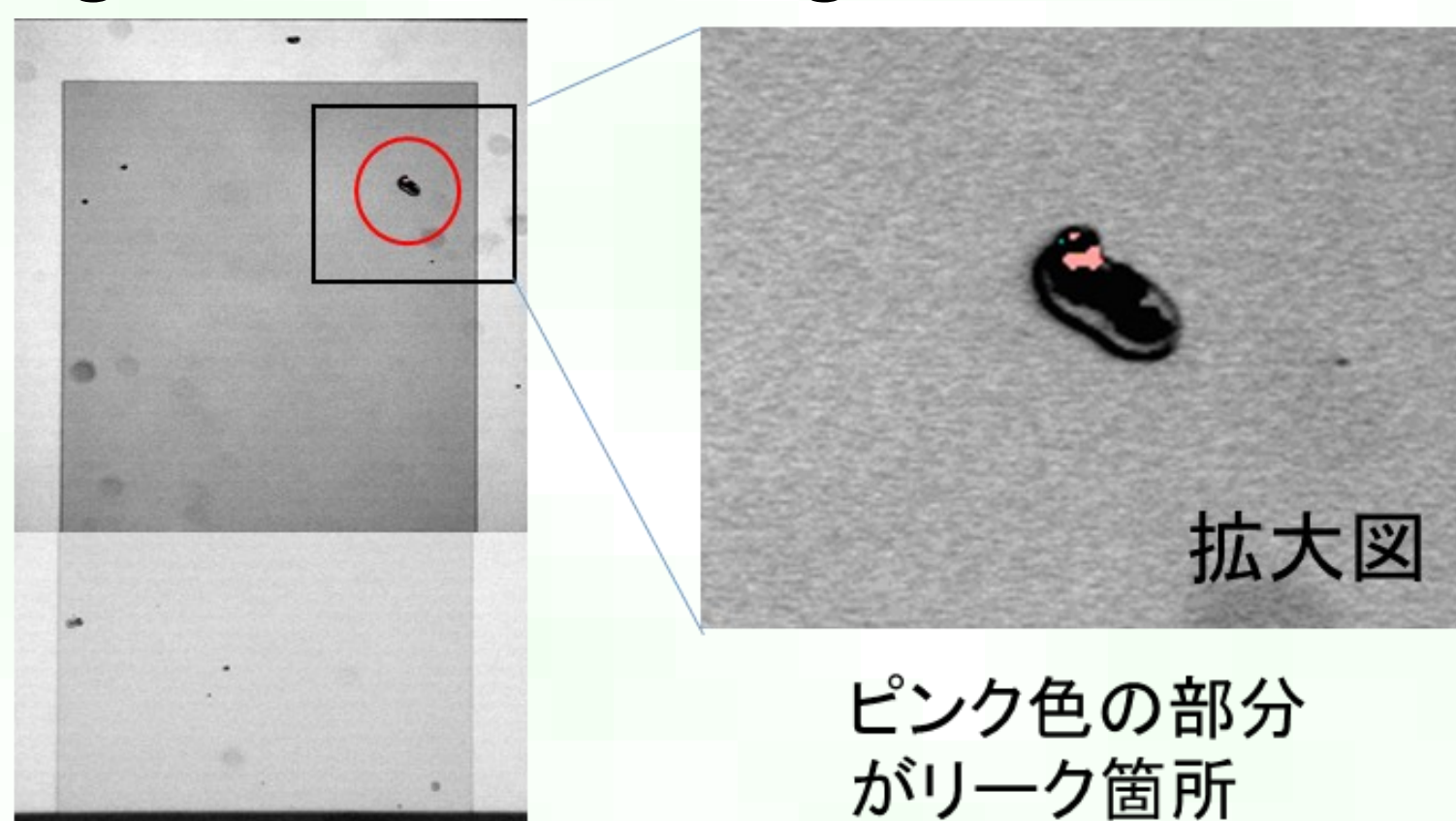
Analysis example 1

■ Assignment of defect point by emission microscope

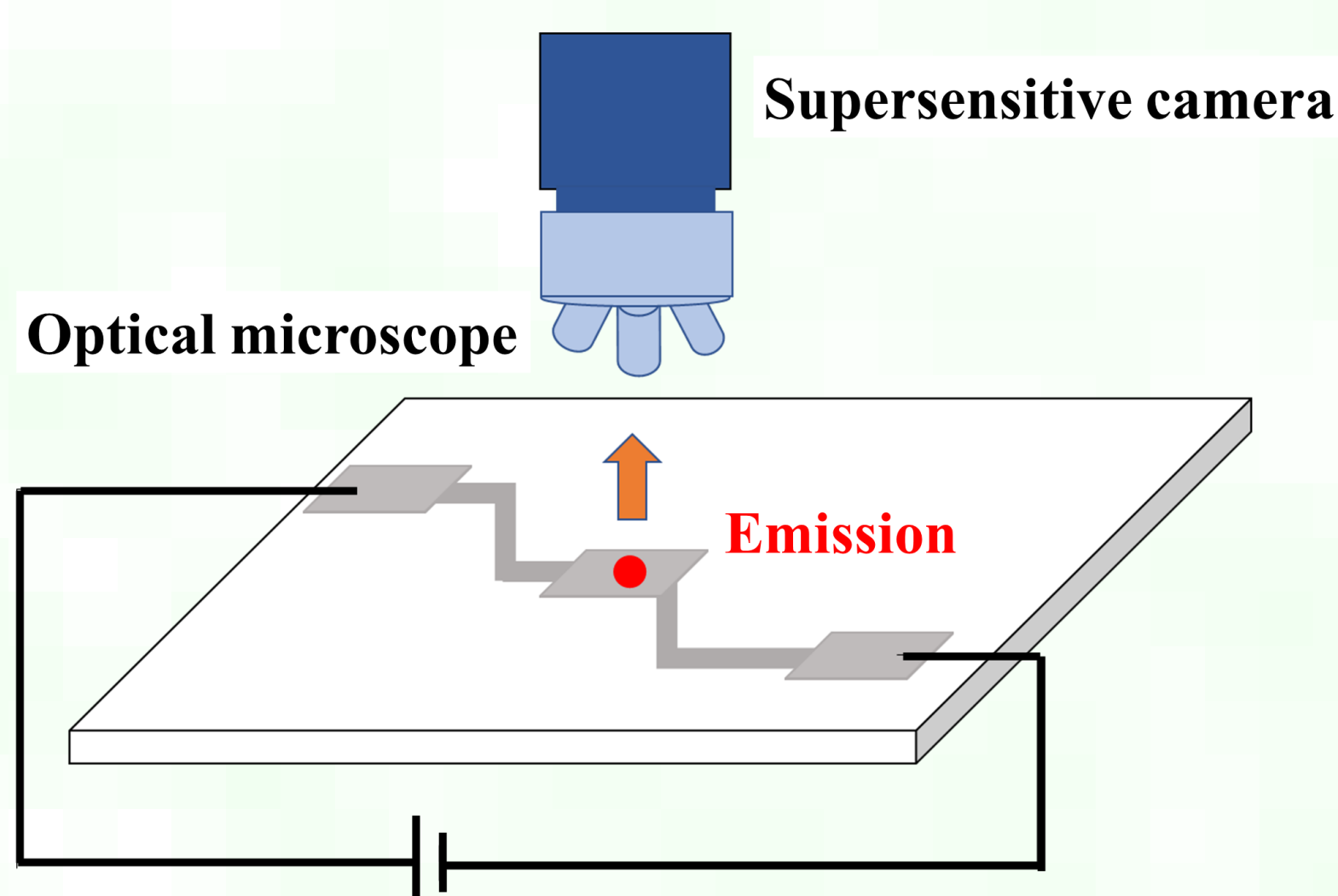
- Assignment of defect point
- Investigation of cause of defects by combining with optical microscope, FE-SEM, etc.

【Measurement principle】

- System: optical microscope and high sensitive camera
- Supersensitive camera can detect emission induced by hot carrier generated by applying voltage.
- Emission point can be detected by combining emission image and reflective image.



a) Detection of defects by emission microscope

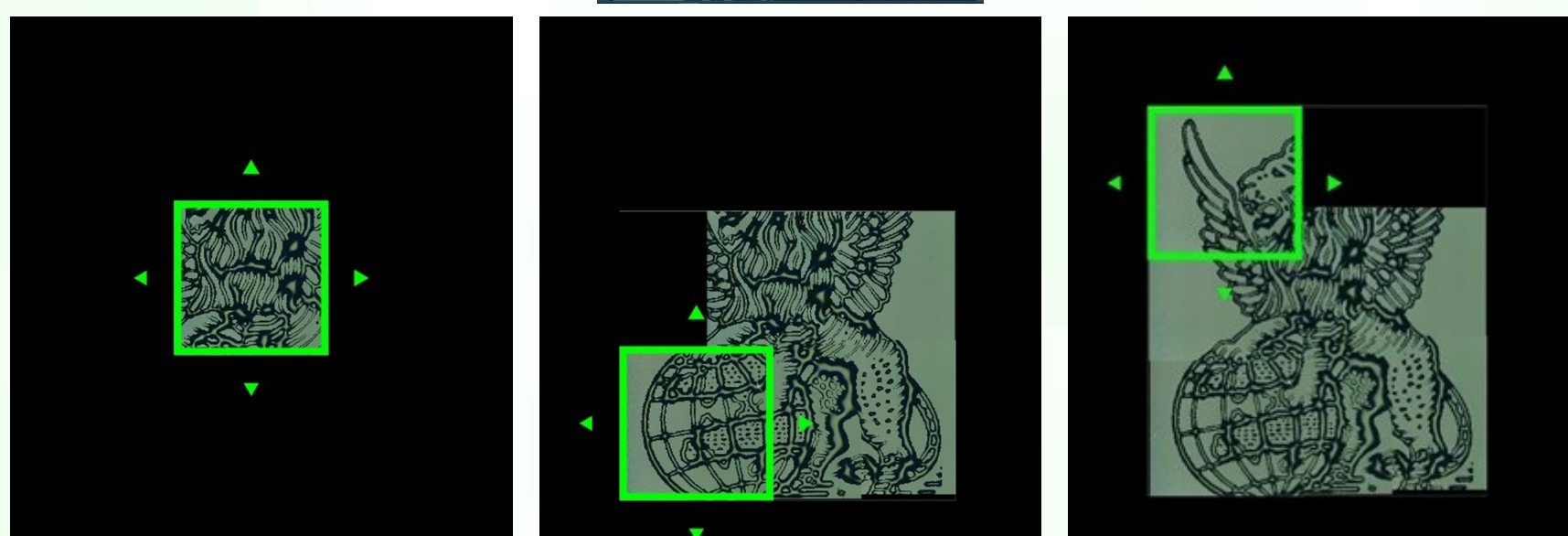
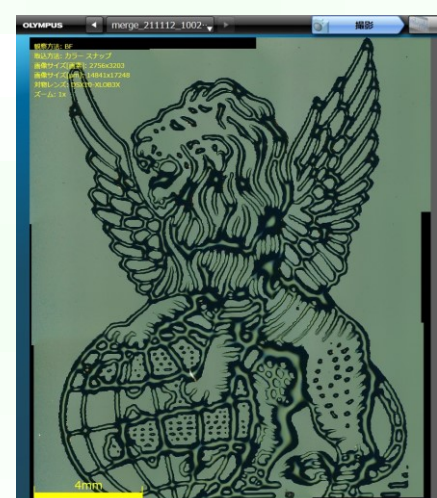


b) Observation of leak point by confocal microscopy

Analysis example 2

■ Observation by digital microscope

- Tiling of plural images
- Observation with magnification of 42~5600
- Various types of observation (BF, focal illumination, DF, BF+DF、polarized illumination, differential interference)

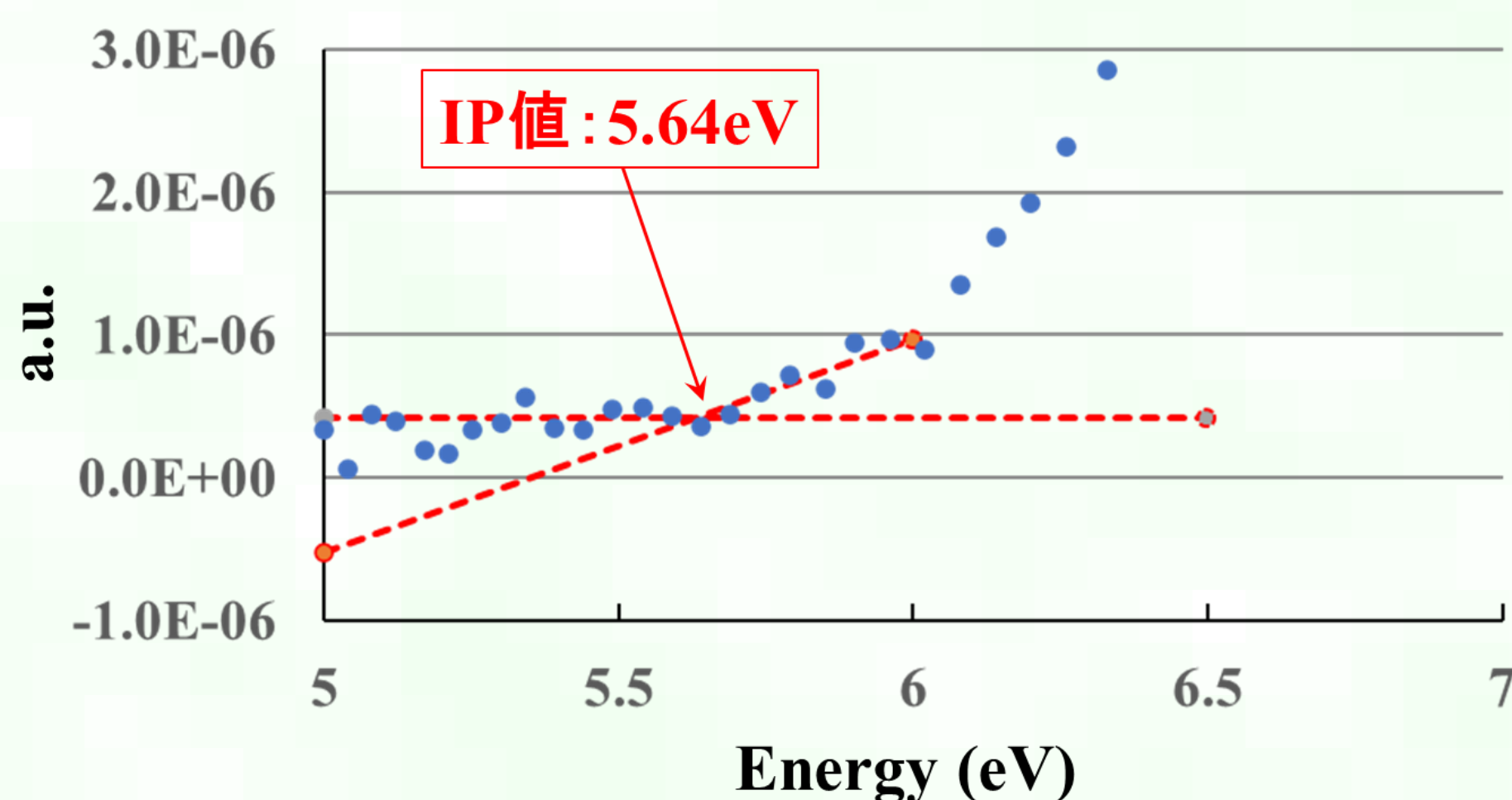


Observation of ink-jet printed pattern

Analysis example 3

■ Ionization potential (IP) measurement

- Measurement method: Photoelectron Yield Spectroscopy (PYS)



(Example)
Ionization potential measurement of a novel material.

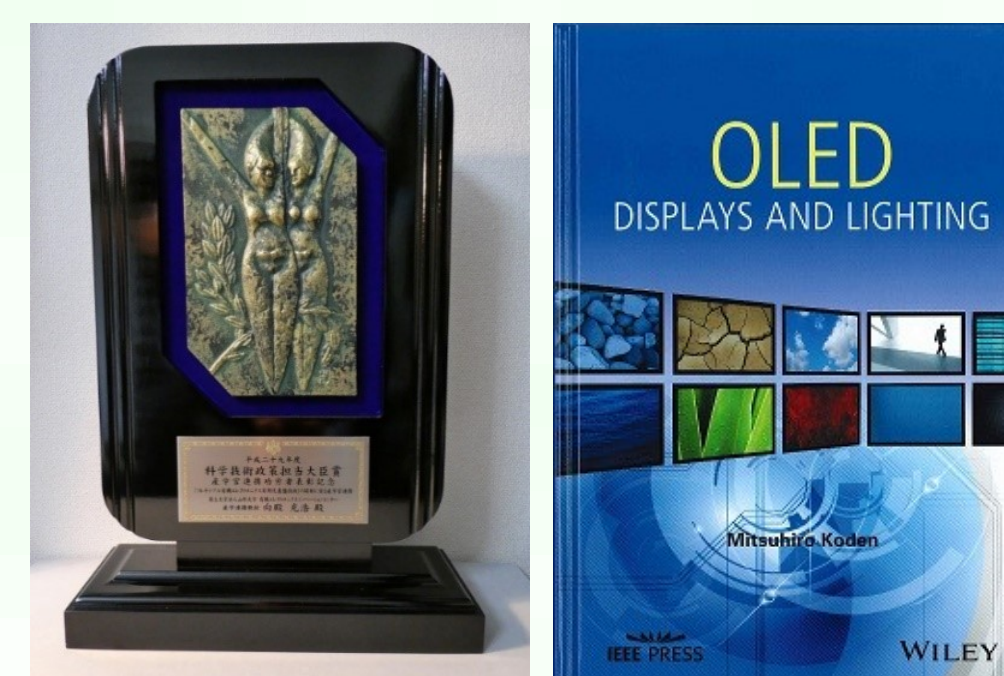
Topics / Publications

Award

- H. Nakada, M. Koden, **“Award from Minister of State for Science and Technology Policy”**, Cabinet Office, Government of Japan, (2017).

Book

- M. Koden, **“OLED Displays and Lighting”** (Wiley, IEEE Press) (2017).
- M. Koden, T. Furukawa, T. Yuki, H. Nakada, Springer Link **“Handbook of Organic Light-Emitting Diodes”** (2020). **“Transparent Electrodes”**



Paper

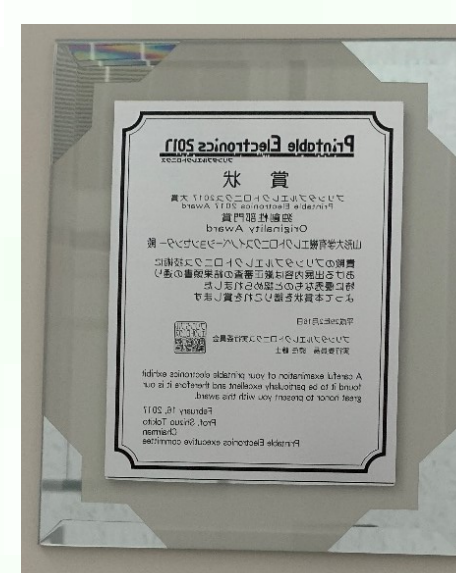
- T. Yuki, T. Nishikawa, M. Sugimoto, H. Nakada, M. Koden, ITE Trans. on MTA Vol. 9, No. 4, pp. 216-221 (2021). **“High Temperature Tolerant Barrier Films with Stacking Barrier Layers by Sputtering and ALD”**
- T. Furukawa, M. Koden, IEICE Trans. Electron, E100-C, 949-954 (2017). **“Novel roll-to-roll deposition and patterning of ITO on ultra-thin glass for flexible OLEDs”**

International Conference

- T. Furukawa, J. Hauptmann, T. Nakagaki, R. Ikeuchi, M. Sagawa, D. Nagata, J. Nakatsuka, IDW'21, FLX5/FMC6-1 (2021). **“Roll-to-Roll Fabrication for OLED Lighting Using Ultra-Thin Glass Substrate and Encapsulating Stainless Steel Foil”**
- M. Natsuka, Y. Ono, H. Mataka, S. Usui, H. Suzuki, M. Abe, T. Furukawa, IDW'21, FLX5/FMC6-2 (2021). **“Protection of OLED Lighting with Ultra-Thin Glass by Special Silicone Gel”**
- Y. Kawamura, T. Takahashi, T. Furukawa, ICFPE 2Rm401-08-02 (2021). **“Improvement of printed electrodes disconnection after 3D thermoforming by optimizing print process on PC film”**
- M. Sugimoto, Y. Fukuchi, H. Tsuruta, M. Koden, H. Nakada, T. Yuki, A-COE 2021, PA-17 (2021). **“OLEDs with on-demand patterns drawn by ink-jet printing”**
- M. Koden, M. Sugimoto, N. Kawamura, T. Yuki, H. Nakada, AM-FPD21, 3-1 (2021). **[Invited] “Novel Flexible Films with High Gas Barrier Layers by Sputtering and ALD”**
- T. Yuki, T. Nishikawa, M. Sugimoto, H. Nakada, M. Koden, IDW'20, FLX2-3 (2020). **“High Temperature Tolerant Barrier Film with Stacking Barrier Layers by Sputtering and ALD”**
- Y. Kawamura, T. Takahashi, K. Wakabayashi, H. Hirose, Y. Azakami, H. Itoh, T. Furukawa, IDW'20, FLX3-04L (2020). **“Effect of Pressure Forming Conditions on PC Sheet integrating Electric Wiring for 3D Electronics Technology”**
- T. Nakagaki, T. Kawabata, H. Takimoto, T. Furukawa, IDW'19, FLXp1-9L (2019). **“Scribing Tool and Cutting Method for Ultra-thin Glass”**
- K. Taira, T. Suzuki, W. Konno, H. Chiba, H. Itoh, M. Koden, T. Takahashi, T. Furukawa, IDW'18, FLX2-4L (2018). **“Development of High Gas Barrier Film Using Novel Precursor by Roll to Roll PECVD”**
- T. Furukawa, N. Kawamura, T. Noda, Y. Hasegawa, D. Kobayashi, M. Koden, IDW'17, FLX6-2 (2017). **“Novel Roll-to-Roll Fabrication Processes of Transparent Electrodes on Ultra-Thin Glass”**

Exhibitions

- **“CEATEC 2021”** (Oct. 2021).
- **“JFlex”** (Jan. 2019, Jan. 2020, Dec. 2020).
- **“Printable Electronics”** (2014, 2015, 2015, 2016, 2017, 2018).
- **“LOPEC”** (2018, 2019 / Germany).
- **“Flex Japan 2019”** (May 2019).
- **“LED & OLED EXPO 2017”** (Jun. 2017 / Korea).
- **“G7 Exhibition”** (May 2016).
- **“International Photonics Exhibition 2015”** (Oct. 2015 / Korea).



Printable Electronics
2017 Award



JFlex Award
(2019, 2020)



**“International Photonics Exhibition
2015”** (October 2015, Korea)



“JFlex 2020”
(Jan. 2020, Tokyo)



“LOPEC” (Mar. 2019, Germany)



“Flex Japan 2019”
(May 2019, Tokyo)

Main Members



Professor, Director for Organic Electronics **Hitoshi Nakada**

nakada@yz.yamagata-u.ac.jp

Field: Organic electronics devices

1981 Graduated at Tohoku University
1981~2013 Pioneer Corporation
1988~ R&D of OLED display and OLED lighting
2013~ INOEL, Yamagata University (current position)

(Award)

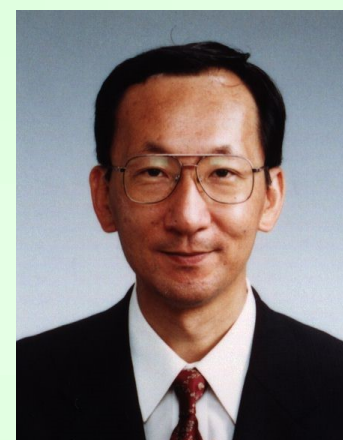
- Award from Minister of State for Science and Technology Policy”, Cabinet Office, Government of Japan (2017).
- Optoelectronics Industry and Technology Development Association, 19th Kenjiro-Sakurai Memorial Award (2003).
- 47th Okochi Memorial Award (2000).

(Development)

- World’s first OLED product (passive-matrix OLED display) (1997).
- World’s first phosphorescent OLED product (2003).
- Passive-matrix full-color flexible OLED display prototype (2003).

(Publication)

- M. Sugimoto, Y. Fukuchi, H. Tsuruta, M. Koden, H. Nakada, T. Yuki, A-COE 2021, PA-17 (2021).



Professor **Dr. Mitsuhiro Koden**

koden@yz.yamagata-u.ac.jp

Field: LCD, OLED, Chemistry

1983 Graduated at Osaka University (PhD)
1983~2012 Sharp Corporation
(Liquid crystal materials, LCD, OLED display, etc.)
1998~2011 Guest prof. of Nara Institute of Science and Technology
2012~ INOEL, Yamagata University (current position)

(Award)

- Award from Minister of State for Science and Technology Policy”, Cabinet Office, Government of Japan (2017).
- Award from The Japanese Liquid Crystal Society (2005).

(Development)

- 17” Ferroelectric liquid crystal display (FLCD) prototype (1999).
- 3.6” Polymer OLED display prototype fabricated by ink-jet (2006).

(Book)

- M. Koden, “OLED Displays and Lighting” (Wiley; IEEE Press) (2017).
- K. Takatoh, M. Hasegawa, M. Koden, N. Itoh, R. Hasegawa, M. Sakamoto, “Alignment Technologies and Applications of Liquid Crystal Devices” Taylor & Francis (2005).



Associate Professor **Tadahiro Furukawa**

ta-furukawa@yz.yamagata-u.ac.jp

Field: Fine patterning technology, Printing, Roll-to-roll technology

1984 Graduated at Saitama University (Master degree)
1984~2011 Kyoto Printing Co., Ltd.
R&D and production of Color filter (CF)
R&D of flexible CF and LCD
2011~ INOEL, Yamagata University (current position)

(Papers)

- T. Furukawa et al, IEICE Trans. Electron, E100-C, 949-954 (2017).

(International conference)

- T. Furukawa et al., IDW’21, FLX5/FMC6-1 (2021).
- T. Furukawa, M. Koden, ICDT2019, 55.2 (2019). [China/Invited]
- T. Furukawa, WCAM2018 (2018). [China/Invited]
- T. Furukawa et al., IDW’17, FLX6-2 (2017).
- T. Furukawa, LED & OLED EXPO 2017 (2017). [Korea]
- T. Furukawa et al., LOPEC (2017). [Germany]
- T. Furukawa et al., IDW/AD’16, FLX3-3 (2016).
- T. Furukawa, IWFPE2016 (2016). [Korea/Invited]
- T. Furukawa, S. Tokito, SID 2015, 4.4 (2015).



Associate Professor **Dr. Toshinao Yuki**

t-yuki@yz.yamagata-u.ac.jp

Field: OLED (Display, Lighting, Device) Polymer materials

1993~1996 Teijin Limited
1996~1999 Graduated at Yamagata University (PhD)
1999~2015 Tohoku Pioneer Corporation
(PMOLED, AMOLED, Tiling OLED, OLED lighting, etc.)
2015~ INOEL, Yamagata University (current position)

(Award)

- The 4th Japan OLED Forum Outstanding Achievement Awards (2011).

(Development)

- World’s first phosphorescent OLED product (2003).
- World’s first large size tiling OLED display product (2010).
- World’s first color-tunable OLED lighting product (2013).

(Publication)

- T. Yuki, T. Nishikawa, M. Sugimoto, H. Nakada, M. Koden, ITE Trans. on MTA Vol. 9, No. 4, pp. 216-221 (2021).



Project Scientist **Miho Sugimoto**

m-sugimoto@yz.yamagata-u.ac.jp

1999 Graduated at Keio University (Master deg.)
1999~2004 Murata Manufacturing Co., Ltd.
2005~2019 Tohoku Pioneer Corporation
2019~ INOEL, Yamagata University (current position)

(Skills)

Film OLED, Encapsulation, Electrode, Equipment, etc.

(Publication)

- M. Sugimoto, Y. Fukuchi, H. Tsuruta, M. Koden, H. Nakada, T. Yuki, A-COE 2021, PA-17 (2021).



Project Scientist **Norifumi Kawamura**

n-kawamura@yz.yamagata-u.ac.jp

2001 Graduated at Yamagata University (Master deg.)
2001~2007 IMES Co., LTD
2007~2013 ROHM Co., Ltd. / Lumiotec Inc.
2013~ INOEL, Yamagata University (current position)

(Skills)

OLEDs (Device, process, Evaluation)

(Publication)

- M. Koden, M. Sugimoto, N. Kawamura, T. Yuki, H. Nakada, AM-FPD21, 3-1 (2021).



Project Scientist **Masanori Abe**

m-abe@yz.yamagata-u.ac.jp

1990~2013 Tohoku Pioneer Corporation
2013~ INOEL, Yamagata University (current position)

(Skills)
Printing (Screen printing, etc.), Roll-to-roll (R2R), OLEDs, Encapsulation, Equipment, etc.

(Publication)

- M. Natsuka, Y. Ono, H. Mataka, S. Usui, H. Suzuki, M. Abe, T. Furukawa, IDW’21, FLX5/FMC6-2 (2021).

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Research Group for Flexible Technologies(Nakada/Furukawa/Yuki/Koden Group)
Innovation Center for Organic Electronics (INOEL)

Yamagata University

1-808-48 Arcadia, Yonezawa, Yamagata 992-0119, Japan

TEL +81-238-29-0575

E-mail: nakada@yz.yamagata-u.ac.jp

E-mail: koden@yz.yamagata-u.ac.jp

URL : <https://inoel.yz.yamagata-u.ac.jp/F-consortium/home-e.html>

